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(19) **United States**(12) **Patent Application Publication**
CHO et al.(10) **Pub. No.: US 2016/0149157 A1**(43) **Pub. Date: May 26, 2016**(54) **ORGANIC LIGHT EMITTING DIODE
DISPLAY INCLUDING CAPPING LAYER
HAVING HIGH REFRACTIVE INDEX**(71) Applicant: **SAMSUNG DISPLAY CO., LTD.**,
Yongin-si (KR)(72) Inventors: **Hwan-Hee CHO**, Hwaseong-si (KR);
Myeong-Suk KIM, Hwaseong-si (KR);
Sung-Wook KIM, Hwaseong-si (KR)(52) **U.S. CL.**CPC **H01L 51/5237** (2013.01); **H01L 51/5253**
(2013.01); **H01L 51/5275** (2013.01); **H01L**
51/0072 (2013.01); **H01L 51/0067** (2013.01);
H01L 51/0094 (2013.01); **H01L 51/0052**
(2013.01); **H01L 51/0058** (2013.01); **H01L**
51/0073 (2013.01); **H01L 51/0074** (2013.01);
H01L 51/0071 (2013.01); **H01L 51/008**
(2013.01)(21) Appl. No.: **14/853,165**(22) Filed: **Sep. 14, 2015**(30) **Foreign Application Priority Data**

Nov. 24, 2014 (KR) 10-2014-0164595

Publication Classification(51) **Int. Cl.****H01L 51/52** (2006.01)**H01L 51/00** (2006.01)(57) **ABSTRACT**

An organic light emitting diode display including a first substrate; a first electrode on the first substrate; an organic light emitting layer on the first electrode; a second electrode on the organic light emitting layer; and a capping layer on the second electrode, wherein the capping layer includes at least one heterocyclic compound, the heterocyclic compound including a carbazole group and a heterocyclic group bonded with the carbazole group.

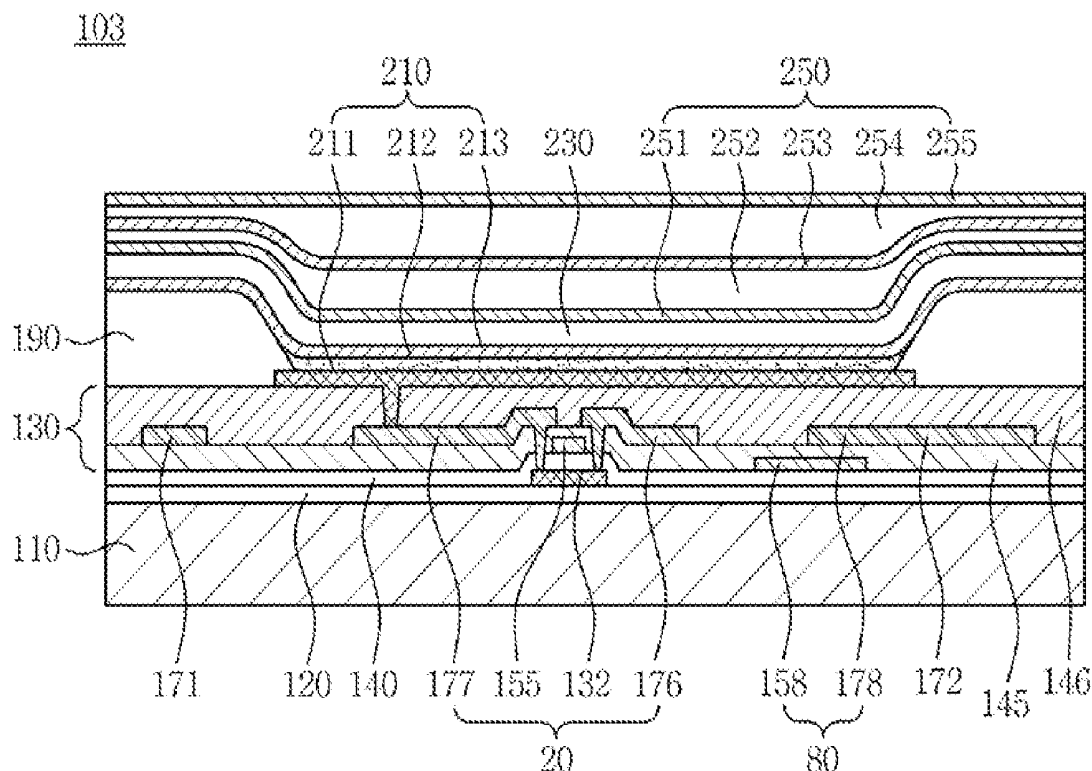


FIG. 1

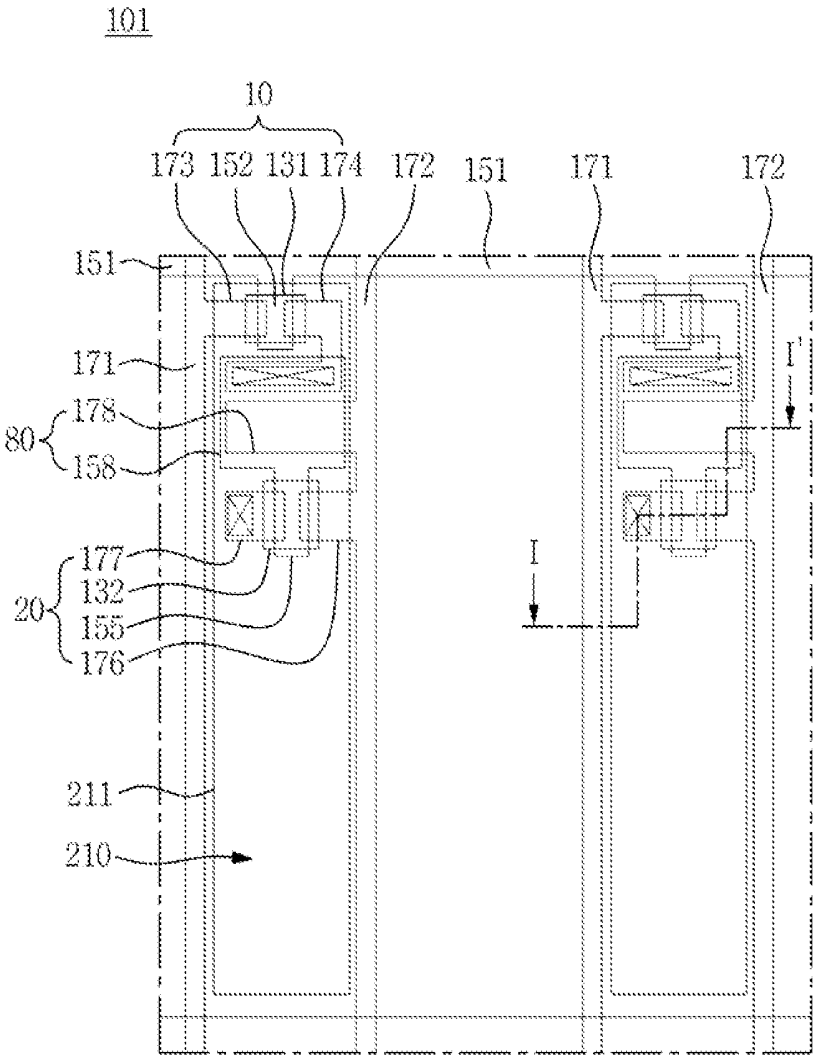


FIG. 2

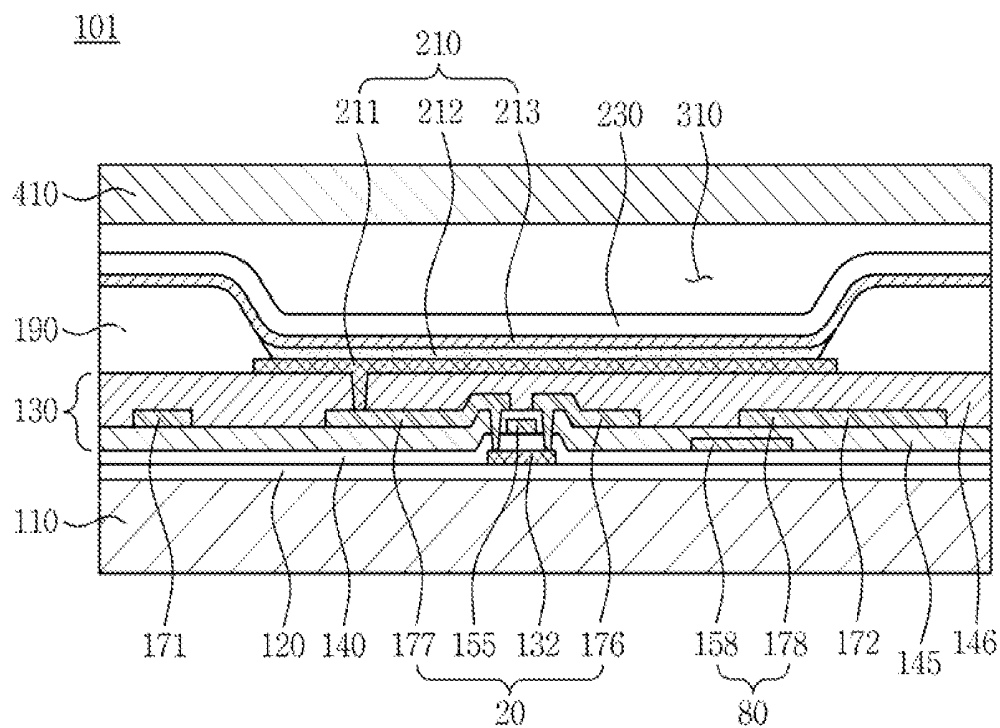


FIG. 3

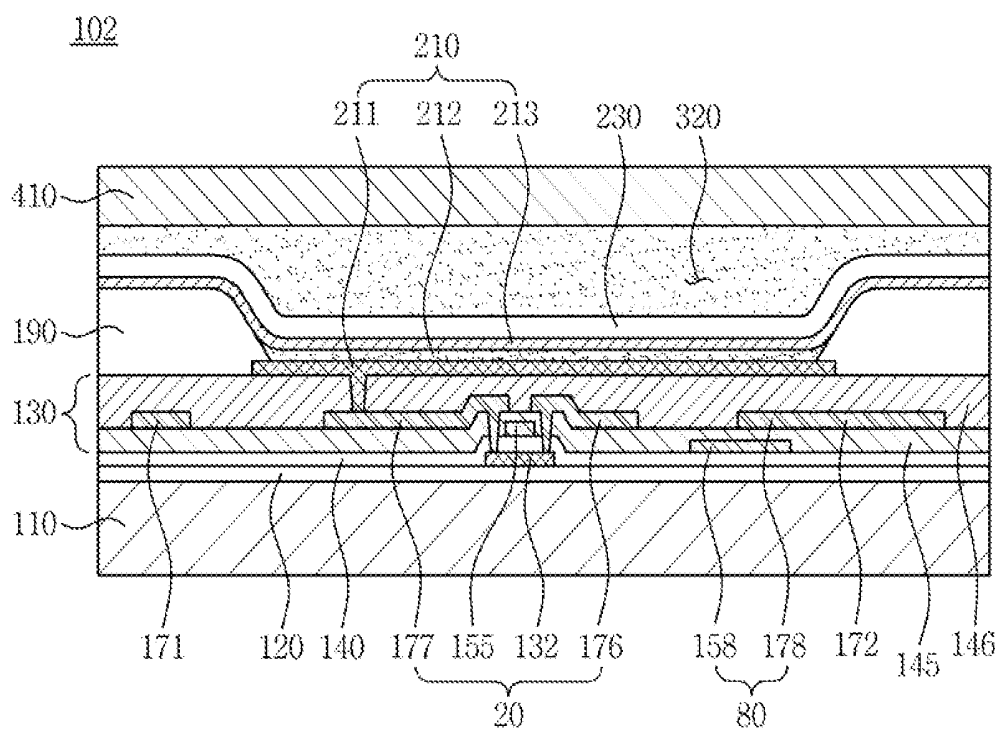
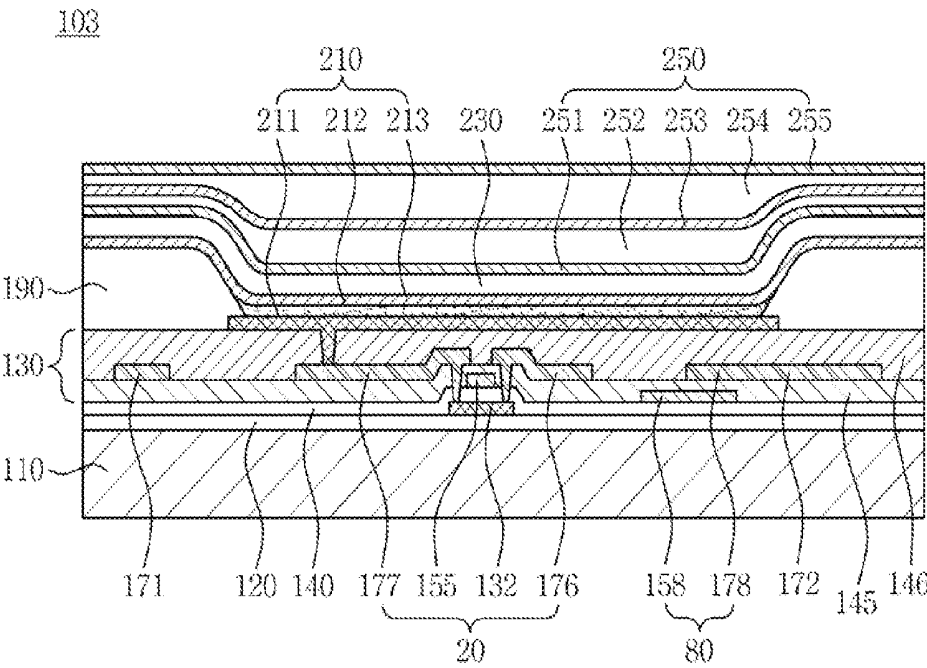


FIG. 4



ORGANIC LIGHT EMITTING DIODE DISPLAY INCLUDING CAPPING LAYER HAVING HIGH REFRACTIVE INDEX

CROSS-REFERENCE TO RELATED APPLICATION

[0001] Korean Patent Application No. 10-2014-0164595, filed on Nov. 24, 2014, in the Korean Intellectual Property Office, and entitled: "Organic Light Emitting Diode Display Comprising Capping Layer Having High Refractive Index," is incorporated by reference herein in its entirety.

BACKGROUND

[0002] 1. Field

[0003] Embodiments relate to an organic light emitting diode display (OLED display) including a capping layer having a high refractive index.

[0004] 2. Description of the Related Art

[0005] An OLED display is a self-emission type display device that displays an image using an organic light emitting diode (OLED) that emits light. An OLED display does not require a separate light source, which is different from liquid crystal display devices, thereby having relatively small thickness and light weight. Further, the OLED display may exhibit excellent properties such as low power consumption, high luminance, and high speed of response, and thus has drawn attention as a display device of the next generation.

[0006] The OLED may include a hole injection electrode, an organic light emitting layer, and an electron injection electrode. A hole and an electron may be respectively supplied from the hole injection electrode and the electron injection electrode into an organic light emitting layer, and may then be combined with each other therein to form an exciton. The OLED emits light by energy generated when the exciton falls from an excited state to a ground state.

[0007] It is to be understood that this background of the technology section is intended to provide useful background for understanding the technology and as such disclosed herein, the technology background section may include ideas, concepts or recognitions that were not part of what was known or appreciated by those skilled in the pertinent art prior to a corresponding effective filing date of subject matter disclosed herein.

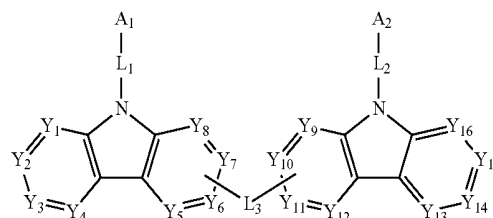
SUMMARY

[0008] Embodiments are directed to an organic light emitting diode display (OLED display) including a capping layer having a high refractive index.

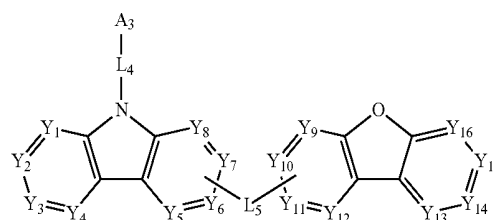
[0009] The embodiments may be realized by providing CLAIM LANGUAGE TO BE ADDED an organic light emitting diode display including a first substrate; a first electrode on the first substrate; an organic light emitting layer on the first electrode; a second electrode on the organic light emitting layer; and a capping layer on the second electrode, wherein the capping layer includes at least one heterocyclic compound, the heterocyclic compound including a carbazole group and a heterocyclic group bonded with the carbazole group.

[0010] The heterocyclic compound may be represented by one of the following Chemical Formulae 1 to 5:

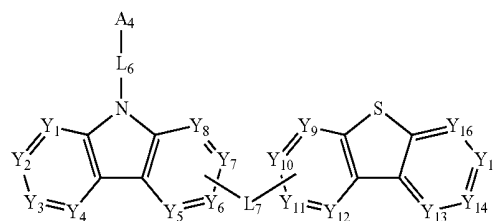
[Chemical Formula 1]



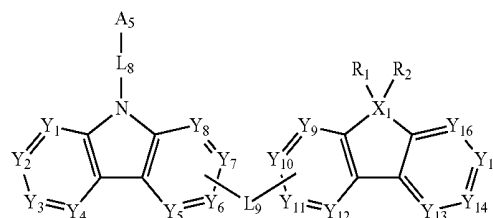
[Chemical Formula 2]



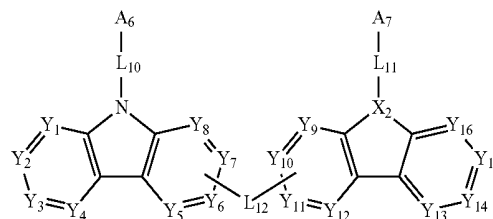
[Chemical Formula 3]



[Chemical Formula 4]



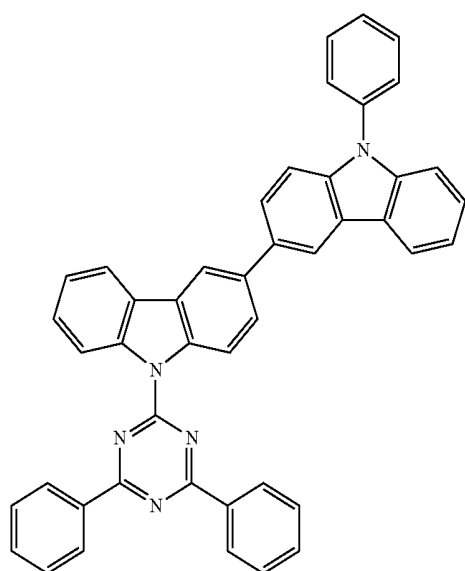
[Chemical Formula 5]



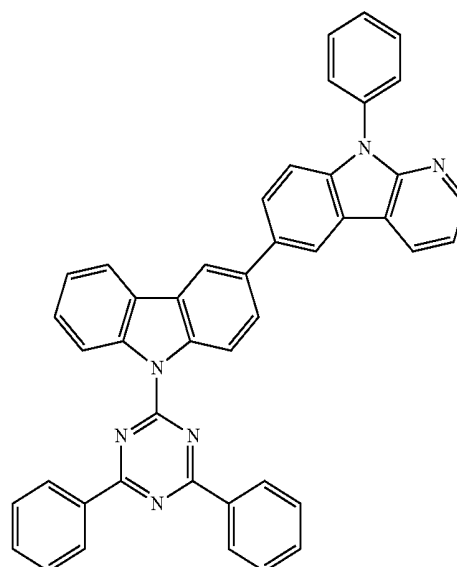
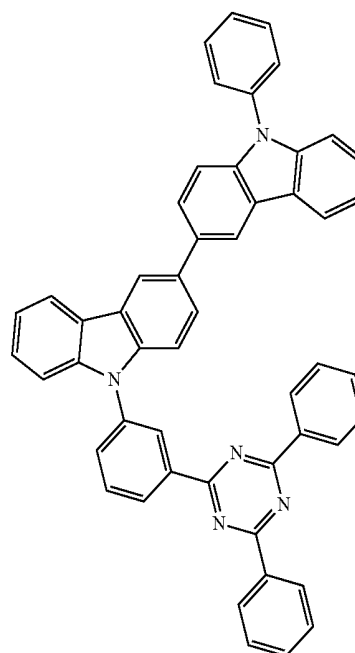
[0011] wherein, in Chemical Formulae 1 to 5, A₁ to A₇ may each independently be or include a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms or a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms; Y₁ to Y₁₆ may each independently be C—R or a nitrogen atom, wherein each R of the C—R may independently be one of a hydrogen atom, a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon

atoms, a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms and having a linear, branched, or cyclic structure, a substituted or unsubstituted alkoxy group having 1 to 30 carbon atoms, a substituted or unsubstituted aryloxy group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aralkyl group having 7 to 30 carbon atoms, a substituted or unsubstituted haloalkyl group having 1 to 30 carbon atoms, a substituted or unsubstituted haloalkoxy group having 1 to 30 carbon atoms, a substituted or unsubstituted alkylsilyl group having 3 to 30 carbon atoms, a substituted or unsubstituted dialkylarylsilyl group having 8 to 40 carbon atoms, a substituted or unsubstituted alkyldiarylsilyl group having 13 to 50 carbon atoms, a substituted or unsubstituted triarylsilyl group having 18 to 60 carbon atoms, a substituted or unsubstituted alkenyl group having 2 to 30 carbon atoms, a substituted or unsubstituted alkynyl group having 2 to 30 carbon atoms, a halogen atom, a cyano group, a hydroxyl group, a nitro group, or a carboxyl group; R of adjacent C—R, when two of Y₁ to Y₁₆ that are adjacent to each other are C—R, may be separate or may be combined to form a cyclic structure; L₁ to L₁₂ may each independently be a single bond or a connecting group; X₁ may be carbon or silicon; R₁ and R₂ may each independently be or include a hydrogen atom, a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms, or a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms, R₁ and R₂ being separate or bonded together to form a cyclic structure; and X₂ may be boron, phosphorus, or P=O.

[0012] The compound represented by Chemical Formula 1 may be one of the following Compounds 1 to 48:

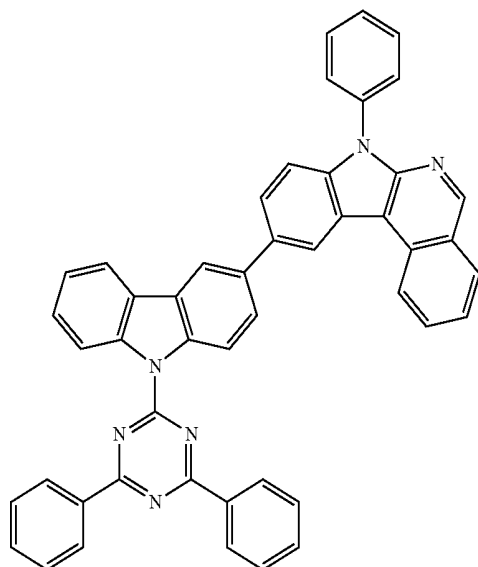


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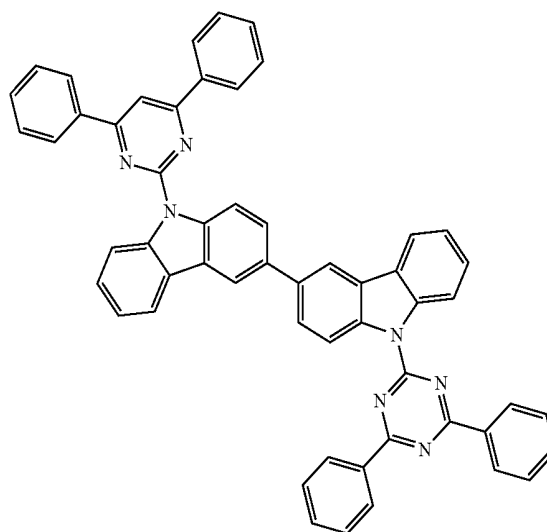
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[4]

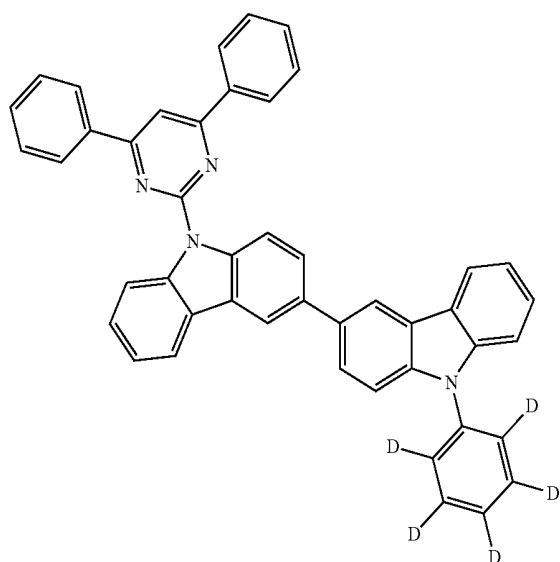


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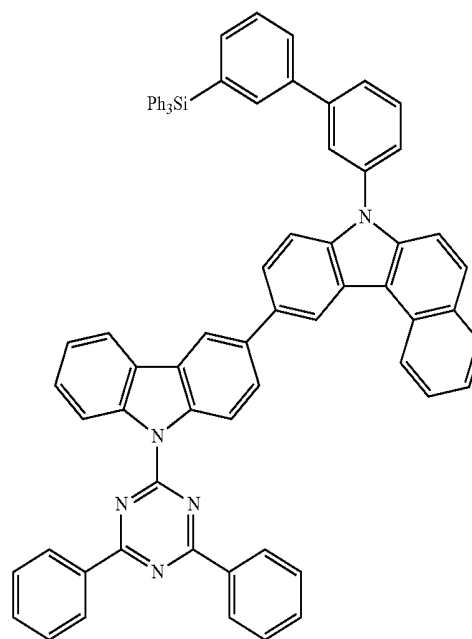
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[5]

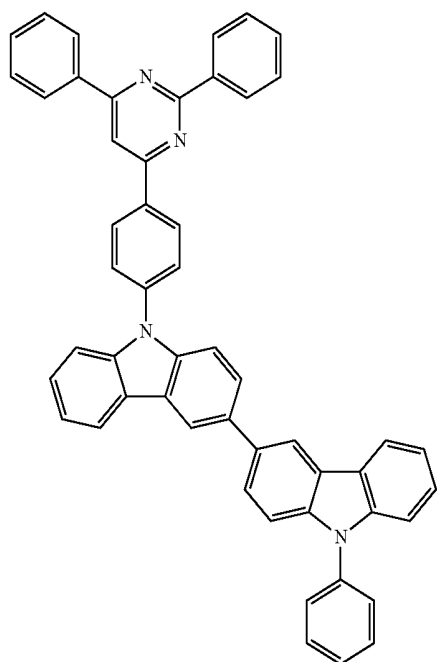


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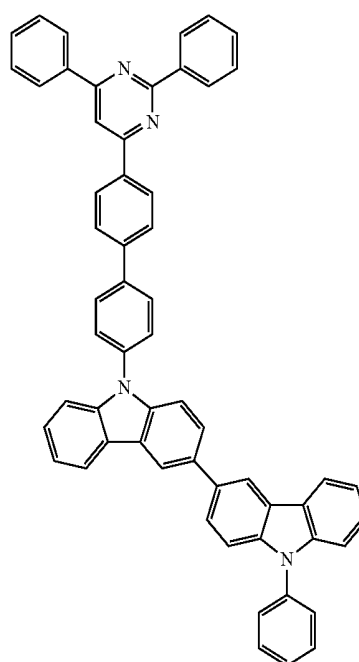
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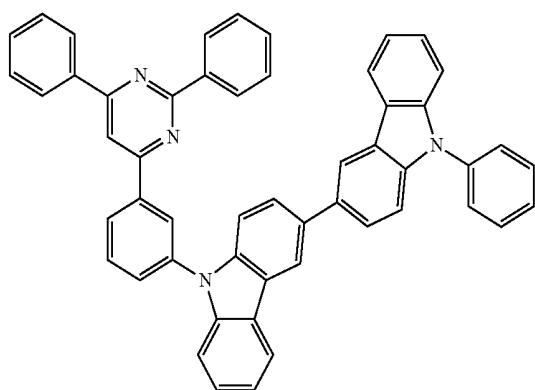


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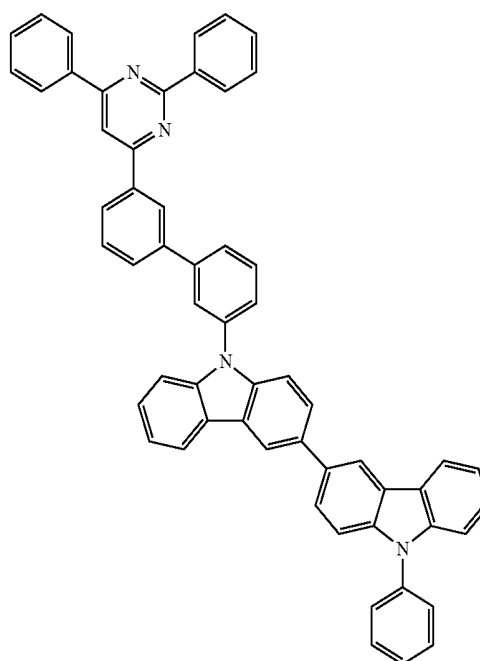
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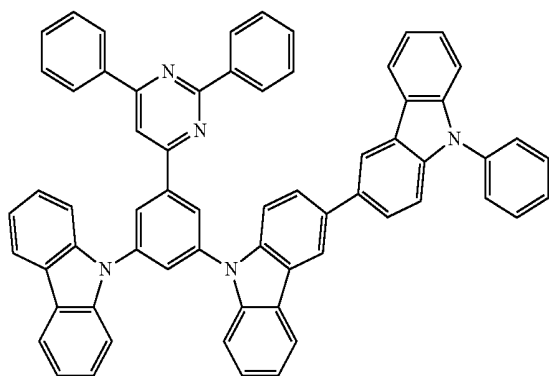
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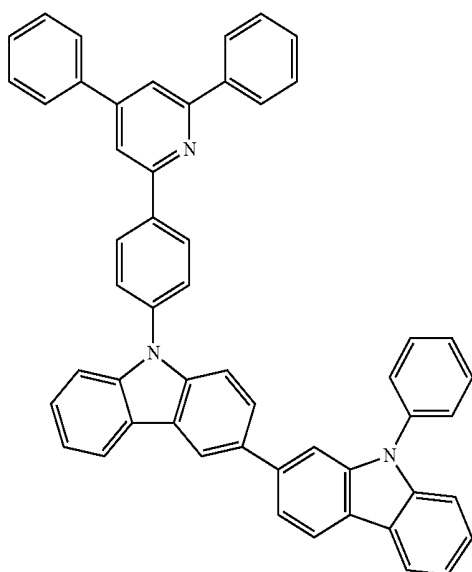
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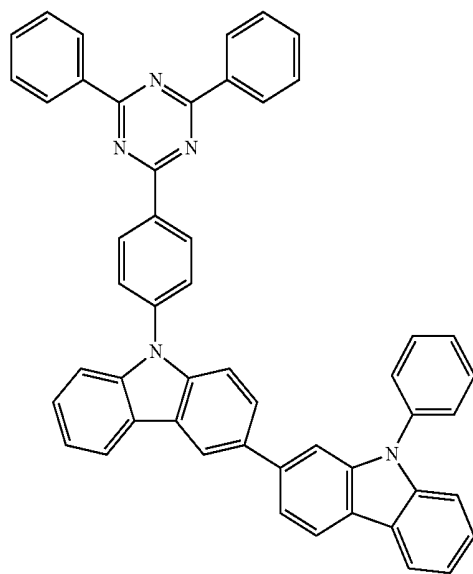
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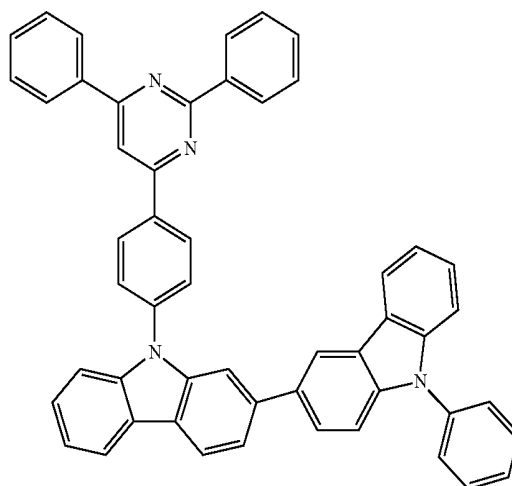


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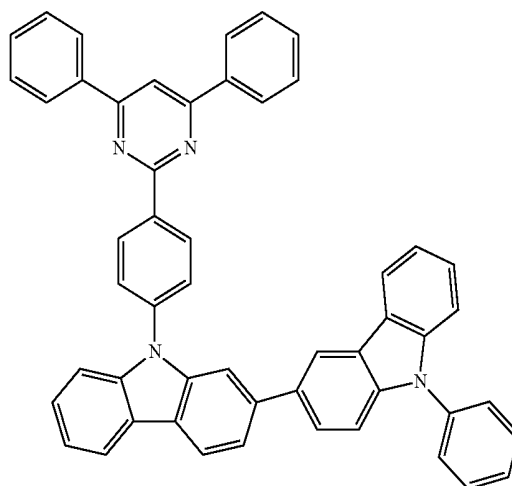


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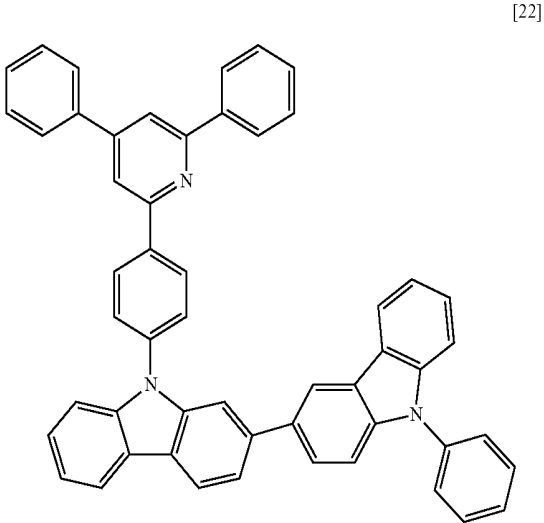
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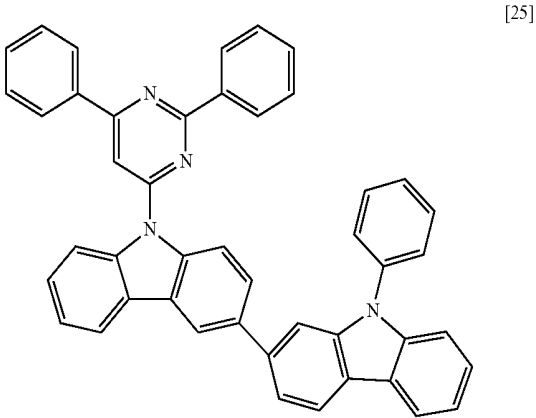
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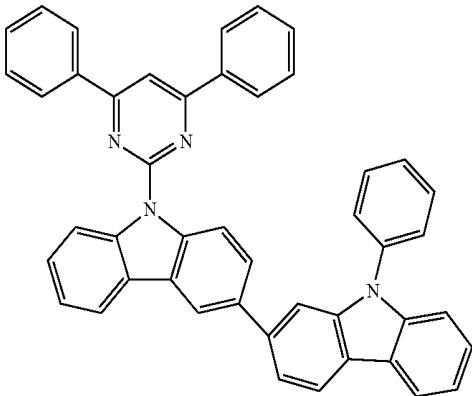
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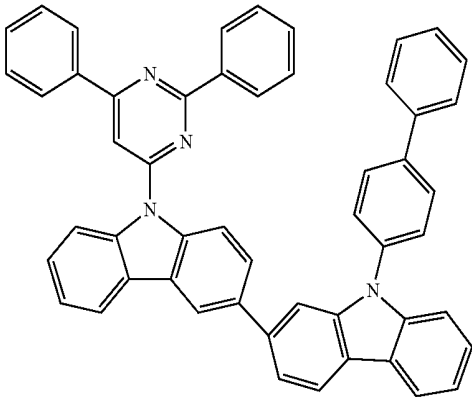
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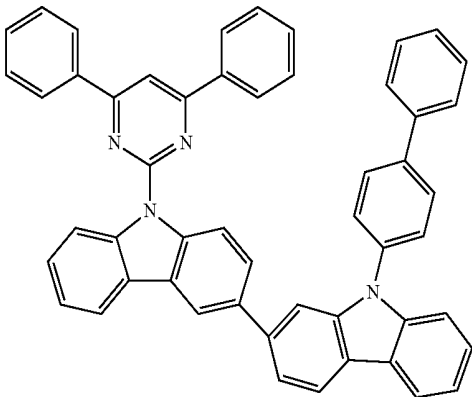
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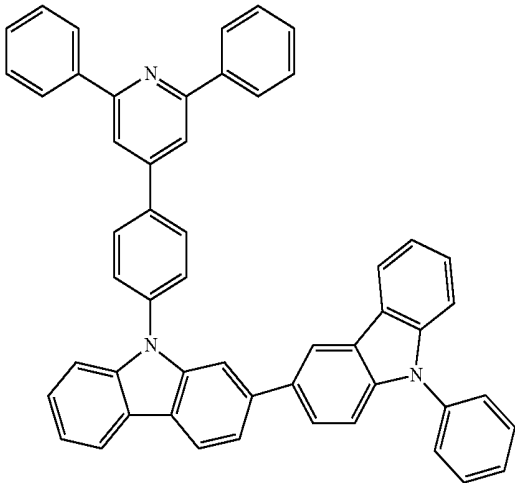
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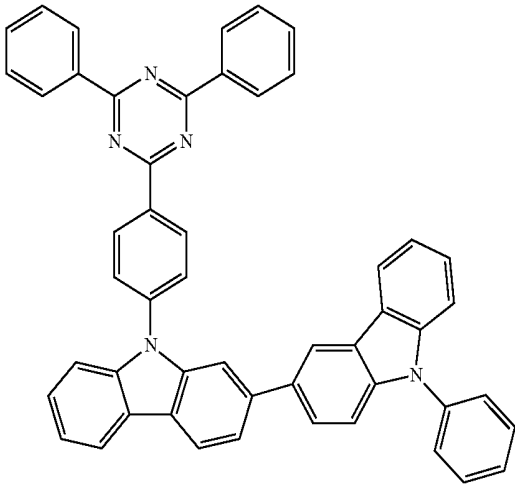
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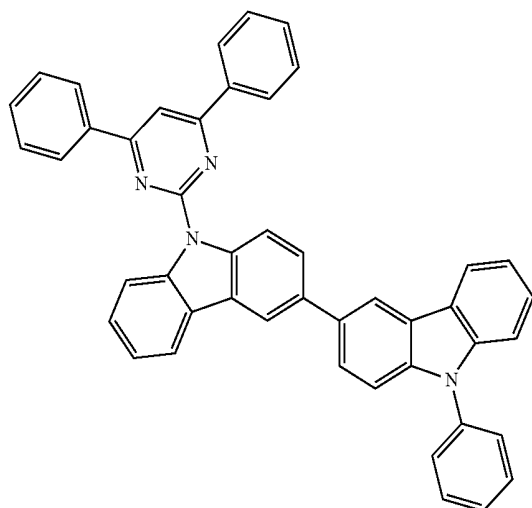


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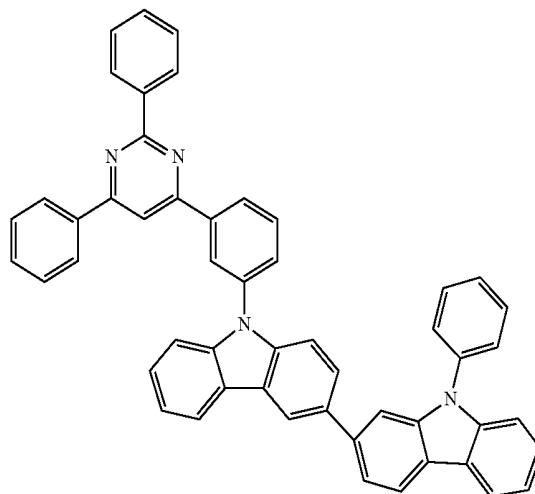
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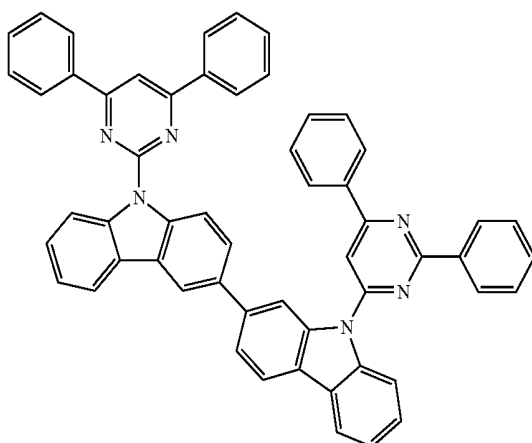


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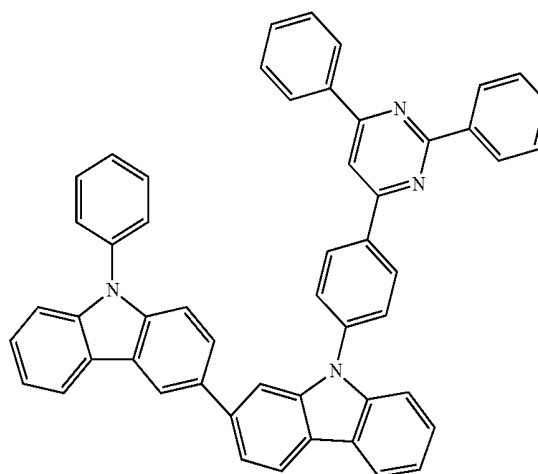
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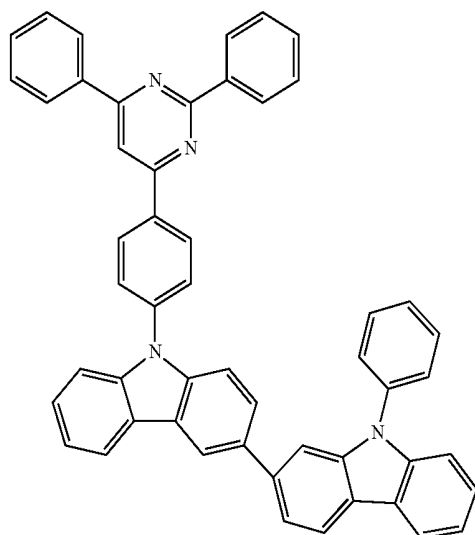
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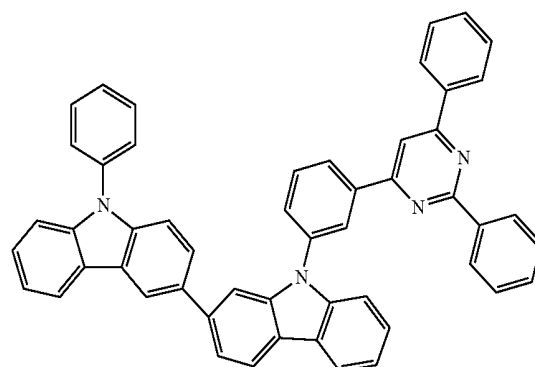
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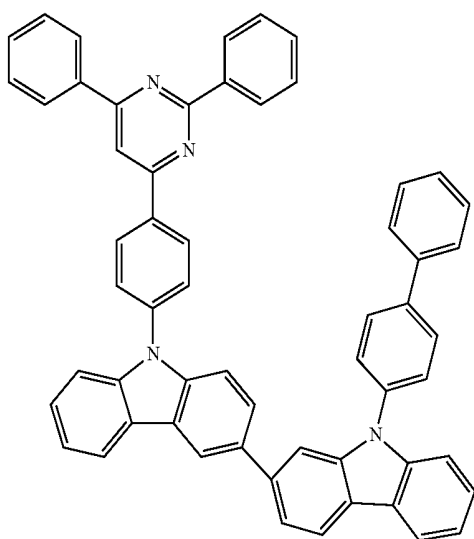
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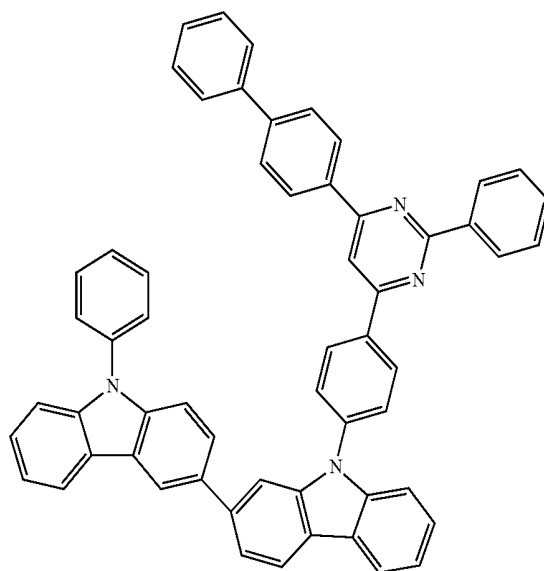


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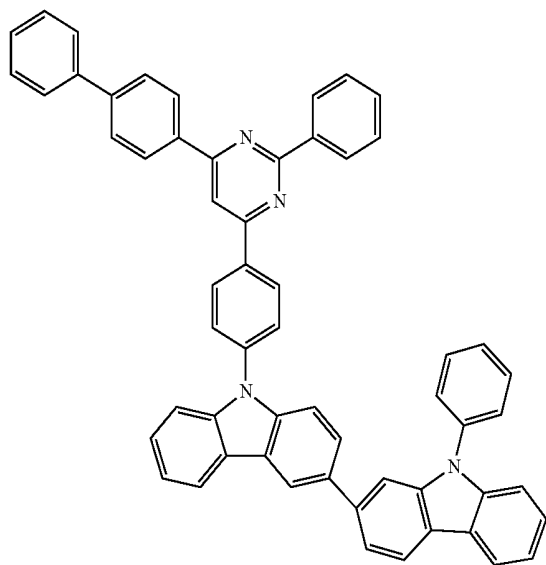


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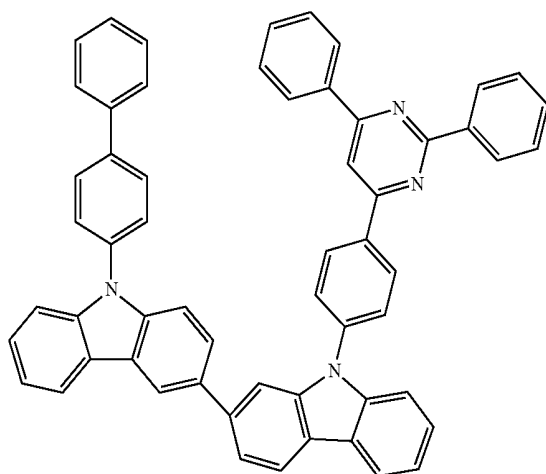
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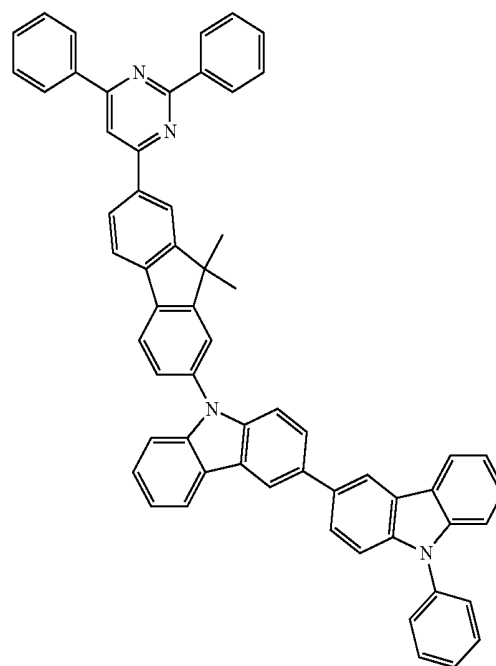
[38]



[36]



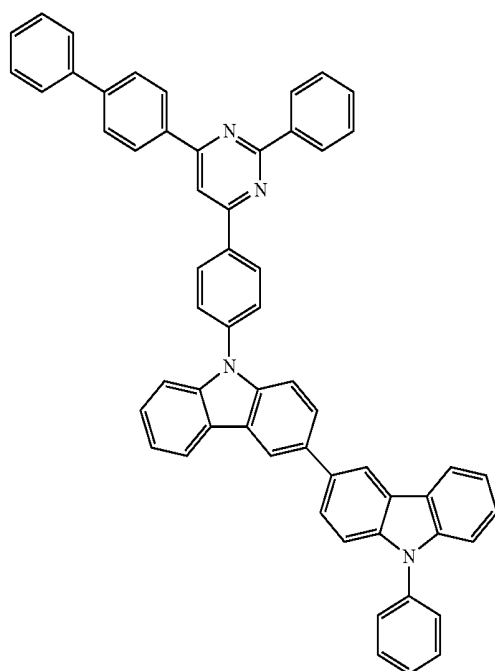
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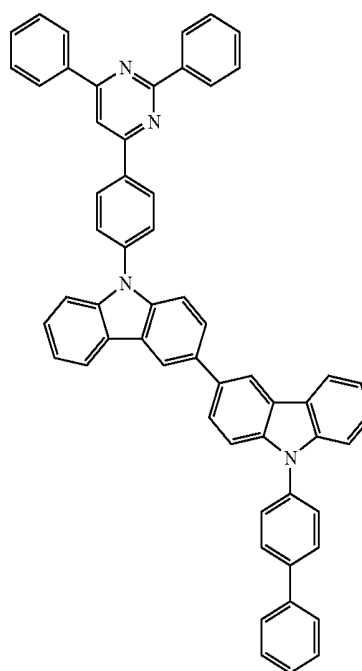
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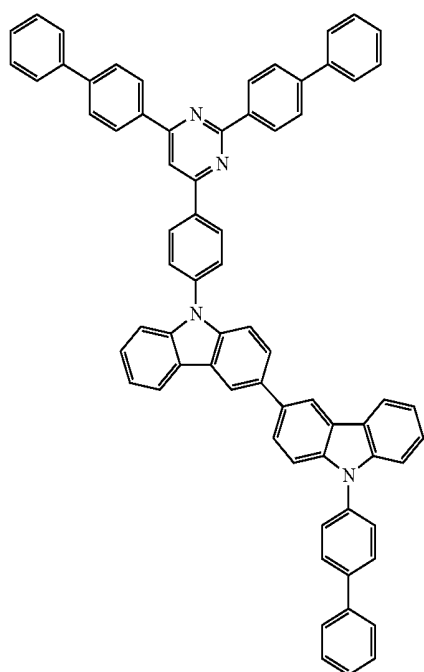


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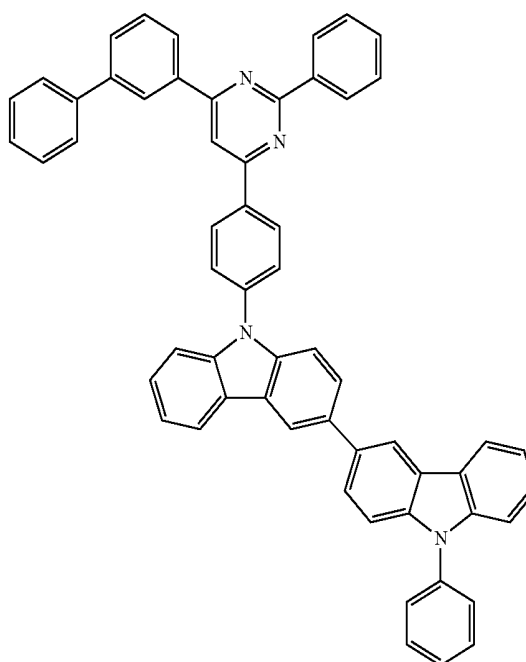
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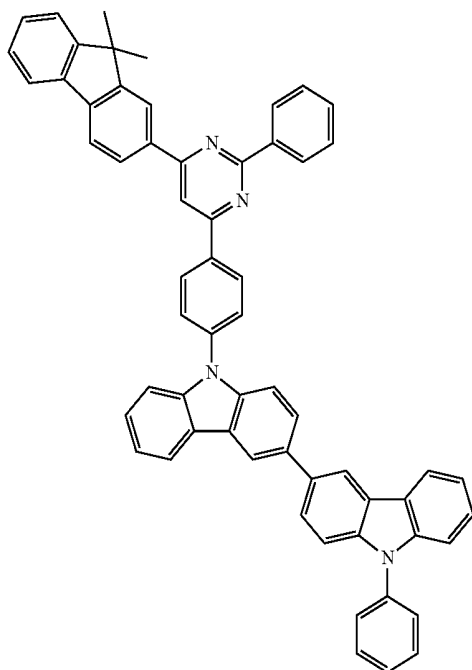
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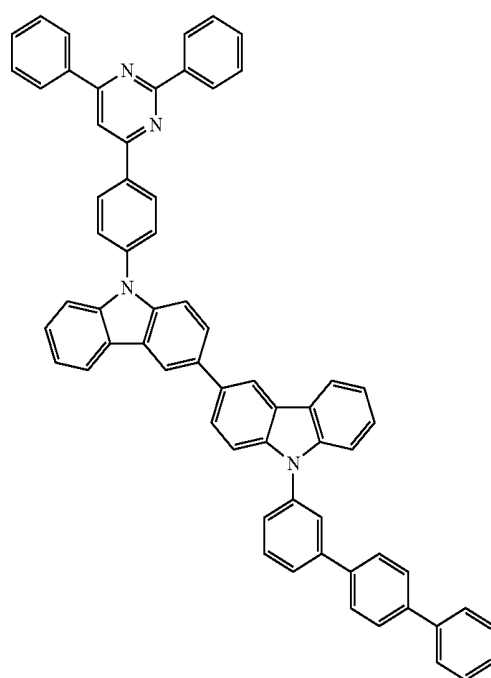
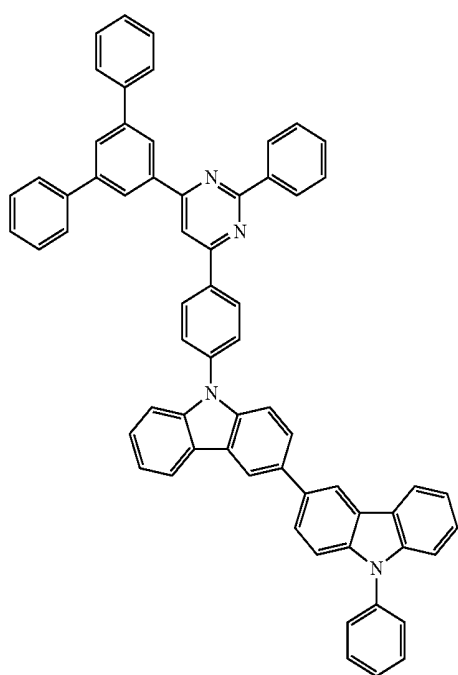
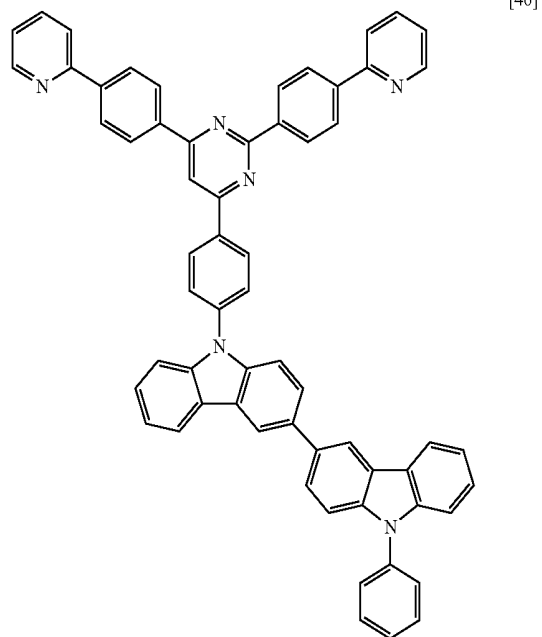
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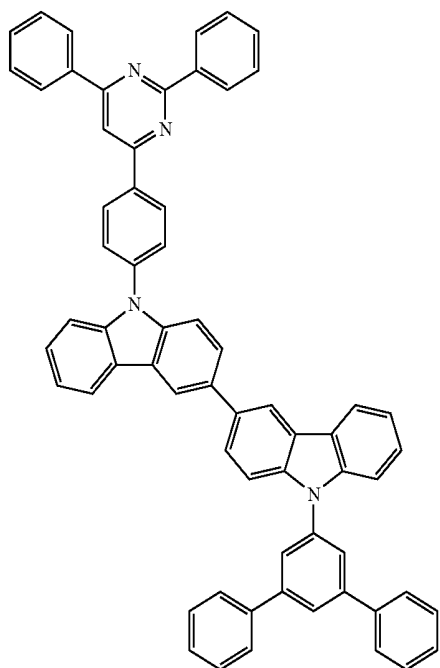
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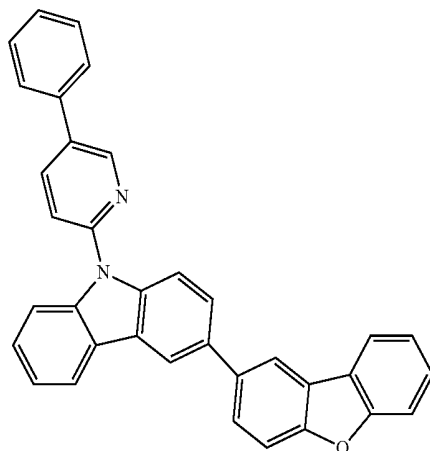
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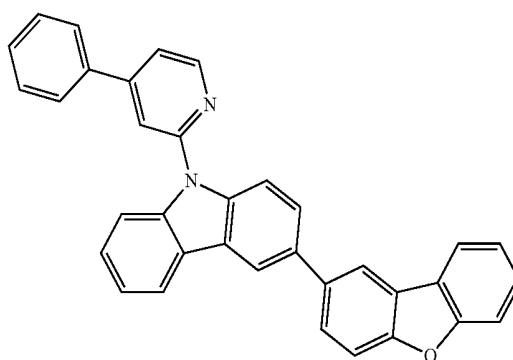
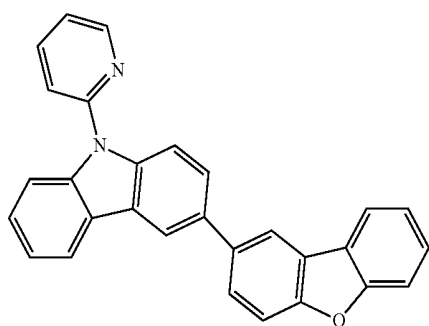
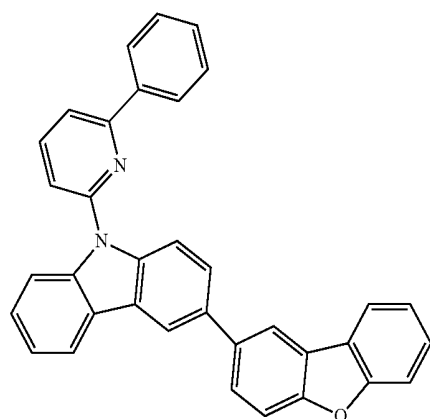
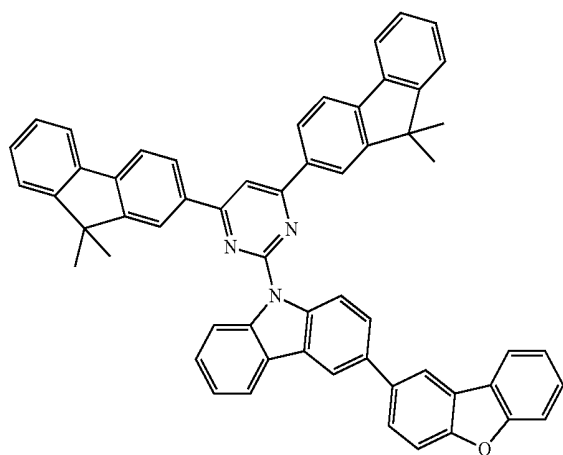
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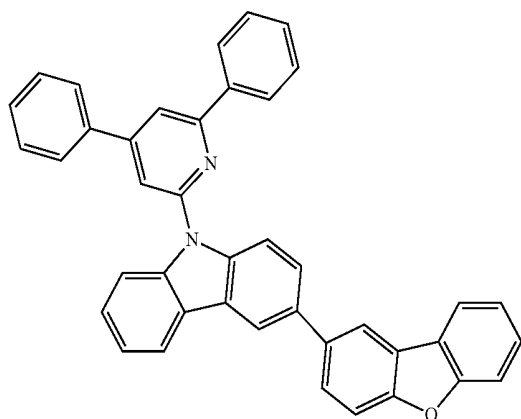


[0013] The compound represented by Chemical Formula 2 may be one of the following Compounds 49 to 73.



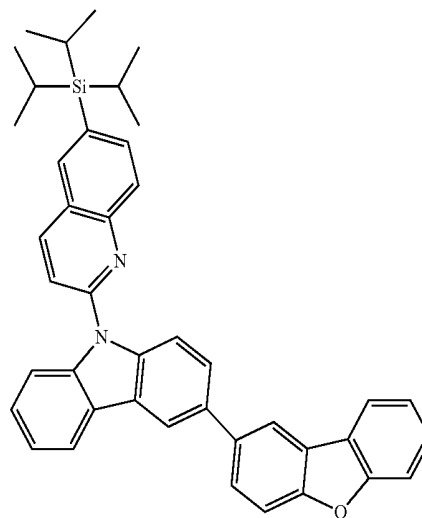
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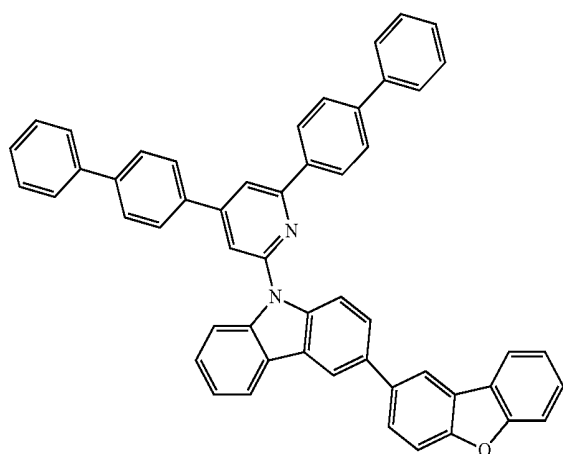


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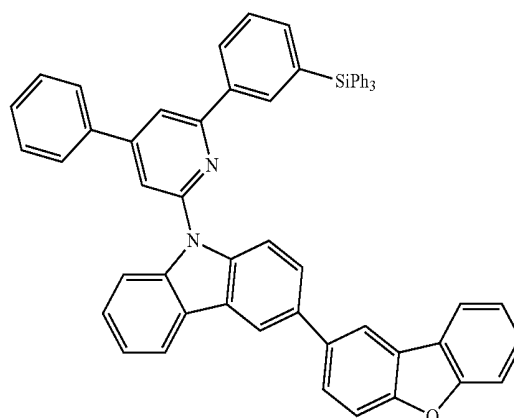
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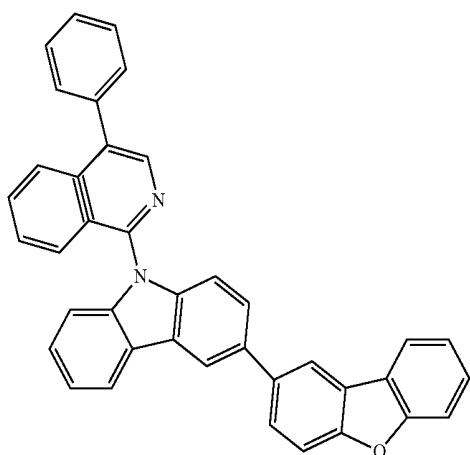
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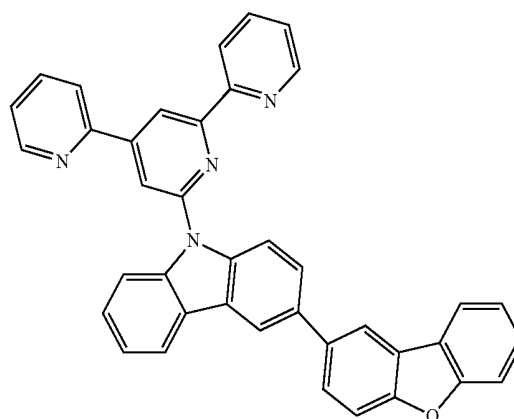
[58]



[56]

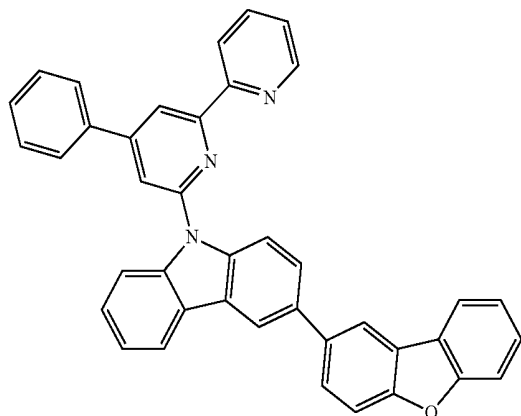


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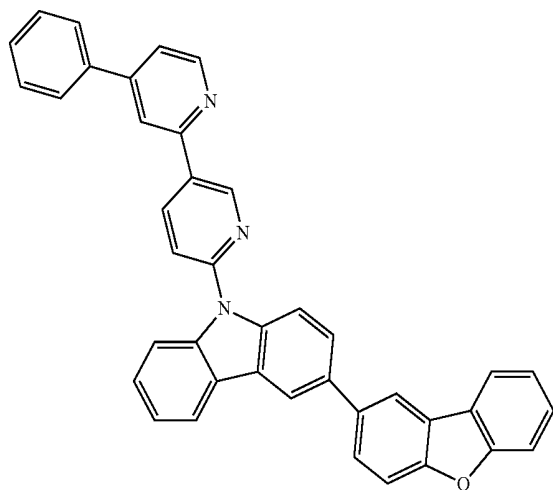


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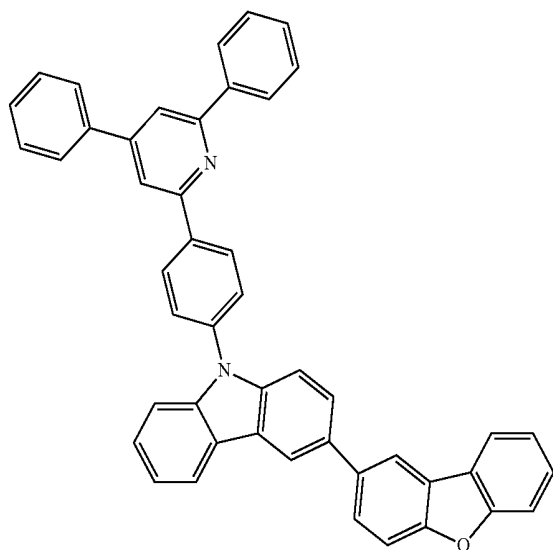
[60]



[61]

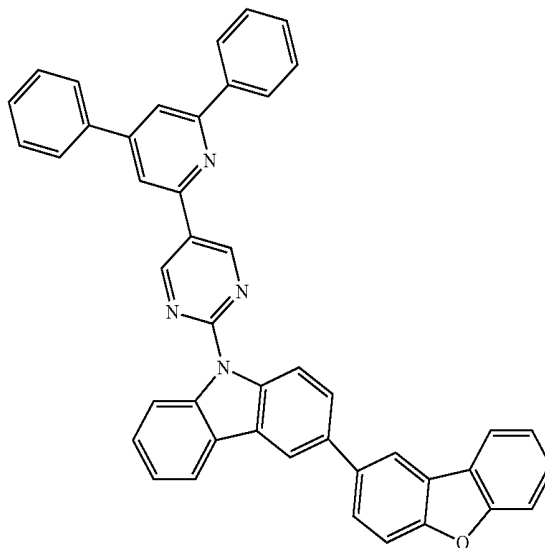


[62]

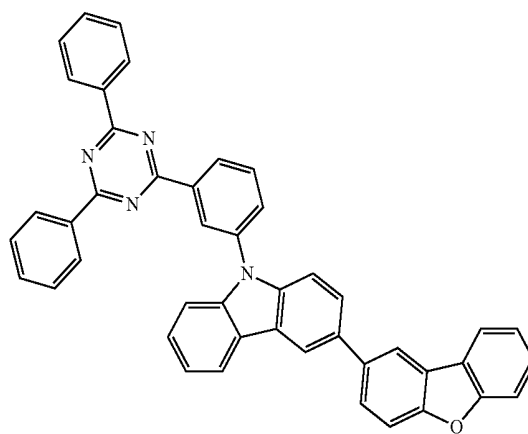


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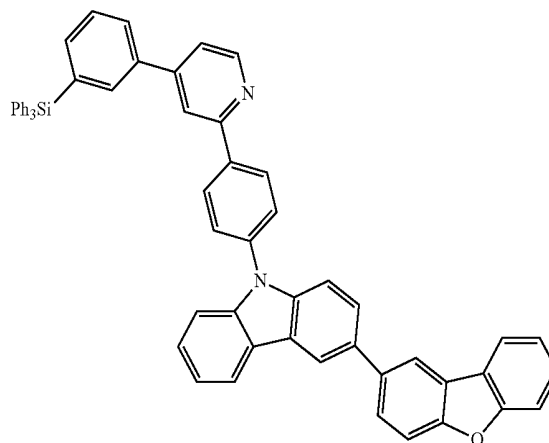
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[64]

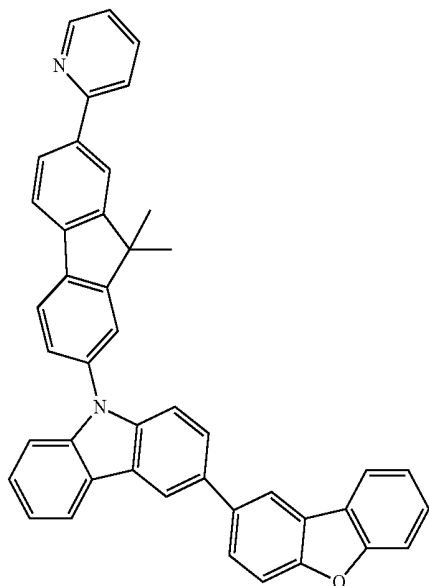


[65]



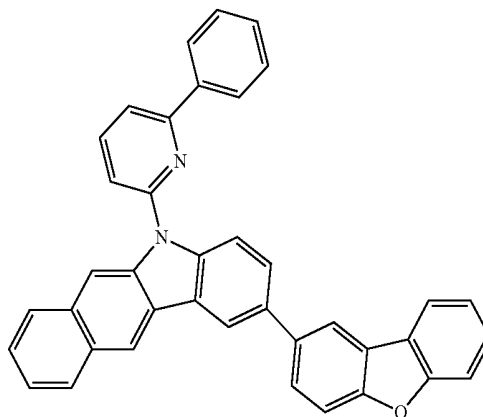
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[66]



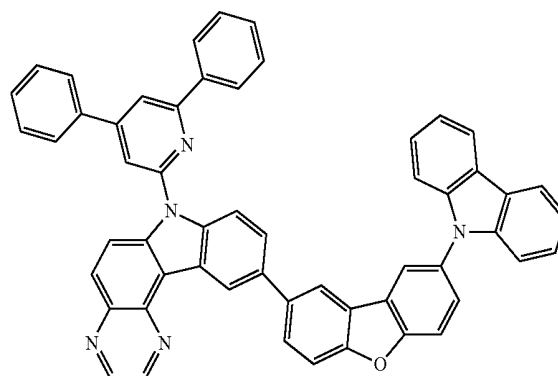
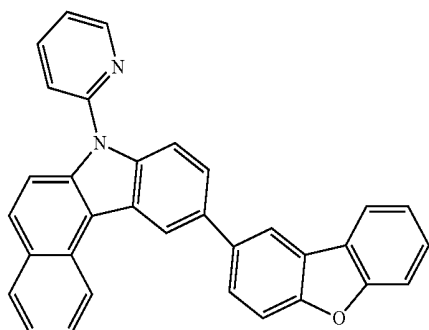
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[69]

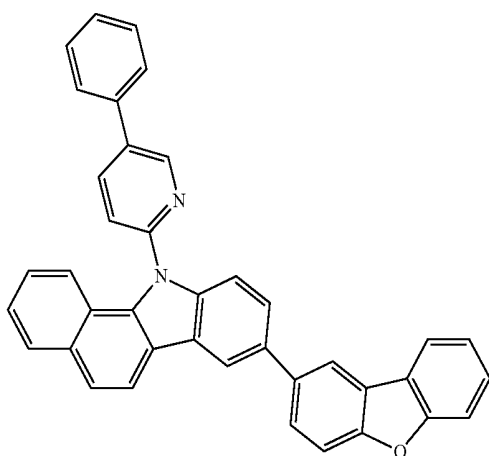


[70]

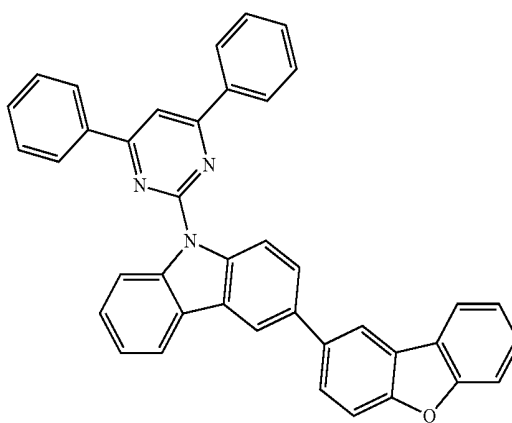
[67]



[68]

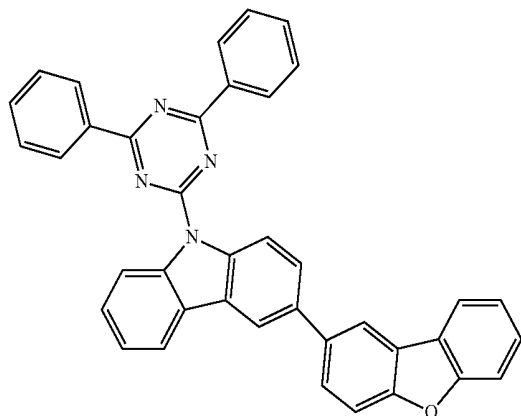


[71]



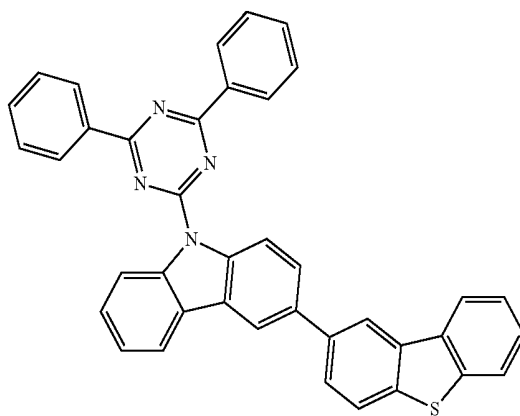
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[72]

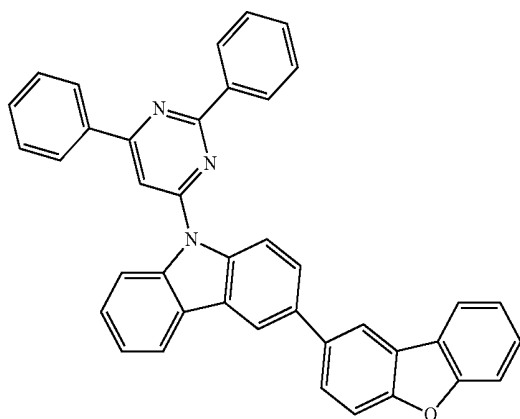


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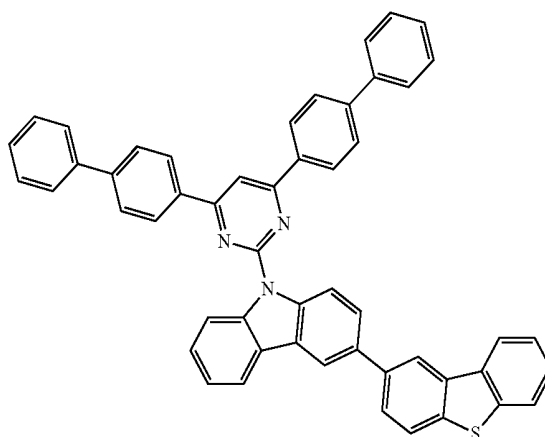
[75]



[73]

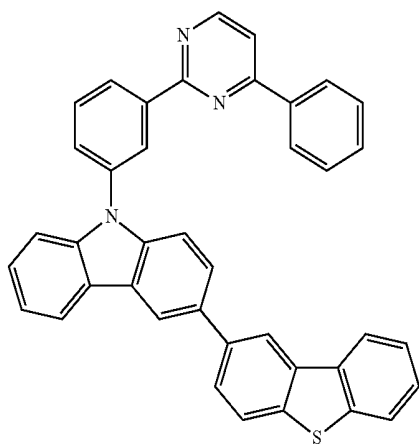


[76]

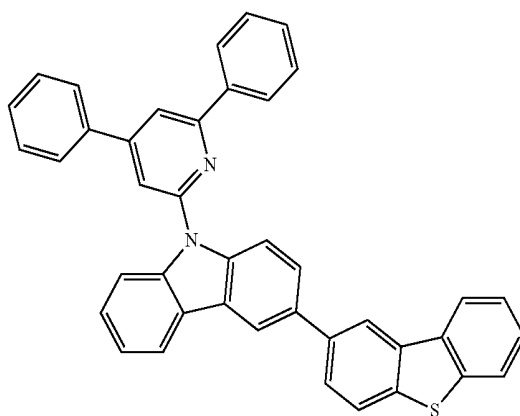


[0014] The compound represented by Chemical Formula 3 may be one of the following Compounds 74 to 78.

[74]

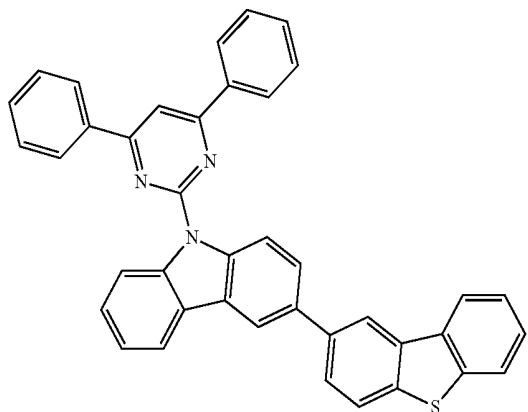


[77]



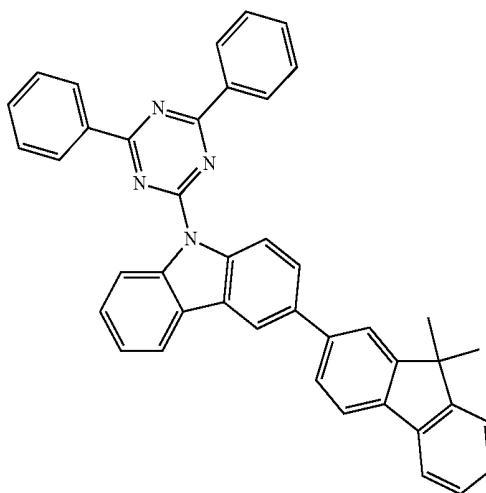
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[78]



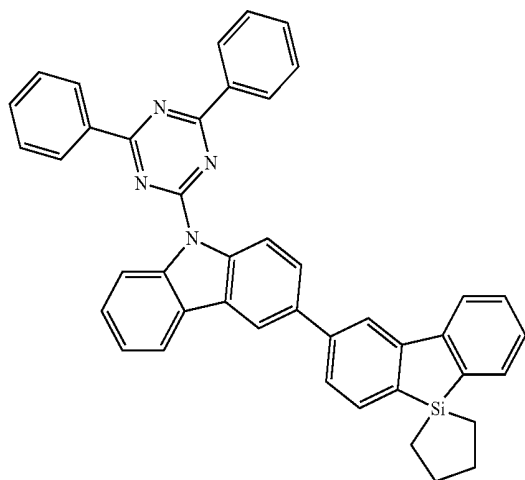
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[81]

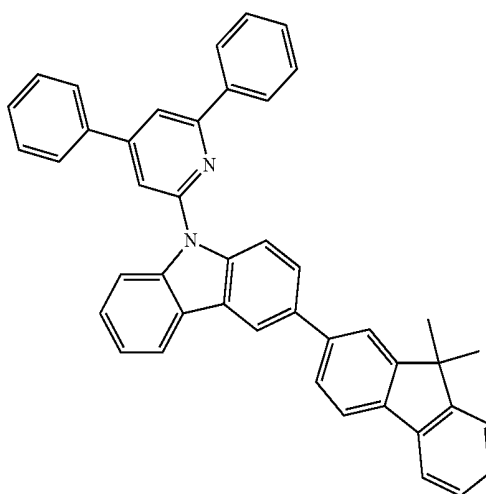


[0015] The compound represented by Chemical Formula 4 may be one of the following Compounds 79 to 84.

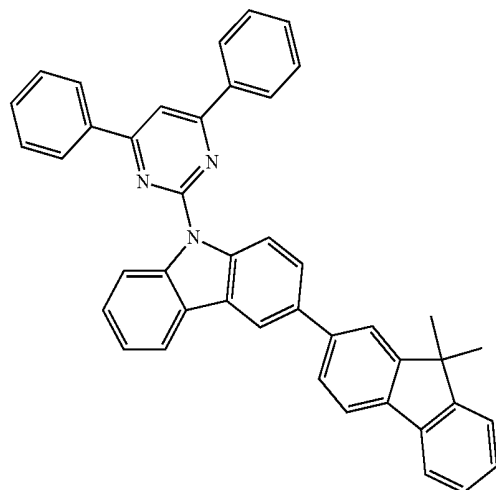
[79]



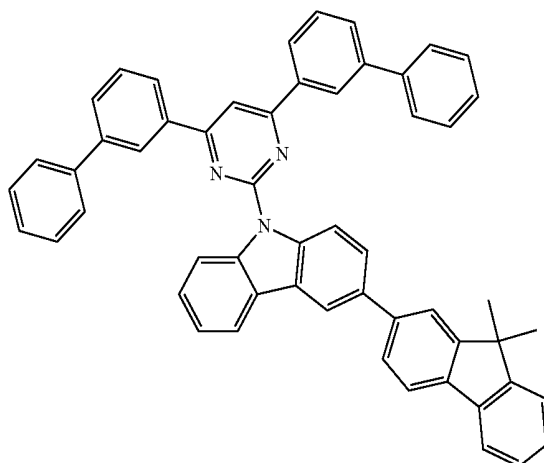
[82]



[80]

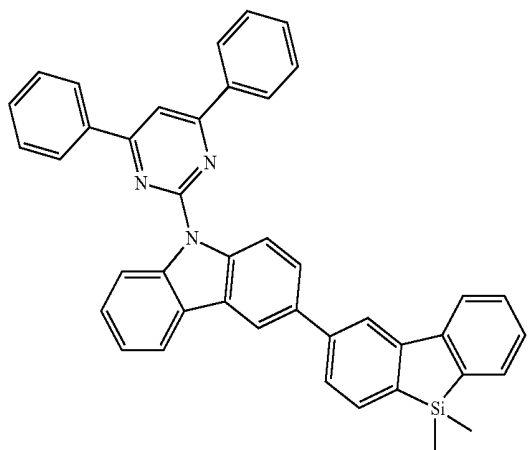


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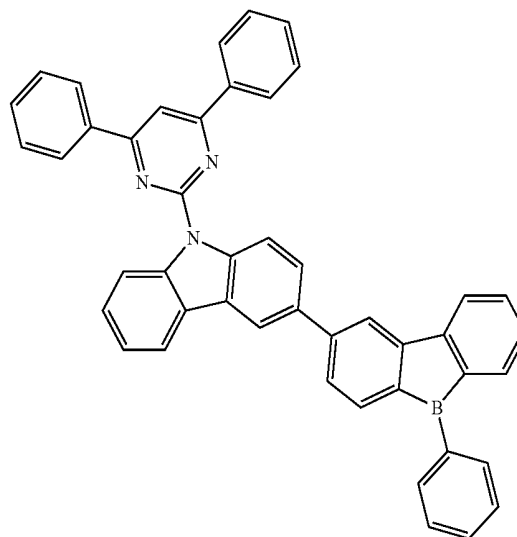
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[84]



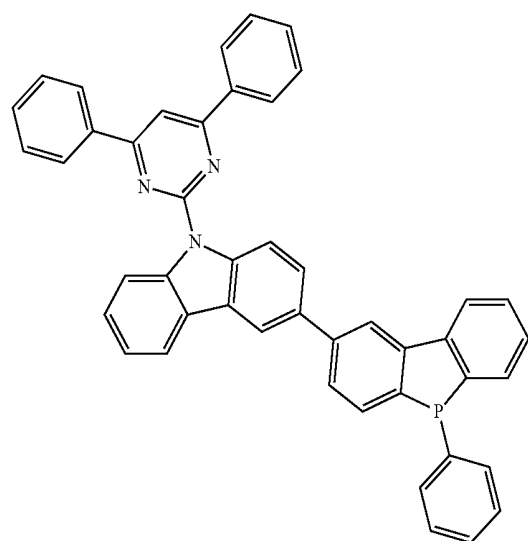
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[87]

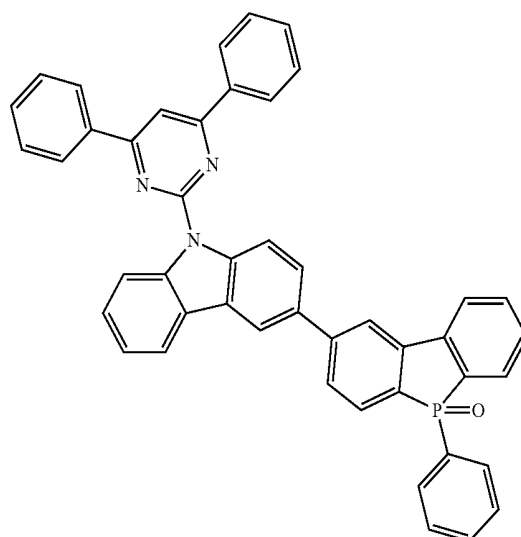
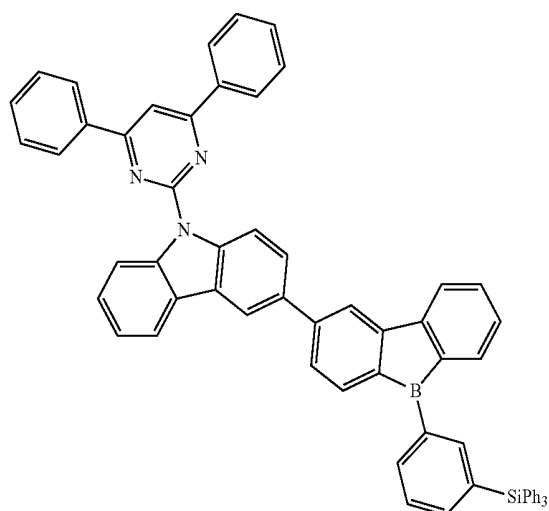


[0016] The compound represented by Chemical Formula 5 may be one of the following Compounds 85 to 88.

[85]



[86]



[88]

[0017] The capping layer may have a refractive index of about 1.9 or higher.

[0018] The capping layer may have a refractive index of about 1.9 to about 3.0.

[0019] The capping layer may have a thickness of about 80 nm to about 900 nm.

[0020] The organic light emitting diode display may further include at least one of a hole injection layer and a hole transporting layer between the first electrode and the organic light emitting layer.

[0021] The organic light emitting diode display may further include at least one of an electron transporting layer and an electron injection layer between the organic light emitting layer and the second electrode.

[0022] The organic light emitting diode display may further include a second substrate on the capping layer, the second substrate being spaced apart from the capping layer.

[0023] The organic light emitting diode display may further include an air layer in a space between the capping layer and the second substrate.

[0024] The organic light emitting diode display may further include a filling member in a space between the capping layer and the second substrate.

[0025] The organic light emitting diode display may further include a thin film encapsulation layer on the capping layer.

BRIEF DESCRIPTION OF THE DRAWINGS

[0026] Features will be apparent to those of skill in the art by describing in detail exemplary embodiments with reference to the attached drawings in which:

[0027] FIG. 1 illustrates a plan view of an organic light emitting diode display (OLED display) according to a first exemplary embodiment;

[0028] FIG. 2 illustrates a cross-sectional view taken along line I-I' of FIG. 1;

[0029] FIG. 3 illustrates a cross-sectional view of an OLED display according to a second exemplary embodiment; and

[0030] FIG. 4 illustrates a cross-sectional view of an OLED display according to a third exemplary embodiment.

DETAILED DESCRIPTION

[0031] Example embodiments will now be described more fully hereinafter with reference to the accompanying drawings; however, they may be embodied in different forms and should not be construed as limited to the embodiments set forth herein. Rather, these embodiments are provided so that this disclosure will be thorough and complete, and will fully convey exemplary implementations to those skilled in the art.

[0032] In the drawing figures, the dimensions of layers and regions may be exaggerated for clarity of illustration. In addition, it will also be understood that when an element is referred to as being “between” two elements, it can be the only element between the two elements, or one or more intervening elements may also be present. Like reference numerals refer to like elements throughout.

[0033] All terminologies used herein are merely used to describe embodiments and may be modified according to the relevant art and the intention of an applicant. Therefore, the terms used herein should be interpreted as having a meaning that is consistent with their meanings in the context of the present disclosure, and is not intended to limit the present disclosure.

[0034] In addition, when a layer or element is referred to as being “on” another layer or element, the layer or element may be directly on the other layer or element, or one or more intervening layers or elements may be interposed therebetween.

[0035] Hereinafter, a first exemplary embodiment will be described with reference to FIGS. 1 and 2.

[0036] FIG. 1 illustrates a plan view of an organic light emitting diode display (OLED display) 101 according to the first exemplary embodiment. FIG. 2 illustrates a cross-sectional view taken along line I-I' of FIG. 1.

[0037] As illustrated in FIGS. 1 and 2, the OLED display 101 according to the first exemplary embodiment may include a first substrate 110, a wiring unit 130, an organic light emitting diode (OLED) 210, a capping layer 230, and a second substrate 410.

[0038] The first substrate 110 may include an insulating material of, e.g., glass, quartz, ceramic, plastic, or the like. In an implementation, the first substrate 110 may include a metal material such as stainless steel and the like.

[0039] A buffer layer 120 may be disposed on the first substrate 110. The buffer layer 120 may include at least one layer of various inorganic and organic layers. The buffer layer 120 may help prevent or efficiently reduce infiltration of undesirable elements, such as moisture, into the wiring unit 130 and the OLED 210, and may planarize the surface of the first substrate 110. In an implementation, the buffer layer 120 may be omitted.

[0040] The wiring unit 130 may be disposed on the buffer layer 120. The wiring unit 130 may refer to a structure including a switching thin film transistor (TFT) 10, a driving TFT 20, and a capacitor 80, and may drive the OLED 210. The OLED 210 may emit light according to a driving signal supplied from the wiring unit 130 to thereby display images.

[0041] FIGS. 1 and 2 illustrate an active-matrix (AM)-type OLED display 101 having a 2Tr-1Cap structure. For example, the 2Tr-1Cap structure may include two TFTs 10 and 20 and a capacitor 80 in each pixel. In an implementation, the display according to an exemplary embodiment may include three or more TFTs and two or more capacitors 80 in one pixel, and may further include additional lines. Herein, the term “pixel” refers to the smallest unit for displaying an image, and the OLED display 101 displays an image using a plurality of pixels.

[0042] Each pixel may include the switching TFT 10, the driving TFT 20, the capacitor 80, and the OLED 210. Further, a gate line 151 disposed along one direction, a data line 171 and a common power line 172 insulated from and intersecting the gate line 151 may be further disposed on the wiring unit 130. Herein, each pixel may be defined by the gate line 151, the data line 171, and the common power line 172, but is not limited thereto. In an implementation, pixels may be defined by a black matrix and/or a pixel defining layer (PDL).

[0043] The OLED 210 may include a first electrode 211, an organic light emitting layer 212 on the first electrode 211, and a second electrode 213 on the organic light emitting layer 212. A hole and an electron may be respectively supplied from the first electrode 211 and the second electrode 213 into the organic light emitting layer 212, and then combined with each other therein to form an exciton. The OLED may emit light by energy generated when the exciton falls from an excited state to a ground state.

[0044] The capacitor 80 may include a pair of capacitor plates 158 and 178 with an interlayer insulating layer 145 interposed therebetween. Herein, the interlayer insulating layer 160 may be a dielectric. Capacitance of the capacitor 80 may be determined by electric charges accumulated in the capacitor 80 and voltage across the pair of capacitor plates 158 and 178.

[0045] The switching TFT 10 may include a switching semiconductor layer 131, a switching gate electrode 152, a switching source electrode 173, and a switching drain electrode 174. The driving TFT 20 may include a driving semiconductor layer 132, a driving gate electrode 155, a driving source electrode 176, and a driving drain electrode 177. Further, a gate insulating layer 140 may be further provided to insulate the semiconductor layers 131 and 132 and the gate electrodes 152 and 155.

[0046] The switching TFT 10 may function as a switching element which selects a pixel to perform light emission. The switching gate electrode 152 may be connected to the gate line 151, and the switching source electrode 173 may be connected to the data line 171. The switching drain electrode

174 may be spaced apart from the switching source electrode **173** and connected to a capacitor plate **158**.

[0047] The driving TFT **20** may apply a driving power, which allows the organic light emitting layer **212** of the OLED **210** in a selected pixel to emit light, to the first electrode **210** serving as a pixel electrode. The driving gate electrode **155** may be connected to the capacitor plate **158** that is connected to the switching drain electrode **174**. The driving source electrode **176** and the other capacitor plate **178** may be respectively connected to the common power line **172**. The driving drain electrode **177** may be connected to the first electrode **211** of the OLED **210** through a contact hole.

[0048] With the aforementioned structure, the switching TFT **10** may be operated by a gate voltage applied to the gate line **151** and may function to transmit a data voltage applied to the data line **171** to the driving TFT **20**. A voltage equivalent to a difference between a common voltage applied from the common power line **172** to the driving TFT **20** and the data voltage transmitted by (or from) the switching TFT **10** may be stored in the capacitor **80**, and a current corresponding to the voltage stored in the capacitor **80** may flow to the OLED **200** through the driving TFT **20**, so that the OLED **210** may emit light.

[0049] According to the first exemplary embodiment, the first electrode **211** may serve as an anode to inject holes, and the second electrode **213** may serve as a cathode to inject electrons. In an implementation, the first electrode **211** may serve as a cathode and the second electrode **213** may serve as an anode.

[0050] The planarizing layer **146** may be disposed on an interlayer insulating layer **145**. The planarizing layer **146** may include insulating materials and may protect the wiring unit **130**. The planarizing layer **146** and the interlayer insulating layer **145** may include the same material.

[0051] The drain electrode **177** of the driving TFT **20** may be connected to the first electrode **211** of the OLED **210** through a contact hole formed on the planarizing layer **146**.

[0052] According to the first exemplary embodiment, the first electrode **211** may be a reflective electrode and the second electrode **213** may be a transfective electrode. Therefore, light generated in the organic light emitting layer **212** may pass through the second electrode **213** for light emission. Accordingly, the OLED display **101** according to the first exemplary embodiment may have a top-emission type structure.

[0053] One or more metal of magnesium (Mg), silver (Ag), gold (Au), calcium (Ca), lithium (Li), chromium (Cr), aluminum (Al), and copper (Cu), or a metal alloy thereof may be used to form the reflective electrode and/or the transfective electrode.

[0054] For example, the first electrode **211** may include a reflective layer including at least one metal of magnesium (Mg), silver (Ag), gold (Au), calcium (Ca), lithium (Li), chromium (Cr), aluminum (Al), and copper (Cu), and a transparent conductive layer disposed on the reflective layer. Herein, the transparent conductive layer may include a transparent conductive oxide (TCO), e.g., at least one of indium tin oxide (ITO), indium zinc oxide (IZO), zinc oxide (ZnO), aluminum zinc oxide (AZO), and indium oxide (In₂O₃). Such transparent conductive layer may have a relatively high work function, thereby allowing more active hole injection through the first electrode **211**.

[0055] Further, the first electrode **211** may have a triple-layer structure including a transparent conductive layer, a reflective layer, and a transparent conductive layer that are sequentially laminated.

[0056] In an implementation, the second electrode **213** may be formed of a transfective layer including one or more metal of magnesium (Mg), silver (Ag), gold (Au), calcium (Ca), lithium (Li), chromium (Cr), aluminum (Al), and copper (Cu).

[0057] In an implementation, at least one of a hole injection layer HIL and a hole transporting layer HTL may be further disposed between the first electrode **211** and the organic light emitting layer **212**. In an implementation, at least one of an electron transporting layer ETL and an electron injection layer EIL may be further disposed between the organic light emitting layer **212** and the second electrode **213**.

[0058] A structure including the organic light emitting layer **212**, the hole injection layer HIL, the hole transporting layer HTL, the electron transporting layer ETL, and the electron injection layer EIL may be referred to as an organic layer. The organic layer may include a low molecular weight organic material or a high molecular weight organic material.

[0059] The pixel defining layer **190** may have an aperture, and the first electrode **211** may be at least partially exposed through the aperture of the pixel defining layer **190**. The first electrode **211**, the organic light emitting layer **212**, and the second electrode **213** may be sequentially laminated within the aperture of the pixel defining layer **190**. In an implementation, the second electrode **213** may be also disposed on the pixel defining layer **190** as well as on the organic light emitting layer **212**. The pixel defining layer **190** may define a light emission area.

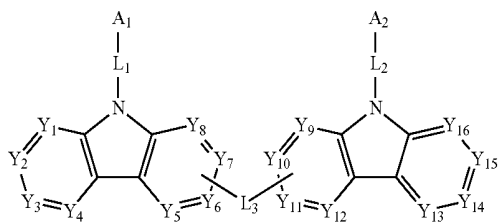
[0060] The capping layer **230** may be disposed on the OLED **210**. The capping layer **230** may basically protect the OLED **210**, and may also allow light emitted in the organic light emitting layer **212** to be efficiently directed outwards.

[0061] The capping layer **230** may include a compound that includes a carbazole group or moiety. For example, the capping layer **230** according to the first exemplary embodiment may include at least one heterocyclic compound that includes a carbazole group or moiety and a heterocyclic group or moiety bonded with the carbazole group or moiety.

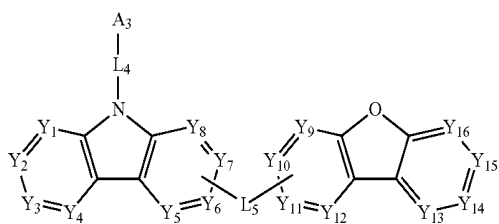
[0062] For example, the heterocyclic group may function as an electron withdrawing group, and the carbazole group may function as an electron donation group. Accordingly, the heterocyclic compound including both the carbazole group and the heterocyclic group bonded with the carbazole group may have dipole moments. The capping layer **230** including such a heterocyclic compound may have a high refractive index, e.g., of higher than about 1.9. For example, the capping layer **230** may have a refractive index of about 1.9 to about 3.0. When the capping layer **230** has a high refractive index, light may be reflected from an interlayer of the capping layer **230** or may be reflected at an interface of the capping layer **230** and another layer or space, such that light resonance may occur.

[0063] The heterocyclic compound that includes a carbazole group and a heterocyclic group bonded with a carbazole group may be represented by one of the following Chemical Formulae 1 to 5.

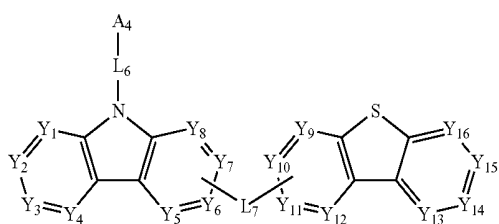
[Chemical Formula 1]



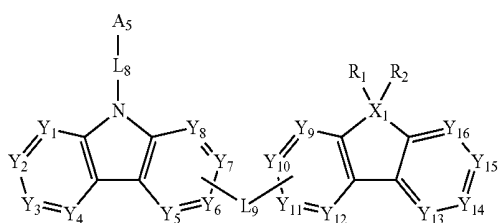
[Chemical Formula 2]



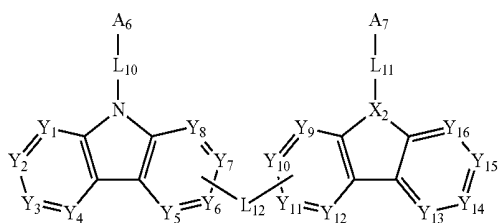
[Chemical Formula 3]



[Chemical Formula 4]



[Chemical Formula 5]



[0064] A_1 to A_7 may each independently be or include, e.g., a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms or a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms. In an implementation, one of A_1 and A_3 to A_6 may be or include, e.g., the substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms.

[0065] Y_1 to Y_{16} may each independently be C—R or a nitrogen atom.

[0066] Each R (of C—R) may independently be or include, e.g., a hydrogen atom, a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms, a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms and forming a linear, branched, or cyclic structure, a substituted or unsubstituted alkoxy group having 1 to 30 carbon atoms, a substituted or

unsubstituted aryloxy group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aralkyl group having 7 to 30 carbon atoms, a substituted or unsubstituted haloalkyl group having 1 to 30 carbon atoms, a substituted or unsubstituted haloalkoxy group having 1 to 30 carbon atoms, a substituted or unsubstituted alkylsilyl group having 3 to 30 carbon atoms, a substituted or unsubstituted dialkylarylsilyl group having 8 to 40 carbon atoms, a substituted or unsubstituted alkylarylsilyl group having 13 to 50 carbon atoms, a substituted or unsubstituted triarylsilyl group having 18 to 60 carbon atoms, a substituted or unsubstituted alkenyl group having 2 to 30 carbon atoms, a substituted or unsubstituted alkynyl group having 2 to 30 carbon atoms, a halogen atom, a cyano group, a hydroxyl group, a nitro group, or a carboxyl group.

[0067] When R is provided in plural, each R may be identical to or different from each other. In an implementation, when two elements of Y_1 through Y_{16} adjacent to each other are C—R, R of the adjacent C—R may be separate or may be combined to form a cyclic structure.

[0068] L_1 to L_{12} may each independently be, e.g., a single bond or a connecting group. In an implementation, the connecting group may include, e.g., an arylene group (such as a phenylene group, a biphenylene group, a terphenylene group, a fluorenylene group, or the like) or a heteroarylene group (such as a pyridine group, a diazine group, a triazine group, a quoline group, an isoquinoline group, or the like).

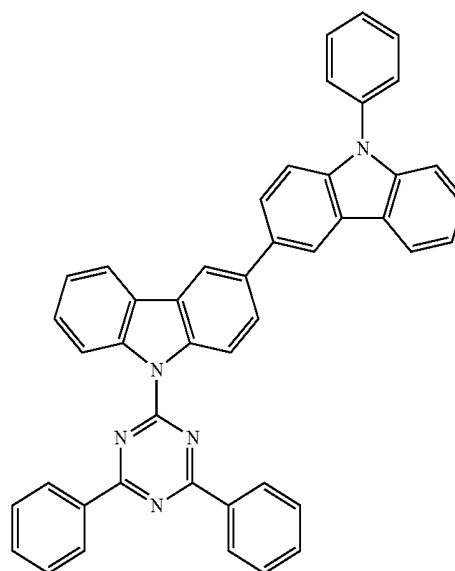
[0069] X_1 may be, e.g., carbon (C) or silicon (Si).

[0070] R_1 and R_2 may each independently be or include, e.g., a hydrogen atom, a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms, or a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms. In an implementation, R_1 and R_2 may be separate or may be bonded together to form a cyclic structure.

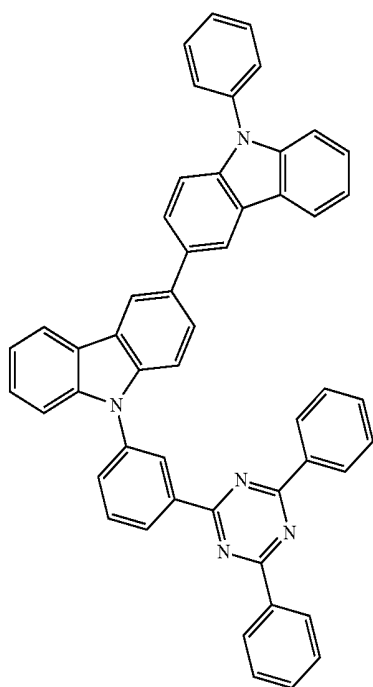
[0071] X_2 may be, e.g., boron (B), phosphorus (P), or P=O.

[0072] In an implementation, the compound represented by Chemical Formula 1 may be one of the following Compounds 1 to 48.

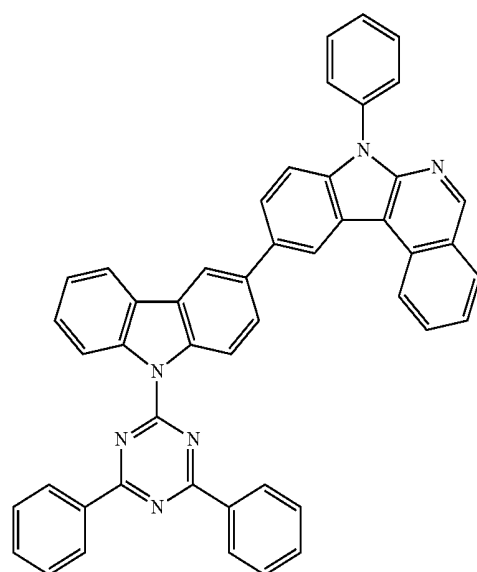
[1]



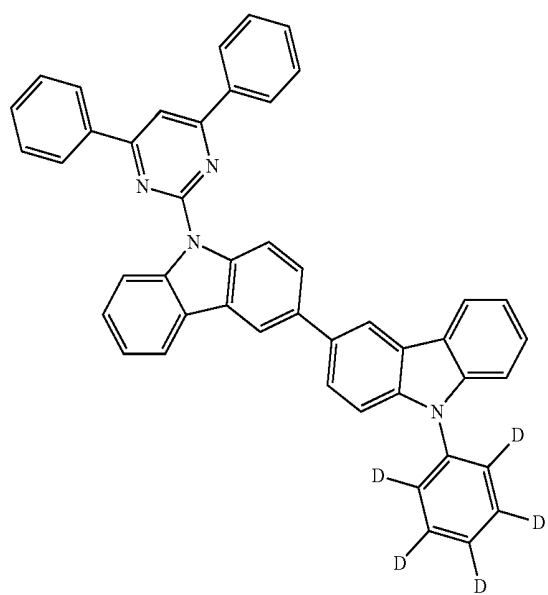
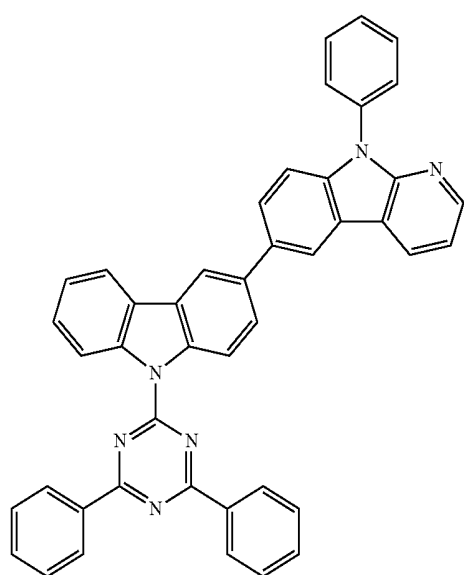
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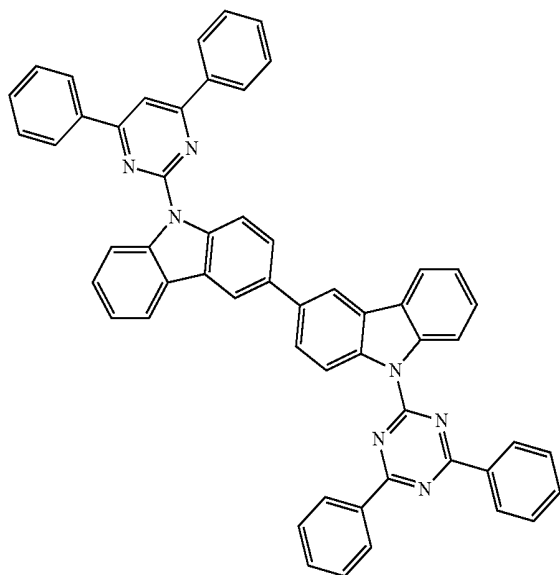


[5]



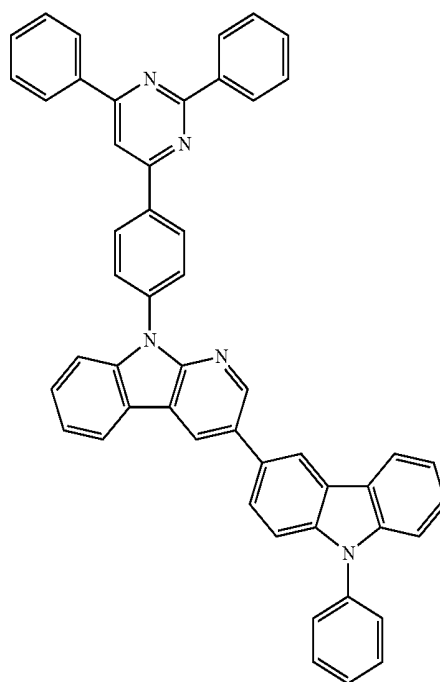
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[6]

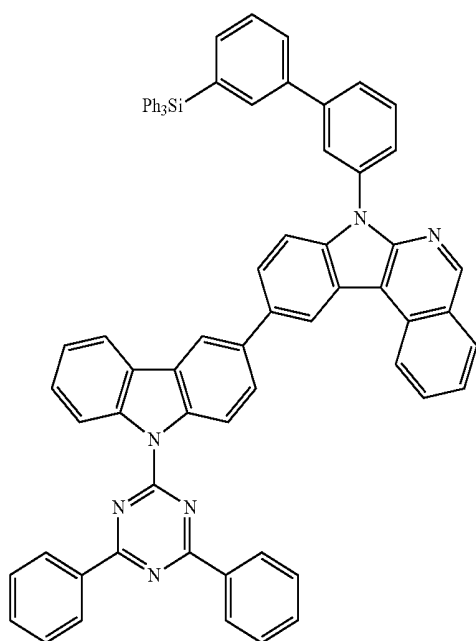


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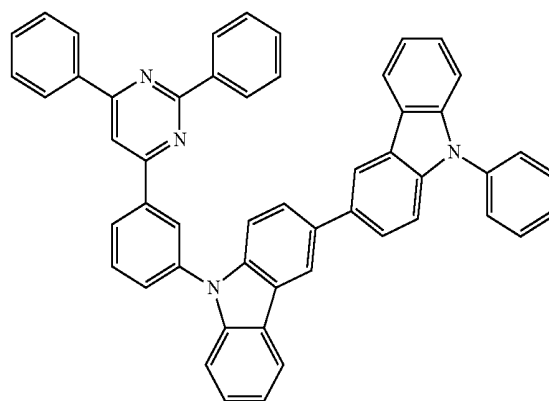
[8]



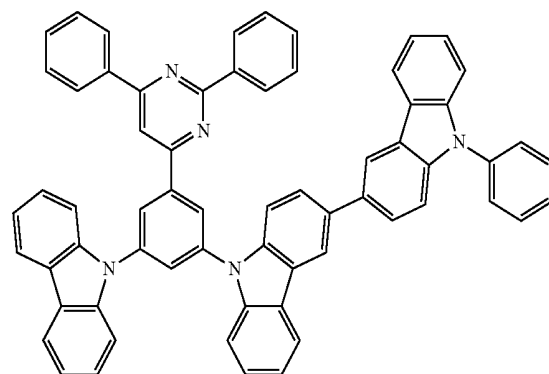
[7]



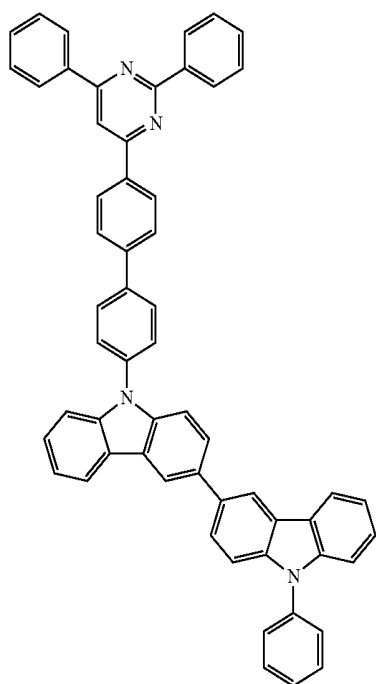
[9]



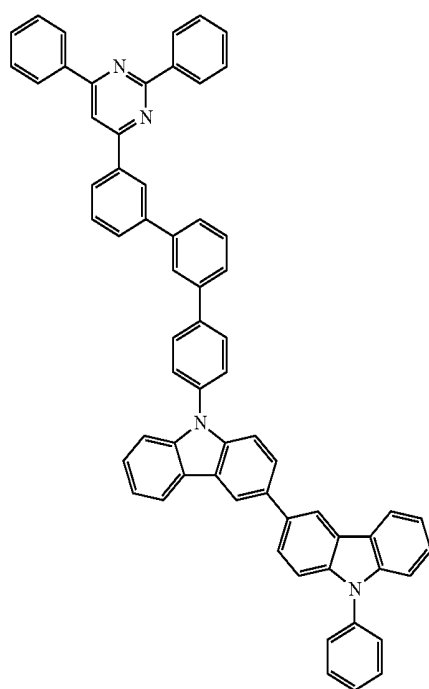
[10]



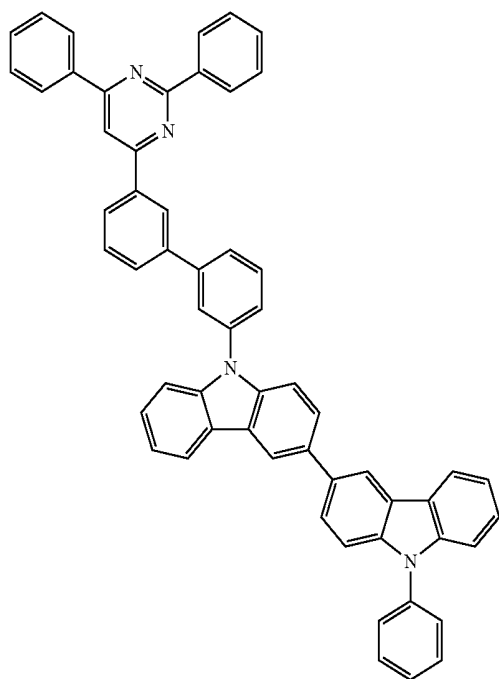
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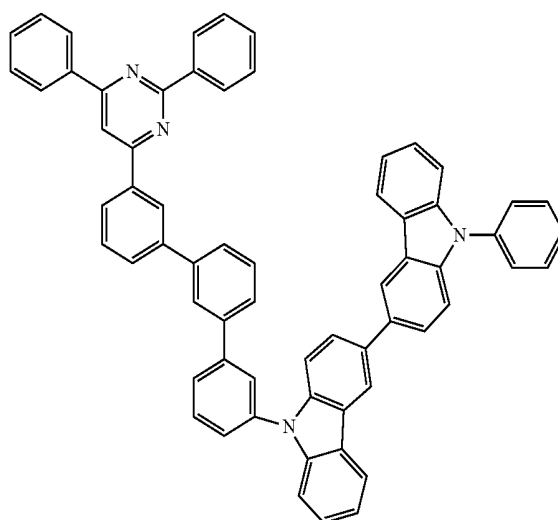
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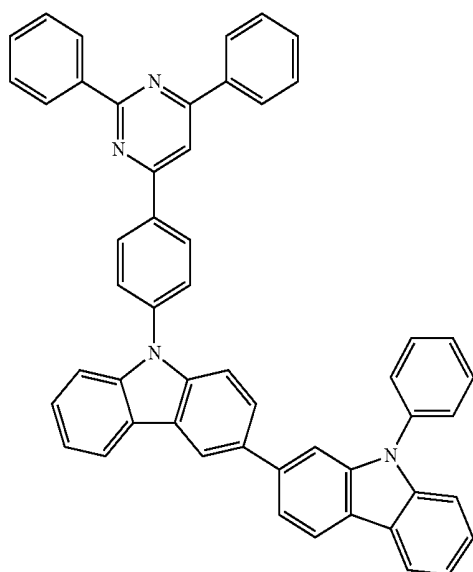
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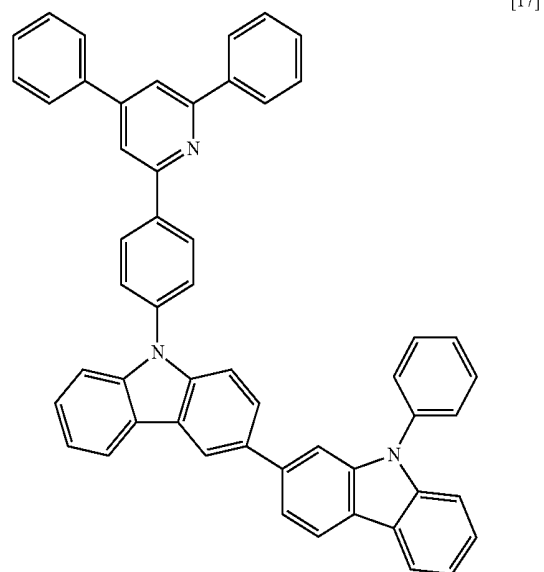
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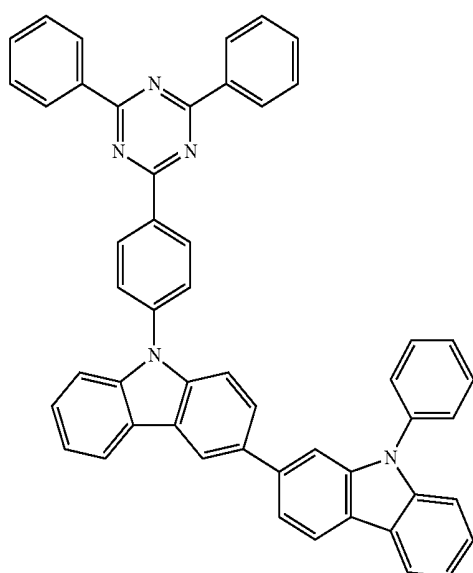
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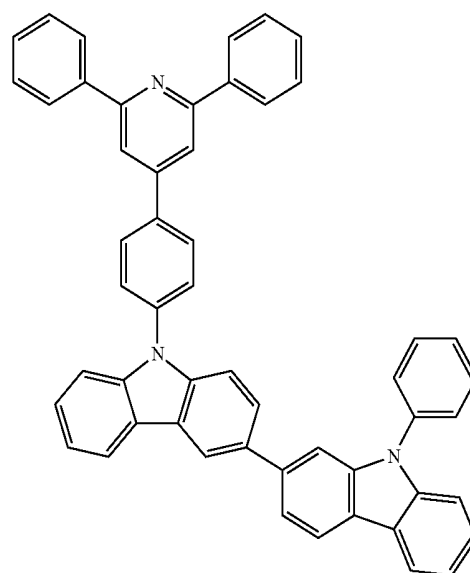
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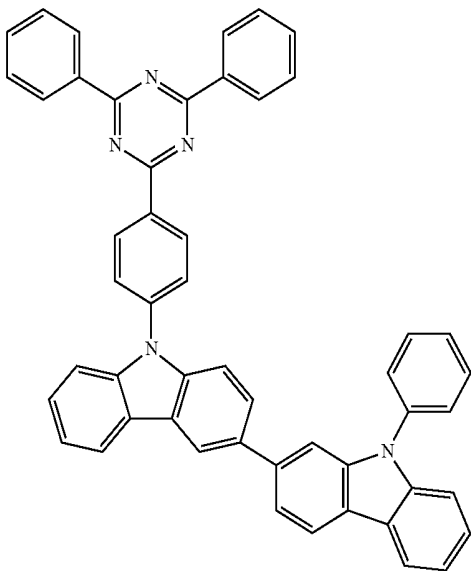


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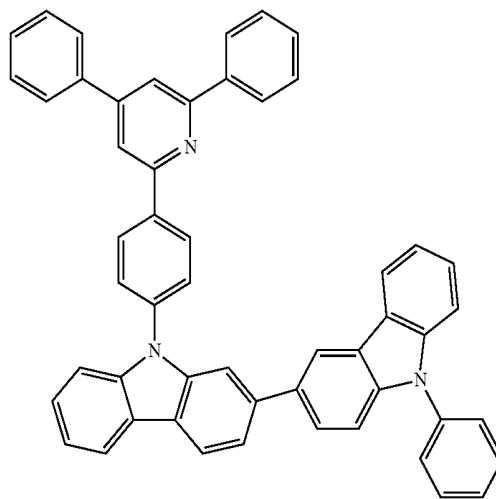
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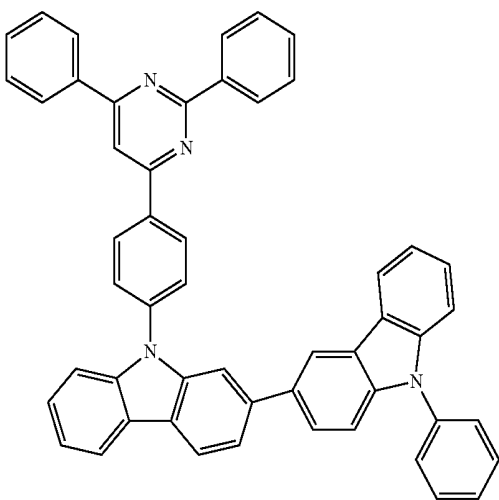


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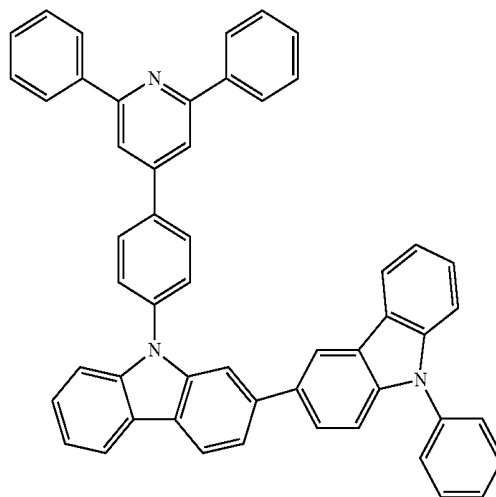
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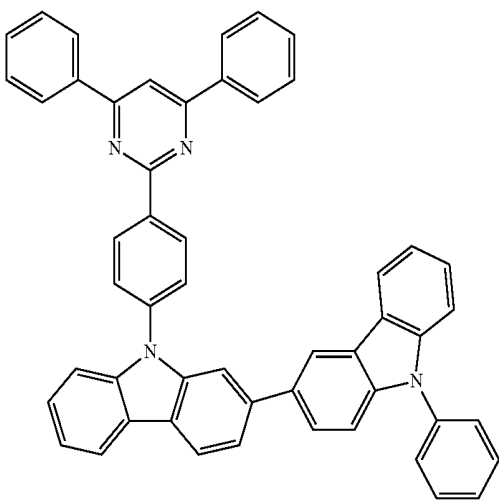
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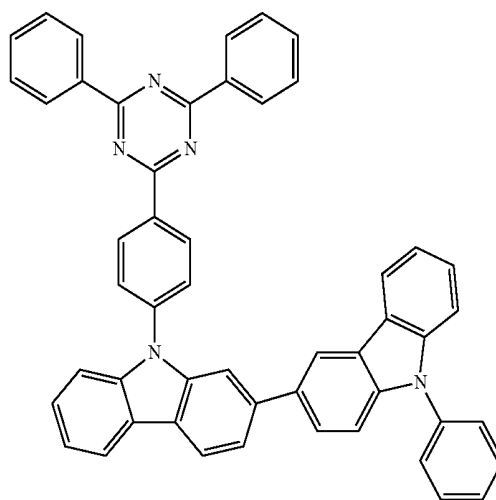
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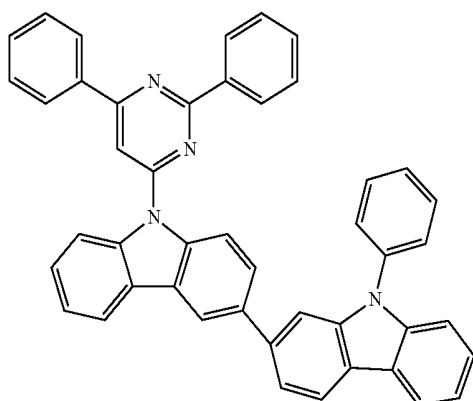
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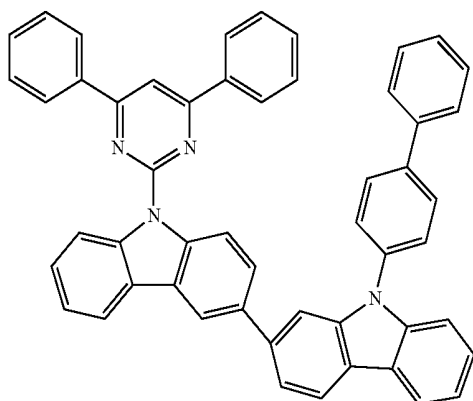
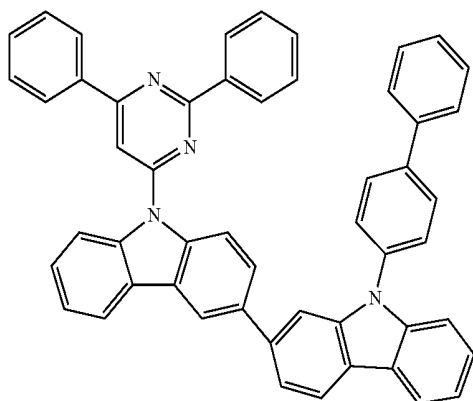
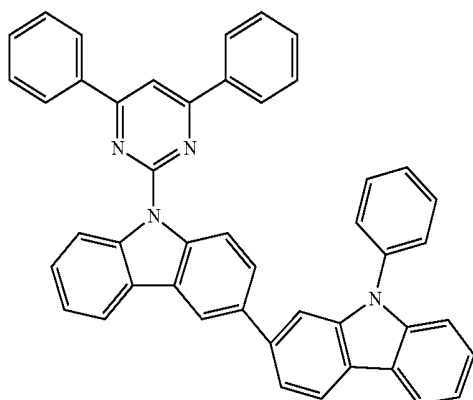
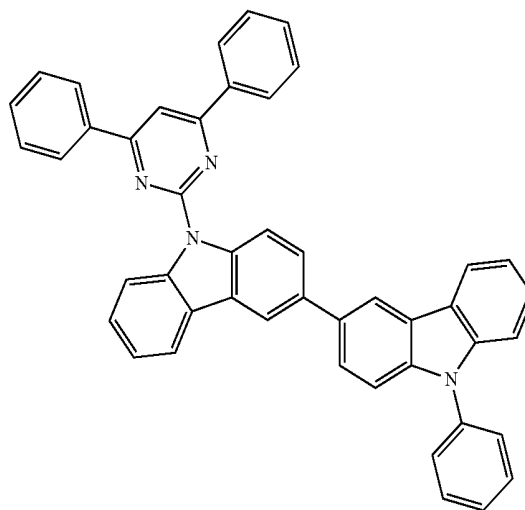
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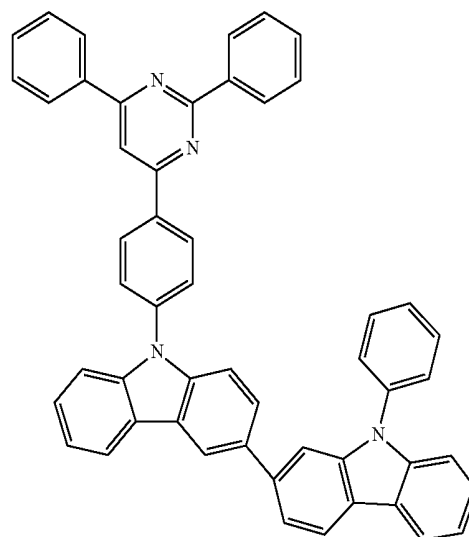
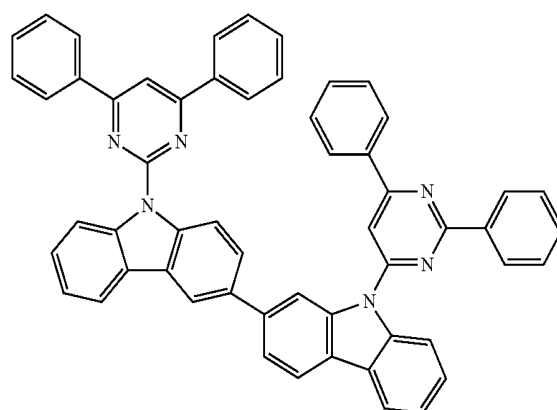
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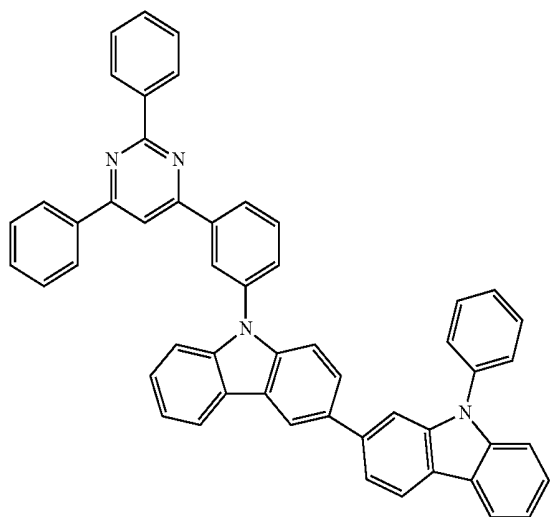
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[31]



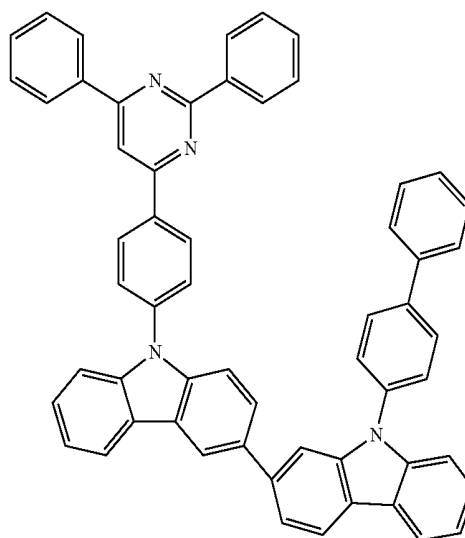
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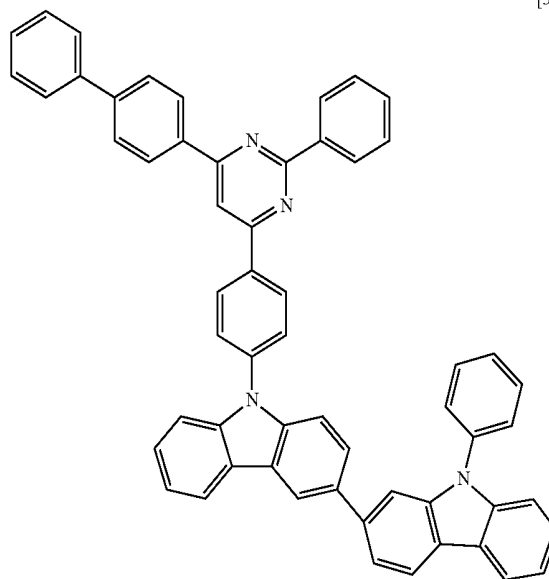


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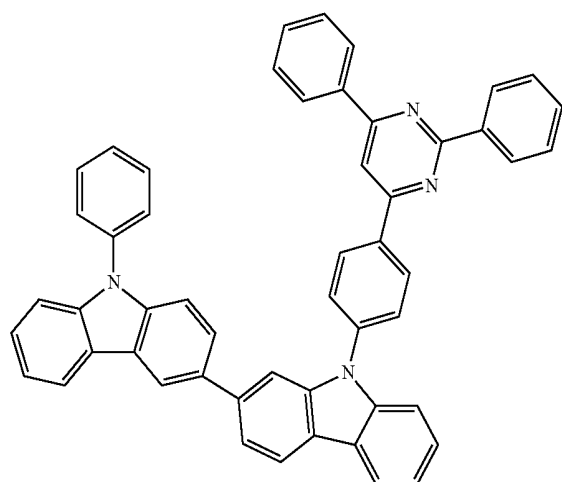


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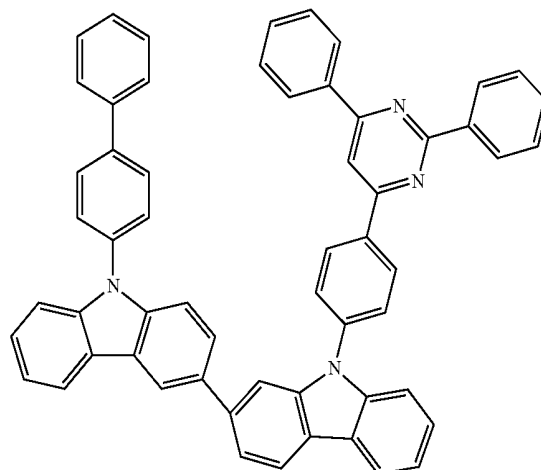
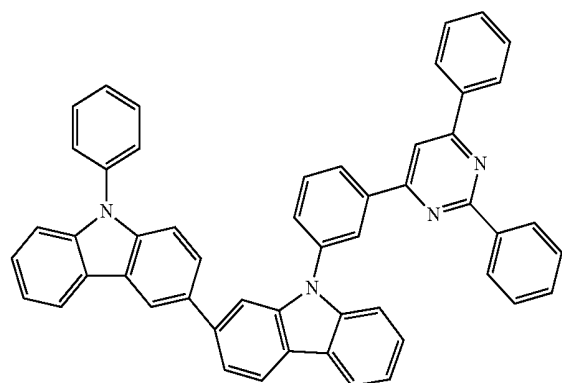


[37]

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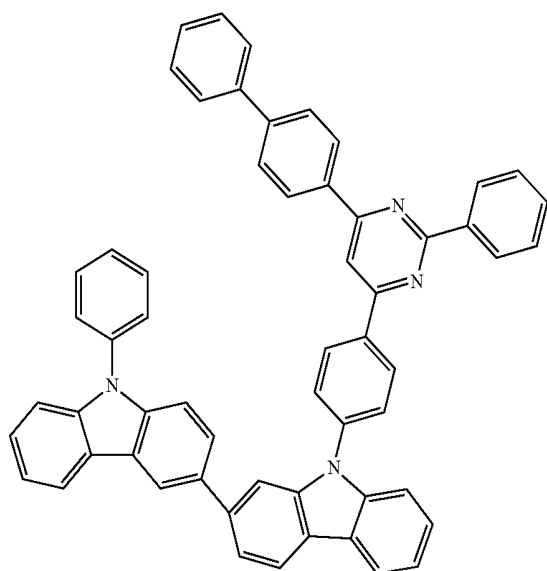


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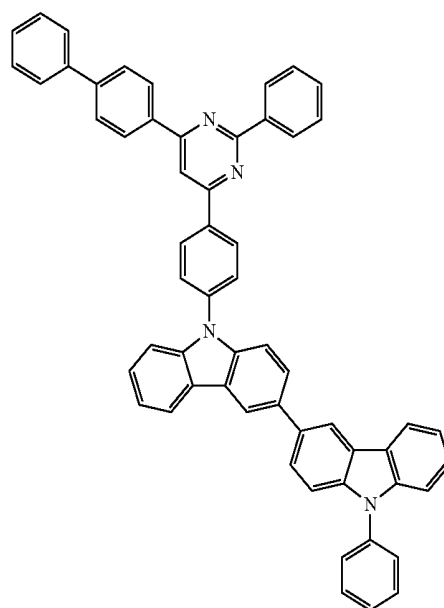
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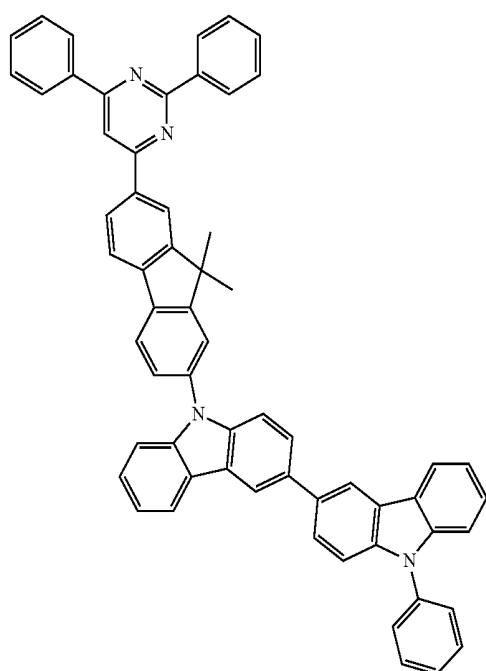


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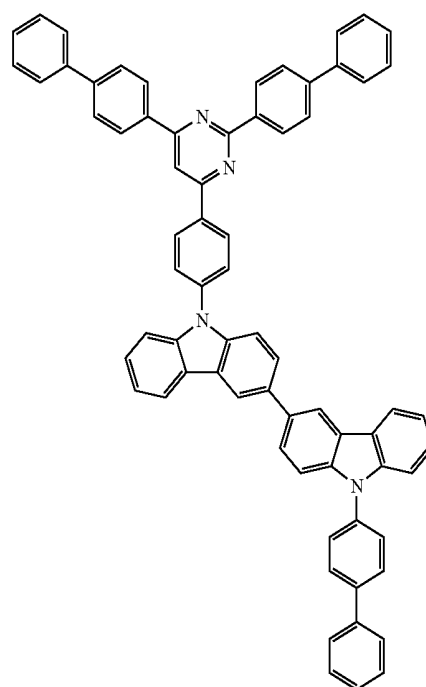
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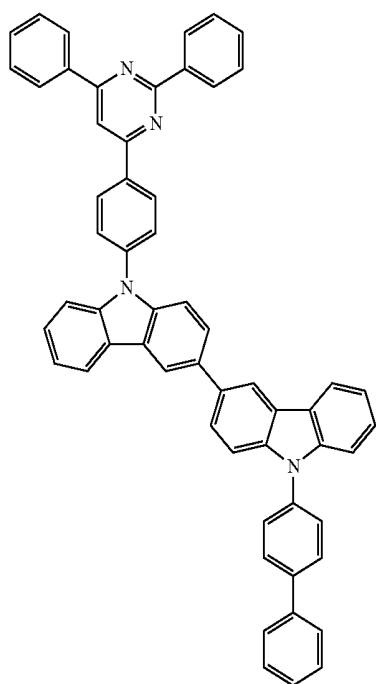
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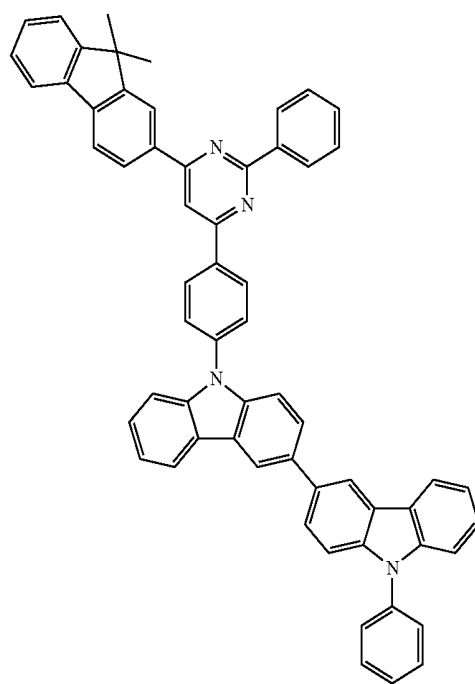
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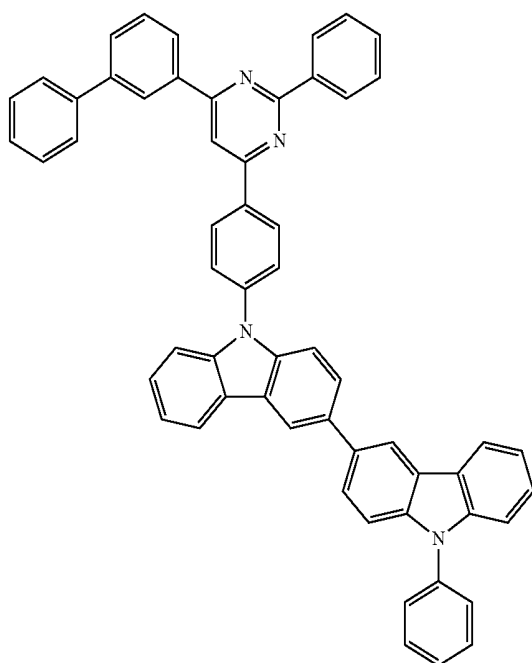
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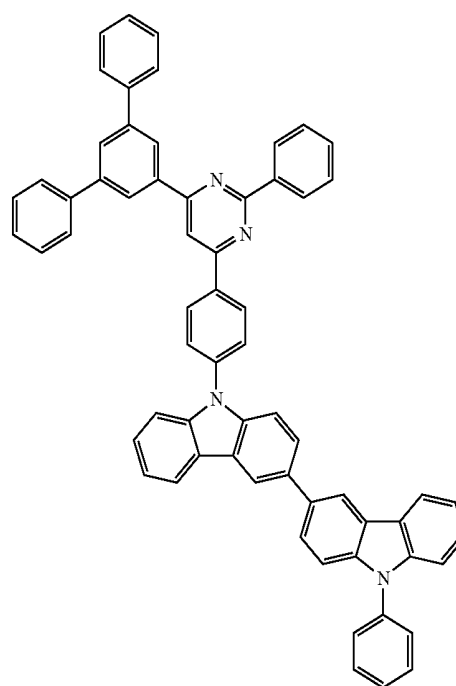
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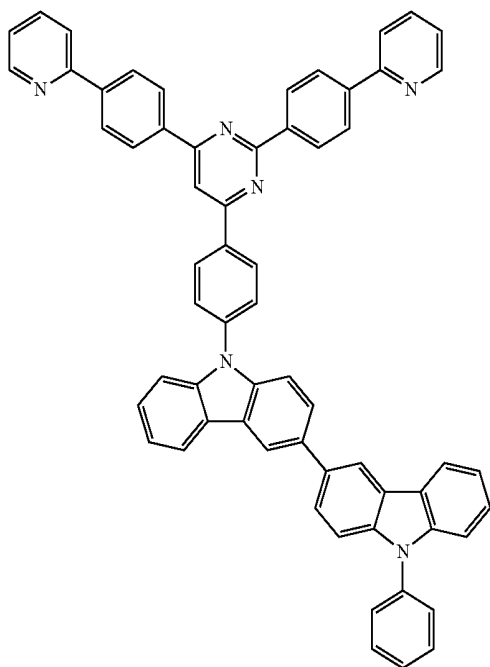
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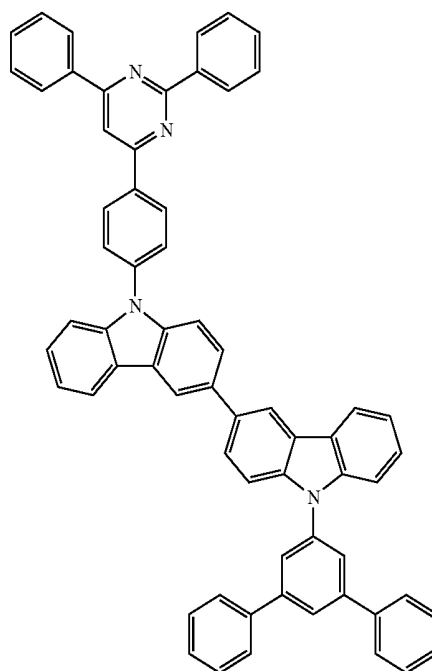


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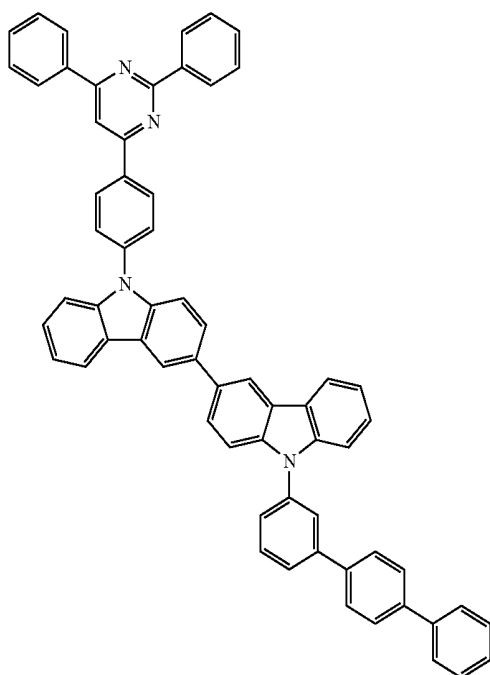
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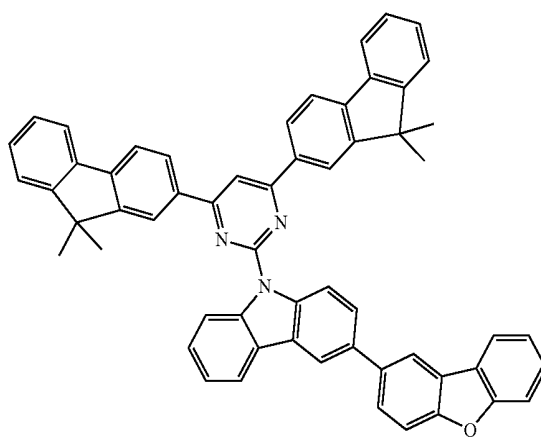
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[0073] In an implementation, the compound represented by Chemical Formula 2 may be one of the following Compounds 49 to 73.

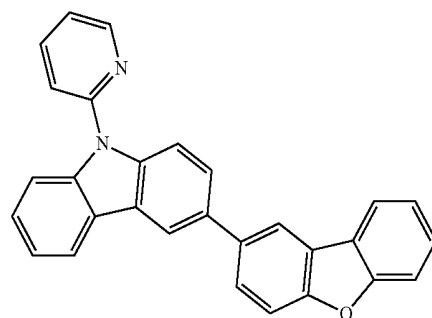
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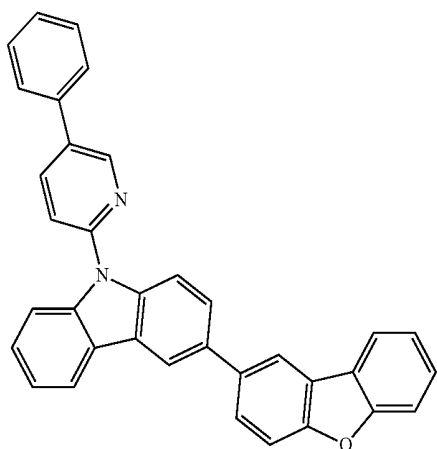
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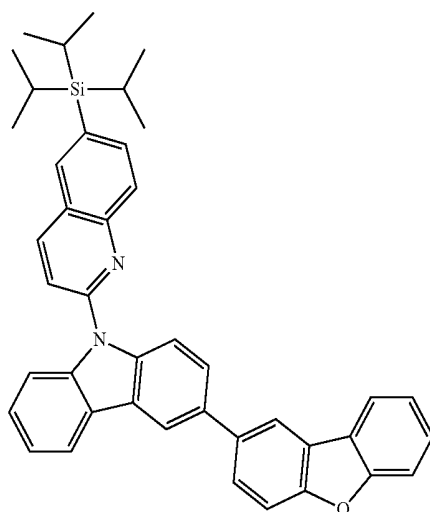
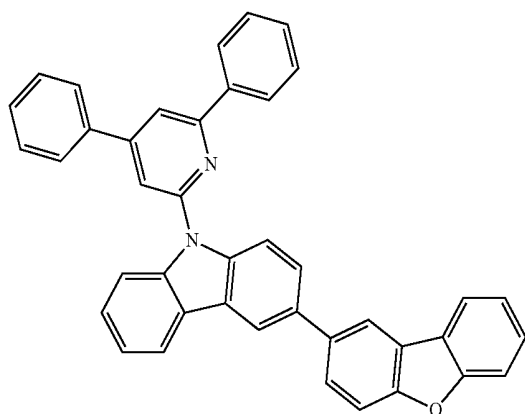
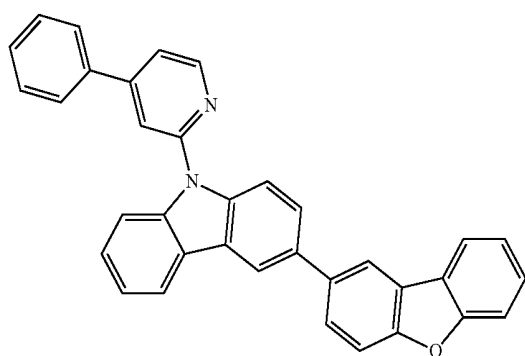
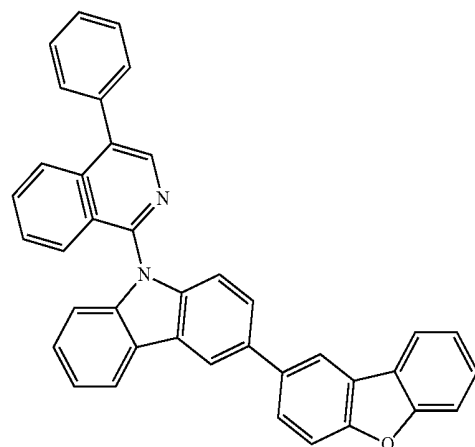
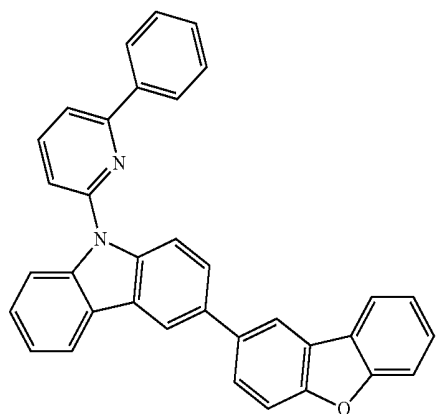
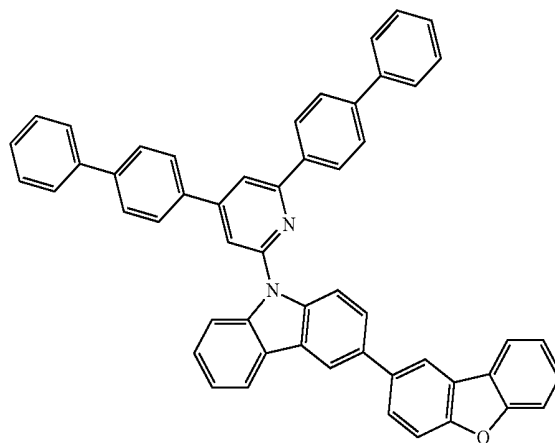
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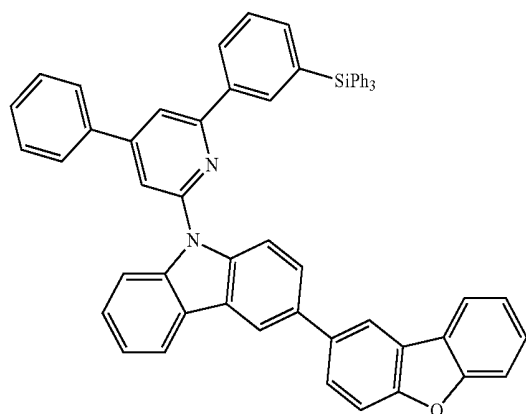


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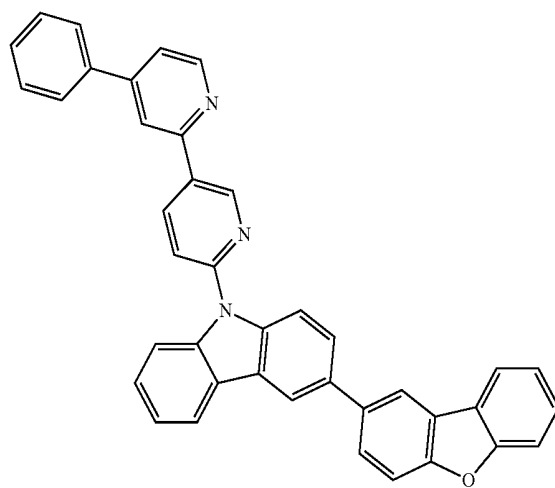
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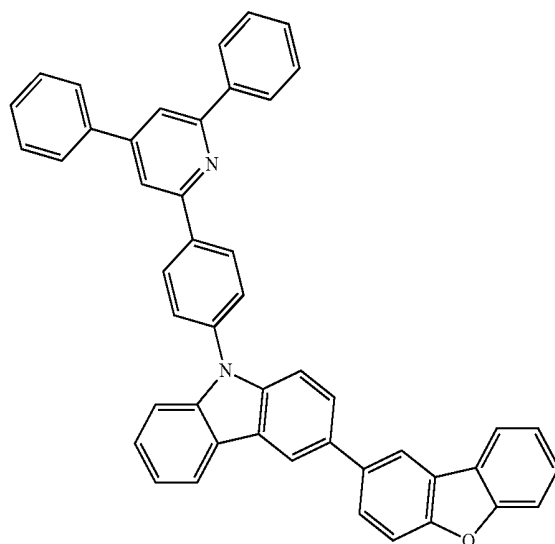
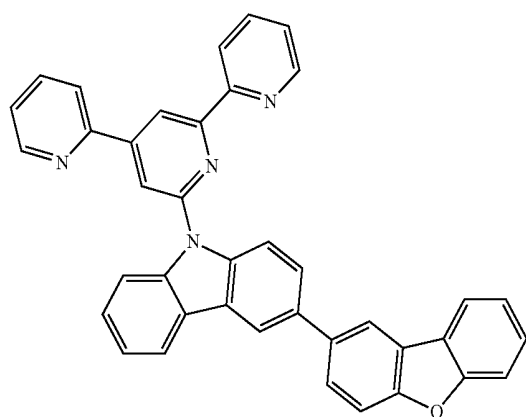
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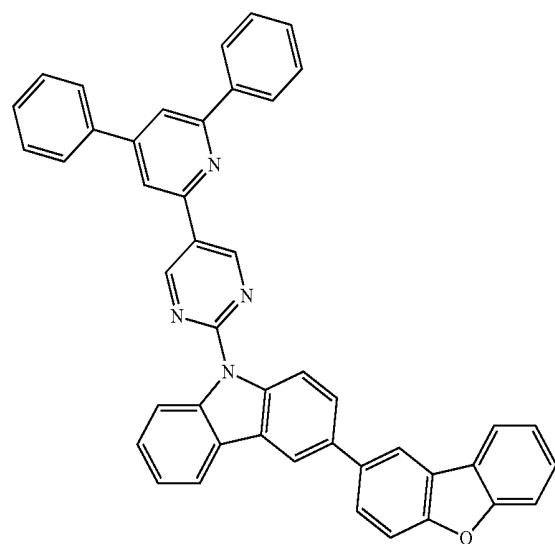
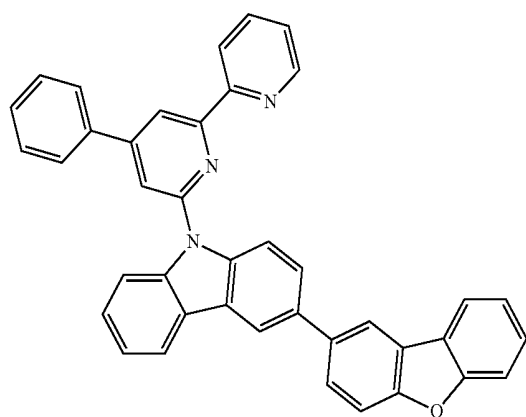
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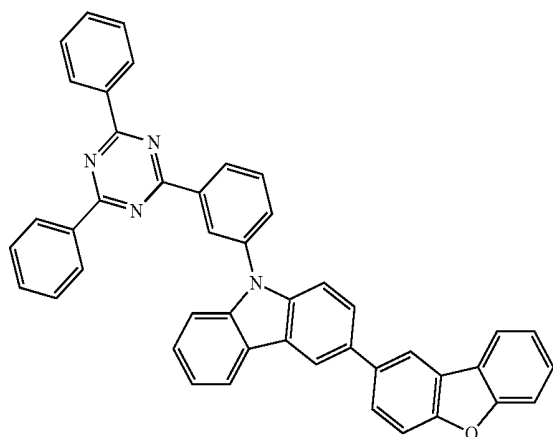
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[60]



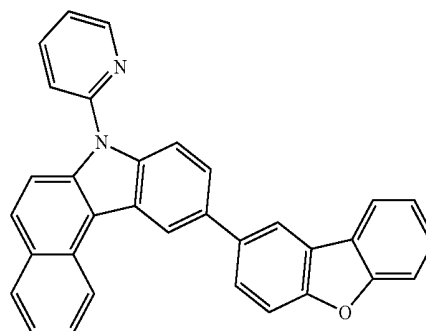
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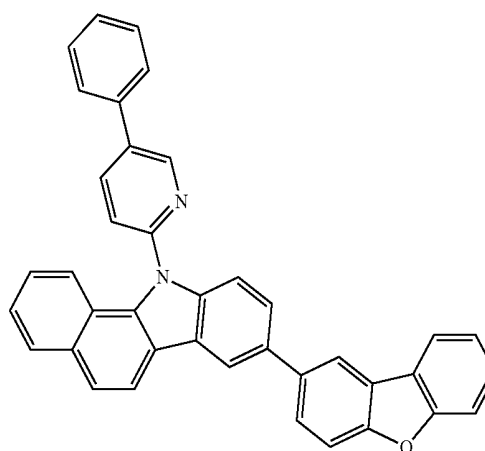


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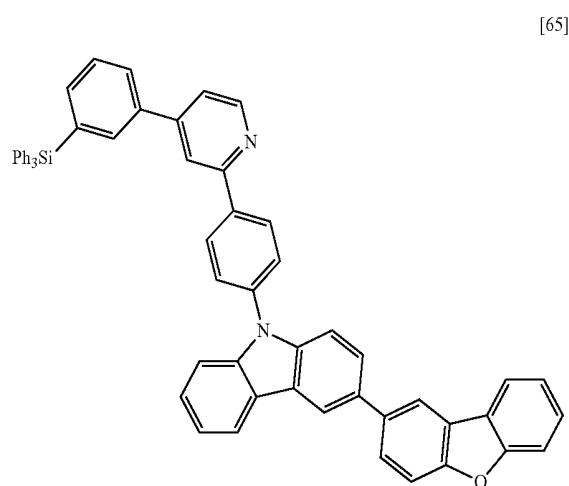
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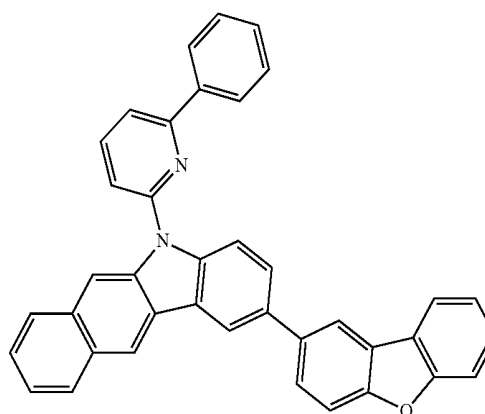
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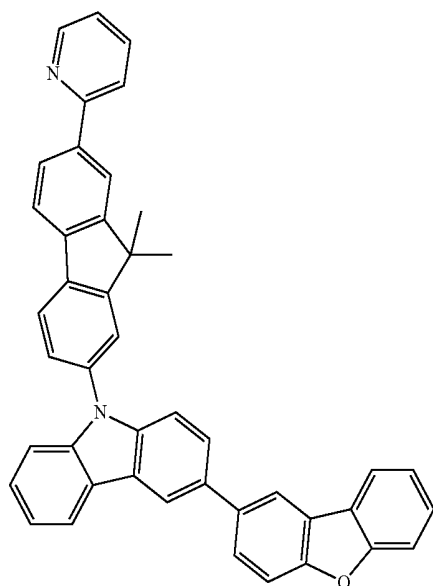
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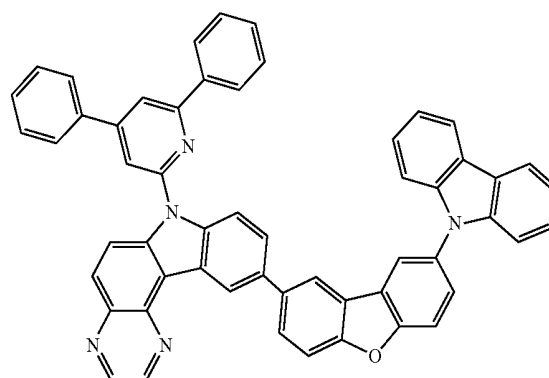
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[66]

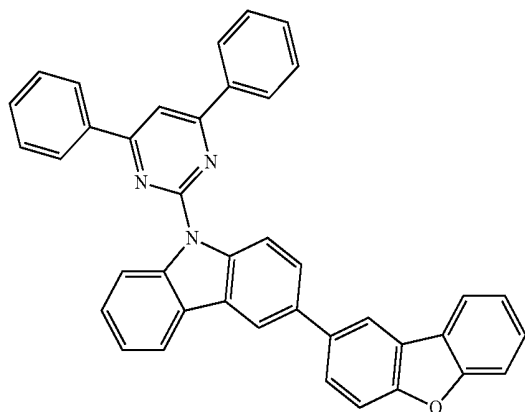


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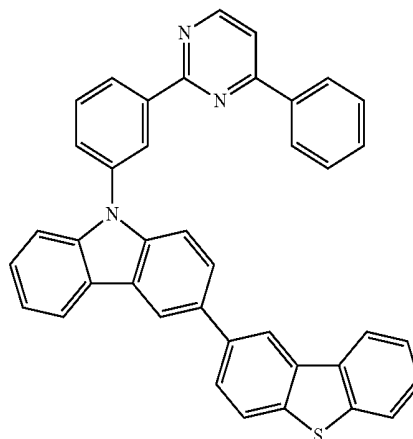


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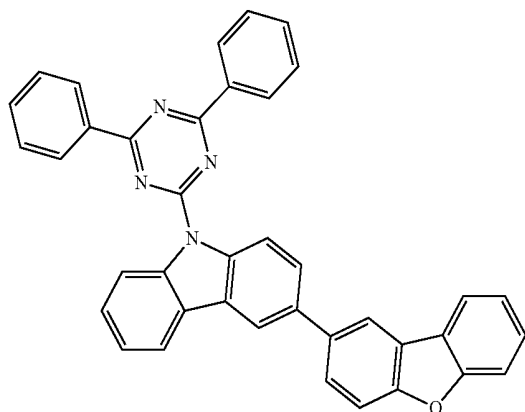
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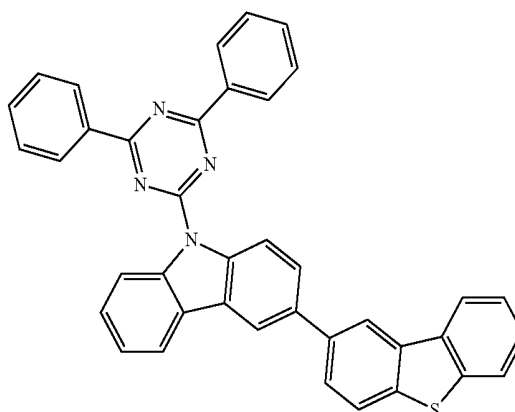
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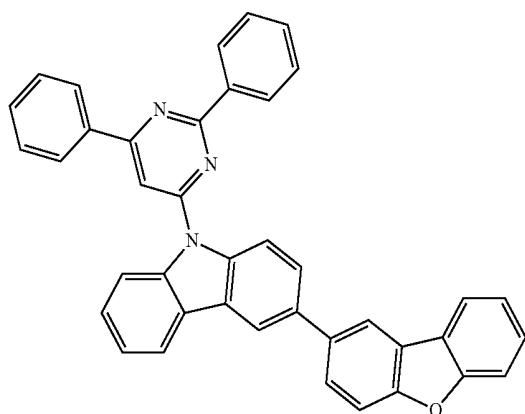
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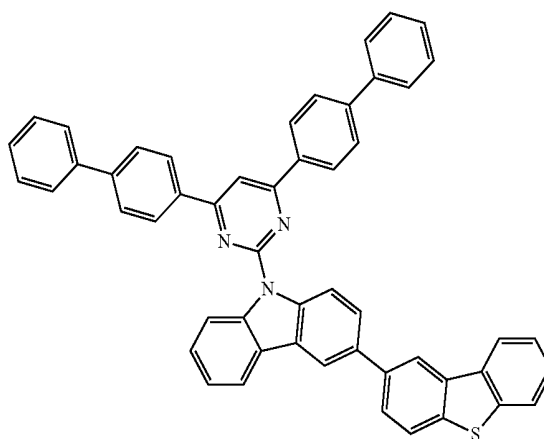
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[73]

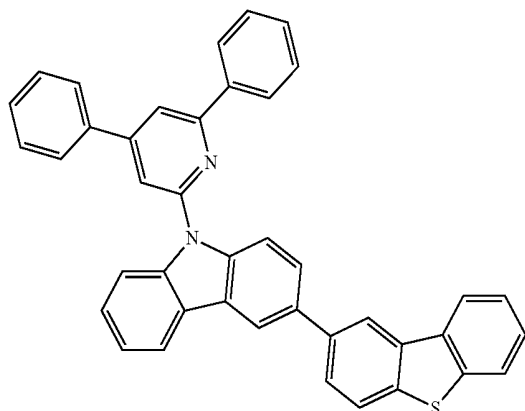


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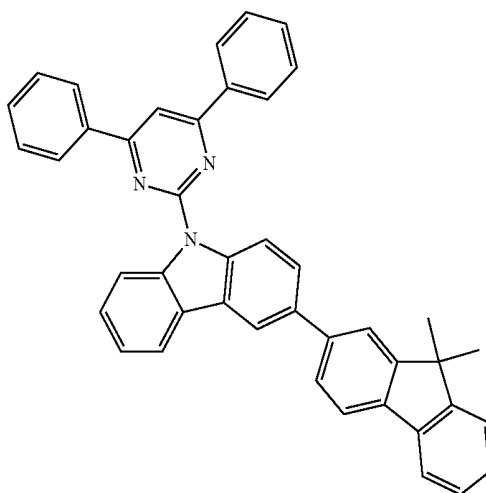
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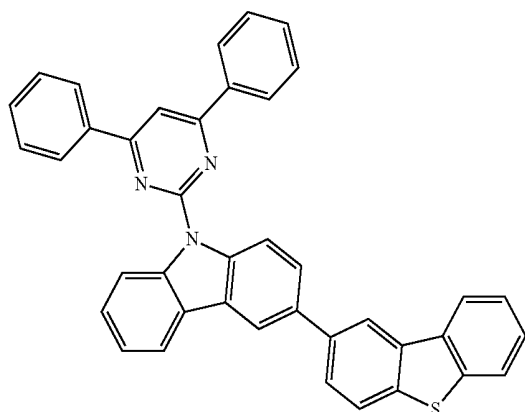


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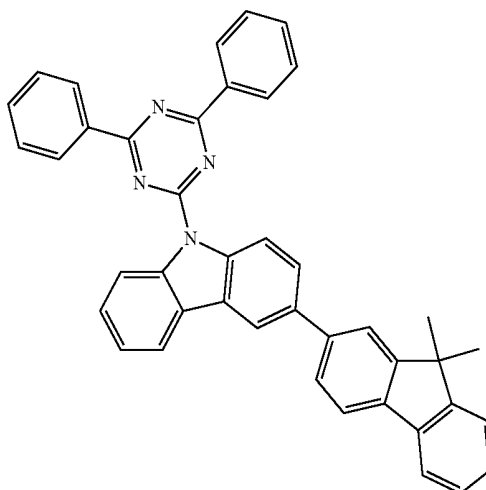
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[78]

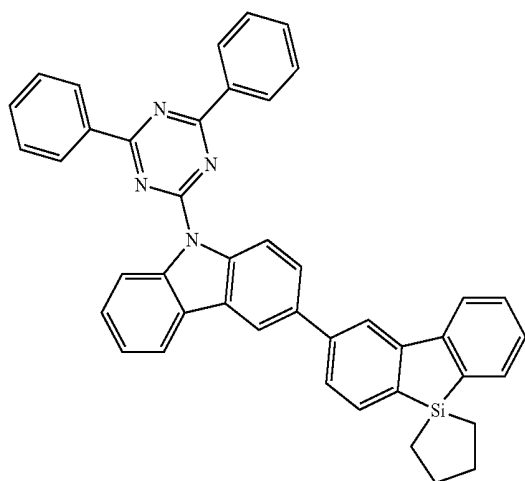


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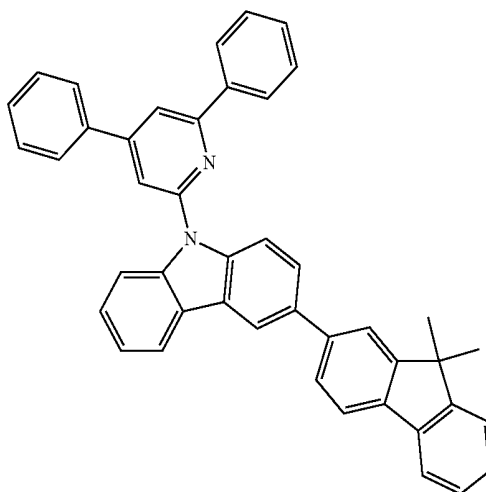


[0075] In an implementation, the compound represented by Chemical Formula 4 may be one of the following Compounds 79 to 84.

[79]

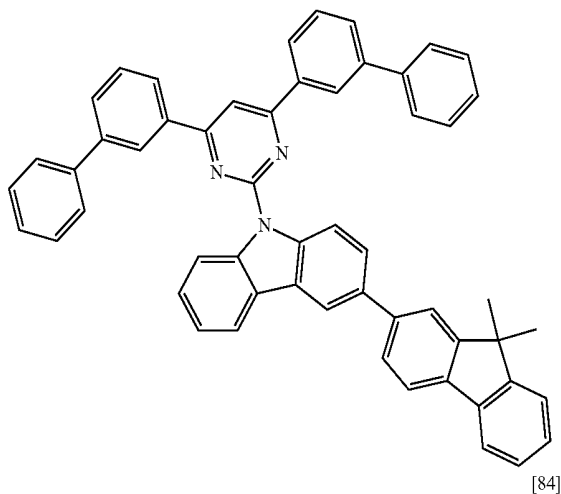


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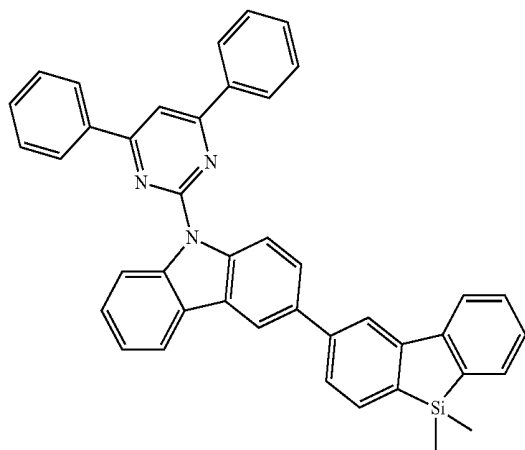


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[83]

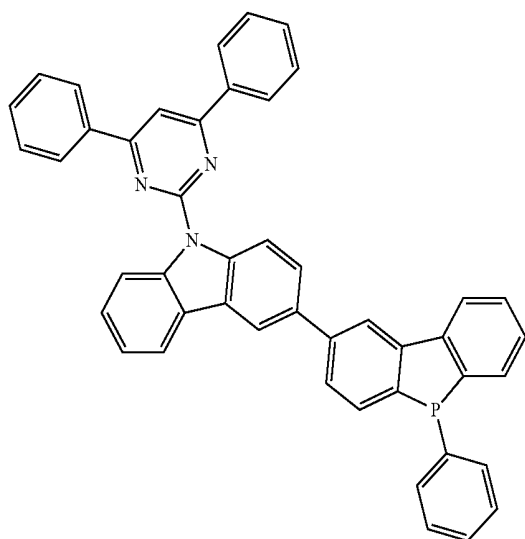


[84]



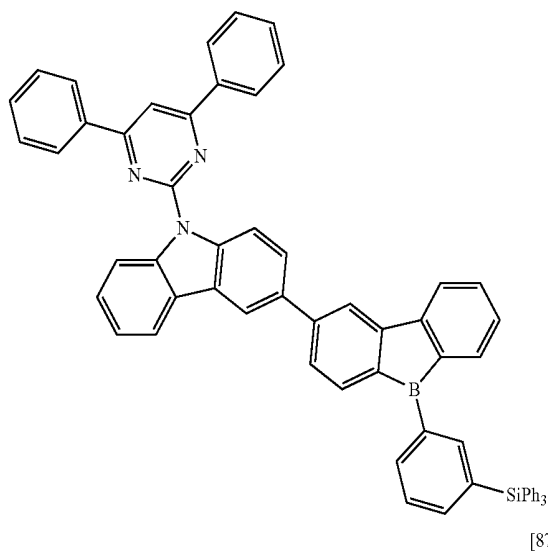
[0076] In an implementation, the compound represented by Chemical Formula 5 may be one of the following Compounds 85 to 88.

[85]

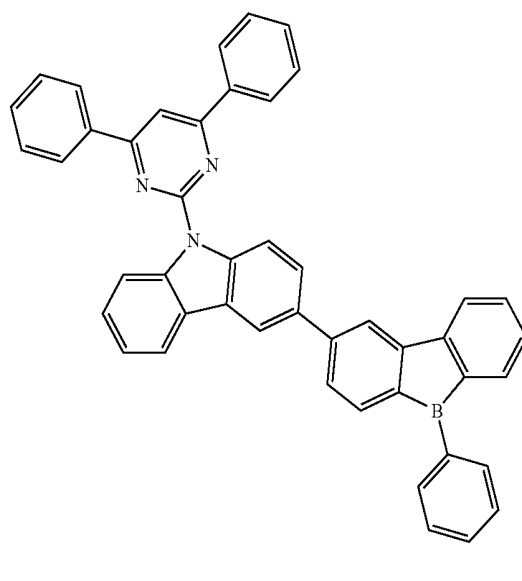


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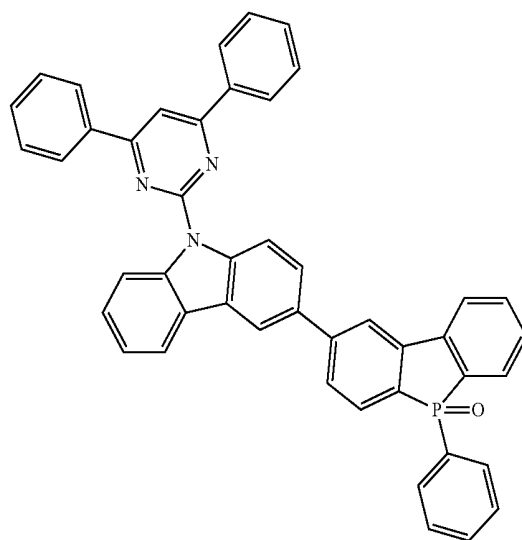
[86]



[87]



[88]



[0077] In an implementation, the capping layer **230** may include one or more of an inorganic material or an organic material having optical transmittance, apart from or in addition to the compound represented by one of Chemical Formulae 1 through 5. For example, the capping layer **230** may include at least one of a low refractive index material having a refractive index of about 1.3 to about 1.9, and a high refractive index material having a refractive index of about 1.9 to about 3.0.

[0078] The low refractive index materials and high refractive index materials may include, e.g., an organic or organometallic material or an inorganic material.

[0079] In an implementation, the inorganic material having the low refractive index may include, e.g., silicon oxide or magnesium fluoride.

[0080] In an implementation, the organic or organometallic material having the low refractive index may include, e.g., acrylic, polyimide, polyamide, Alq_3 [tris(8-hydroxyquinolino)aluminum], or the like.

[0081] In an implementation, the inorganic material having the high refractive index may include, e.g., zinc oxide, titanium oxide, zirconium oxide, niobium oxide, tantalum oxide, tin oxide, nickel oxide, silicon nitride, indium nitride, and/or gallium nitride.

[0082] In an implementation, the organic or organometallic material having the high refractive index may include, e.g., poly(3,4-ethylenedioxythiophene) (PEDOT), 4,4'-bis[N-(3-methylphenyl)-N-phenylamino]biphenyl (TPD), 4,4',4"-tris[N-(3-methylphenyl)-N-phenylamino]triphenylamine (m-MT-DATA), 1,3,5-tris[N,N-bis(2-methylphenyl-amino)-benzene (o-MTDAB), 1,3,5-tris[N,N-bis(3-methylphenyl-amino)-benzene (m-MTDAB), 1,3,5-tris[N,N-bis(4-methylphenyl)-amino]-benzene (p-MTDAB), 4,4'-bis[N,N-bis(3-methylphenyl)-amino]-diphenylmethane (BPPM), 2,2',2"-(1,3,5-benzotriyl)tris-[1-phenyl-1H-benzimidazol] (TPBI), and/or 3-(4-biphenyl)-4-phenyl-5-t-butylphenyl-1,2,4-triazole (TAZ).

[0083] In an implementation, the capping layer **230** may include various suitable materials.

[0084] In an implementation, the capping layer **230** may have a thickness of, e.g., about 10 nm to about 300 nm. In an implementation, the capping layer **230** may have a thickness of, e.g., 300 nm or more, or about 300 nm to about 600 nm, in order to fully protect the OLED **210**. In an implementation, the capping layer **230** may have a thickness of, e.g., greater than 600 nm.

[0085] The capping layer **230** may be manufactured by a suitable method, e.g., it may be formed by deposition.

[0086] A second substrate **410** may be disposed on the capping layer **230**.

[0087] The second substrate **410** may be a transparent insulating substrate including, e.g., glass, quartz, ceramic, and/or plastic. The second substrate **410** may be bonded and sealed to the first substrate **100** so as to cover the OLED **210**.

[0088] Referring to FIG. 2, an air layer **310** may be formed in a space between the second substrate **410** and the capping layer **230**. The air layer **310** may have a lower refractive index than that of the capping layer **230**.

[0089] In an implementation, light generated in the organic light emitting layer **212** of the OLED **210** may pass through the second electrode **213**, the capping layer **230**, the air layer **310**, and the second substrate **410** to be released outwards.

[0090] While propagating outwards, the light generated in the organic light emitting layer **212** may arrive at an interlayer

interface. The light may pass through the interlayer interface, or may fail to propagate through the interlayer interface and thus may be reflected therefrom.

[0091] In an implementation, light generated in the organic emission layer **212** may be reflected from or at an interface between the capping layer **230** and the air layer **310**. The reflected light may then be reflected again from or at an interface between the second electrode **213** and the capping layer **230**, or may propagate through the second electrode **213** and the organic light emitting layer **212** and may then be reflected from an upper surface of the first electrode **211**.

[0092] Accordingly, the light may be repeatedly reflected off interfaces between the respective layers or spaces and, during the reflections, light having a predetermined wavelength may be resonated and light having other wavelengths may be dissipated. The resonated light may be amplified and may then be released outwards. By virtue of such resonance, light efficiency of the OLED display **101** may be improved.

[0093] Hereinafter, a second exemplary embodiment will be described with reference to FIG. 3.

[0094] FIG. 3 illustrates a cross-sectional view of an OLED display **102** according to a second exemplary embodiment. Repeated descriptions with regard to configurations identical to those of the first exemplary embodiment may be omitted for brevity.

[0095] An OLED display **102** according to the second exemplary embodiment may include a filling member **320** in a space between a capping layer **230** and a second substrate **410**. The filling member **320**, in place of the air layer **310**, may fill the interior space of the OLED display **102**.

[0096] The filling member **320** may include an organic material, e.g., a polymer. In an implementation, the refractive index of the filling member **320** may be less than or more than (e.g., different from) that of the capping layer **230**, or may be equivalent to that of the capping layer **230**.

[0097] The filling member may be selected according to the refractive index of the capping layer **230** and the second substrate **410**. For example, when the second substrate **410** is a glass substrate having a refractive index of about 1.5, a polymer having a refractive index of about 1.5 may be used as a material for the filling member **320**. In an implementation, the material for the filling member **320** may include, e.g., poly(methylmethacrylate) (PMMA).

[0098] As the filling member **320** fills the empty space of the OLED display **102**, the device strength and durability of the OLED display **102** may be improved due to the filling member **320**.

[0099] Hereinafter, a third exemplary embodiment will be described with reference to FIG. 4.

[0100] FIG. 4 illustrates a cross-sectional view of an OLED display **103** according to a third exemplary embodiment. Repeated descriptions with regard to configurations identical to those of the first exemplary embodiment may be omitted for brevity.

[0101] An OLED display **103** according to the third exemplary embodiment may include a thin film encapsulation layer **250** on a capping layer **230**.

[0102] The thin film encapsulation layer **250** may include one or more inorganic layers **251**, **253**, and **255**, and one or more organic layers **252** and **254**. The thin film encapsulation layer **250** may have a structure where the inorganic layers **251**, **253**, and **255** and the organic layers **252** and **254** are alternately laminated. In this case, the inorganic layer **251** may be disposed at a lowest portion of the laminated struc-

ture. For example, the inorganic layer **251** may be disposed closest to the OLED **210**. In an implementation, the thin film encapsulation layer **250**, as illustrated in FIG. 4, may include three inorganic layers **251**, **253**, and **255**, and two organic layers **252** and **254**.

[0103] The inorganic layers **251**, **253**, and **255** may include one or more inorganic materials of, e.g., Al_2O_3 , TiO_2 , ZrO , SiO_2 , AlON , AlN , SiON , Si_3N_4 , ZnO , and Ta_2O_5 . The inorganic layers **251**, **253**, and **255** may be formed using methods such as chemical vapor deposition (CVD) or atomic layer deposition (ALD). In an implementation, the inorganic layers **251**, **253**, and **255** may be formed using suitable methods.

[0104] The organic layers **252** and **254** may include, e.g., polymer-based materials. In an implementation, the polymer-based materials may include, e.g., acrylic resins, epoxy resins, polyimide, and polyethylene. The organic layers **252** and **254** may be formed by, e.g., a thermal deposition process. The thermal deposition process for forming the organic layers **252** and **254** may be performed in a range of temperatures that may not damage the OLED **210**. In an implementation, the organic layers **252** and **254** may be formed using suitable methods.

[0105] The inorganic layers **251**, **253**, and **255** having a high density of thin films may help prevent or efficiently reduce infiltration of, e.g., moisture or oxygen. For example, most infiltration of moisture and oxygen into the OLED **210** may be prevented by the inorganic layers **251**, **253**, and **255**.

[0106] Moisture and oxygen that passes through the inorganic layers **251**, **253**, and **255** may be further blocked by the organic layers **252** and **254**. The organic layers **252** and **254** may show a relatively low moisture-infiltration preventing efficacy compared to the inorganic layers **251**, **253**, and **255**. However, the organic layers **252** and **254** may also serve as a buffer layer to reduce stress between the respective layers of the inorganic layers **251**, **253**, and **255** and the organic layers **252** and **254**, apart from preventing of moisture infiltration. Further, the organic layers **252** and **254** may have planarizing properties, and an uppermost surface of the thin film encapsulation layer **250** may be planarized.

[0107] The thin film encapsulation layer **250** may have a thickness of about 10 μm or less. For example, the OLED display **103** may be formed to have an overall thickness significantly small.

[0108] A second substrate may be disposed on the thin film encapsulation layer **250**, and the second substrate **410** may be omitted. In the case where the second substrate is omitted, flexible properties of the OLED display **103** may be enhanced.

[0109] By way of summation and review, in order to enhance applicability of the OLED displays, methods have been considered to effectively protect the OLED and to efficiently extract light generated in the organic light emitting layer and improve light efficiency.

[0110] The embodiments may provide an organic light emitting diode display exhibiting improved light efficiency.

[0111] According to the embodiments, an OLED display may include a capping layer including a heterocyclic compound that includes a carbazole group and a heterocyclic group, thereby having excellent light efficiency.

[0112] Example embodiments have been disclosed herein, and although specific terms are employed, they are used and are to be interpreted in a generic and descriptive sense only and not for purpose of limitation. In some instances, as would be apparent to one of ordinary skill in the art as of the filing of the present application, features, characteristics, and/or elements described in connection with a particular embodiment may be used singly or in combination with features, characteristics, and/or elements described in connection with other embodiments unless otherwise specifically indicated. Accordingly, it will be understood by those of skill in the art that various changes in form and details may be made without departing from the spirit and scope of the present invention as set forth in the following claims.

What is claimed is:

1. An organic light emitting diode display, comprising:

a first substrate;

a first electrode on the first substrate;

an organic light emitting layer on the first electrode;

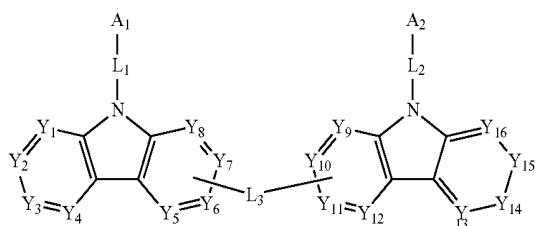
a second electrode on the organic light emitting layer; and

a capping layer on the second electrode,

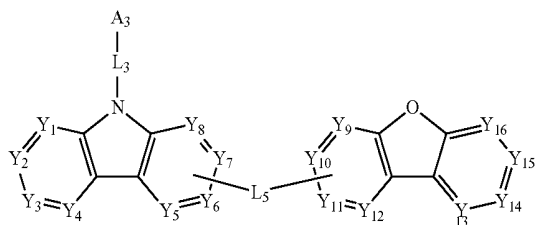
wherein the capping layer includes at least one heterocyclic compound, the heterocyclic compound including a carbazole group and a heterocyclic group bonded with the carbazole group.

2. The organic light emitting diode display as claimed in claim 1, wherein the heterocyclic compound is represented by one of the following Chemical Formulae 1 to 5:

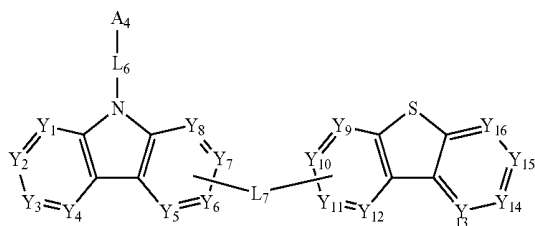
[Chemical Formula 1]



[Chemical Formula 2]

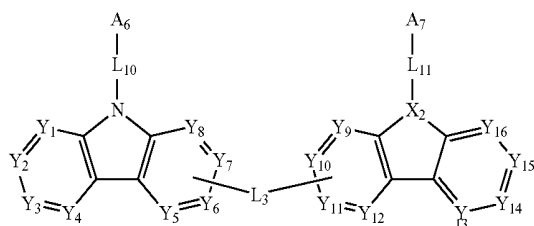
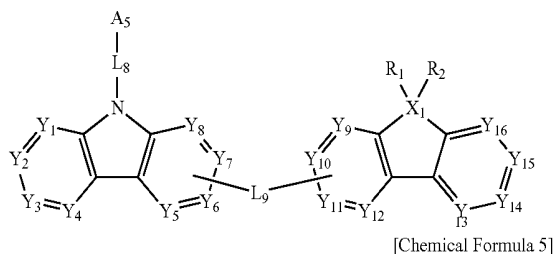


[Chemical Formula 3]



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[Chemical Formula 4]



wherein, in Chemical Formulae 1 to 5,

A₁ to A₇ are each independently a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms or a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms;

Y₁ to Y₁₆ are each independently C—R or a nitrogen atom, wherein each R of the C—R is independently one of a hydrogen atom, a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms, a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms and having a linear, branched, or cyclic structure, a substituted or unsubstituted alkoxy group having 1 to 30 carbon atoms, a substituted or unsubstituted aryloxy group having 6 to 30 ring carbon atoms, a substituted or unsubstituted aralkyl group having 7 to 30 carbon atoms, a substituted or unsubstituted haloalkyl group having 1 to 30 carbon atoms, a substituted or unsubstituted haloalkoxy group having 1 to 30 carbon atoms, a substituted or unsubstituted alkylsilyl group having 3 to 30 carbon atoms, a substituted or unsubstituted dialkylarylsilyl group having 8 to 40 carbon atoms, a substituted or unsubstituted alkyl diarylsilyl group having 13 to 50 carbon atoms, a substituted or unsubstituted triarylsilyl group having 18 to 60 carbon atoms, a substituted or unsubstituted alkenyl group having 2 to 30 carbon atoms, a substituted or unsubstituted alkynyl group having 2 to 30 carbon atoms, a halogen atom, a cyano group, a hydroxyl group, a nitro group, or a carboxyl group;

R of adjacent C—R, when two of Y₁ to Y₁₆ that are adjacent to each other are C—R, are separate or are combined to form a cyclic structure;

L₁ to L₁₂ are each independently a single bond or a connecting group;

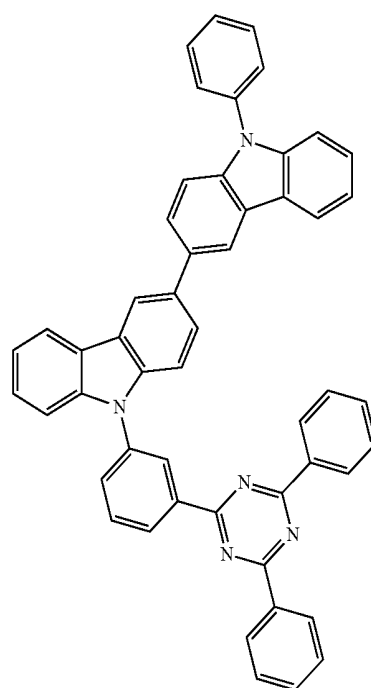
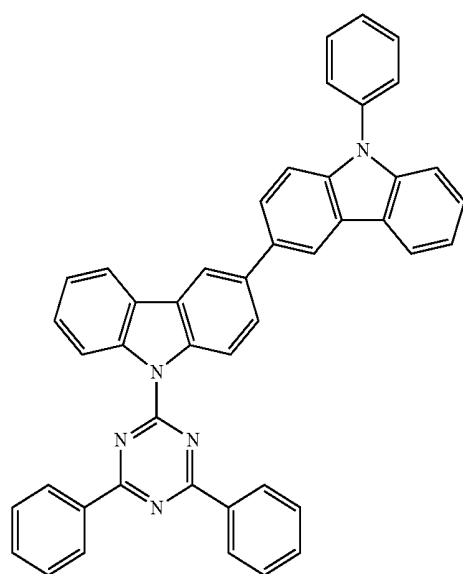
X₁ is carbon or silicon;

R₁ and R₂ are each independently a hydrogen atom, a substituted or unsubstituted aromatic hydrocarbon group having 6 to 30 ring carbon atoms, a substituted or

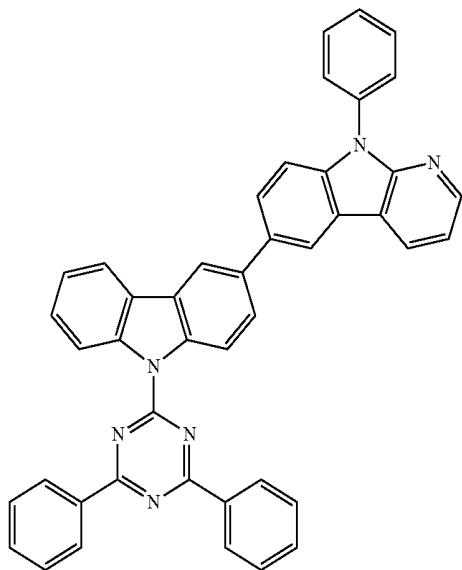
unsubstituted aromatic heterocyclic group having 1 to 30 ring carbon atoms, or a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms, R₁ and R₂ being separate or bonded together to form a cyclic structure; and

X₂ is boron, phosphorus, or P=O.

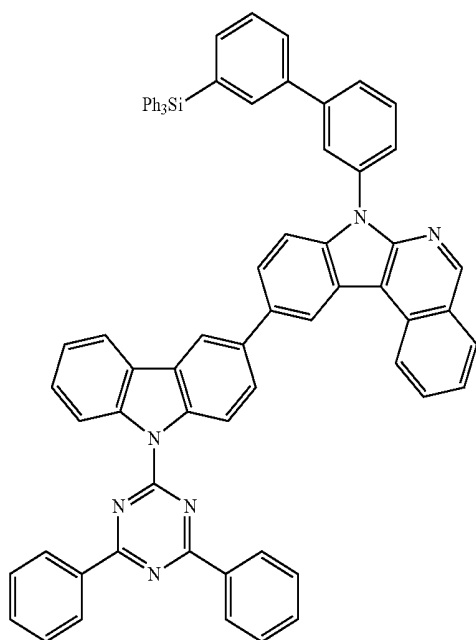
3. The organic light emitting diode display as claimed in claim 2, wherein the compound represented by Chemical Formula 1 is one of the following Compounds 1 to 48:



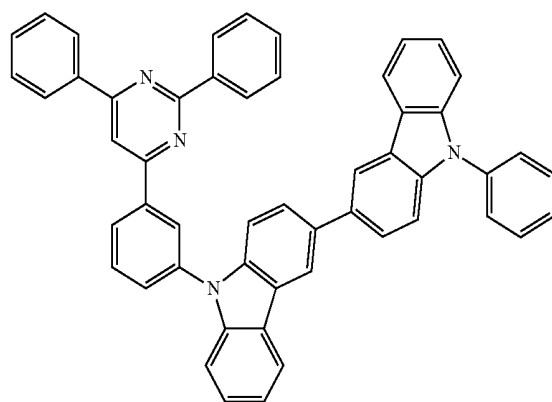
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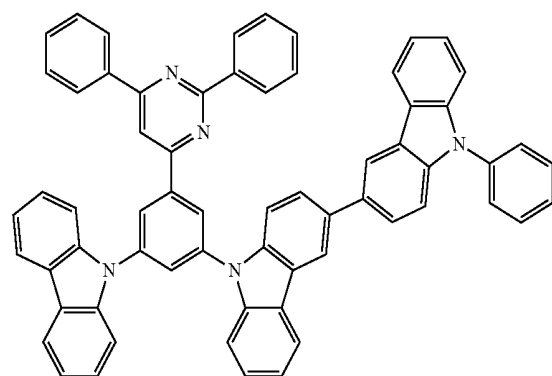


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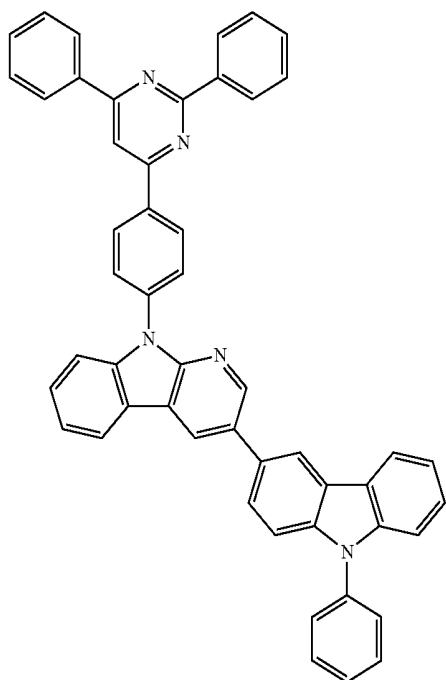


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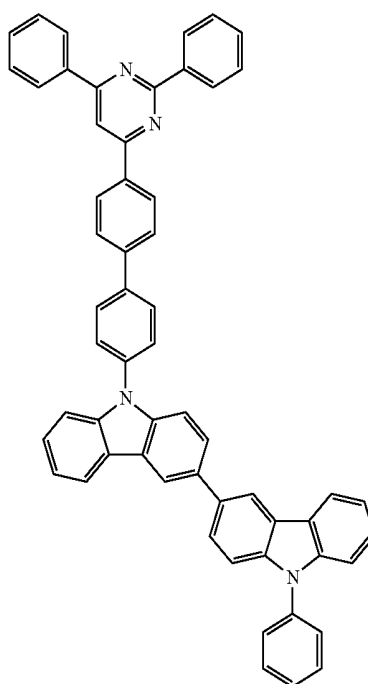
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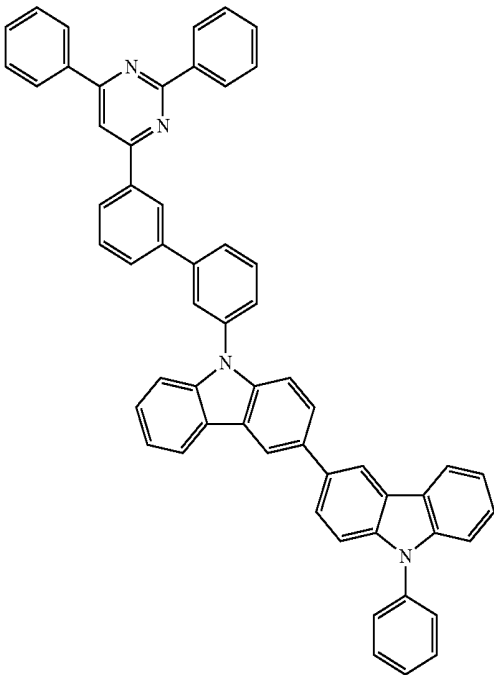
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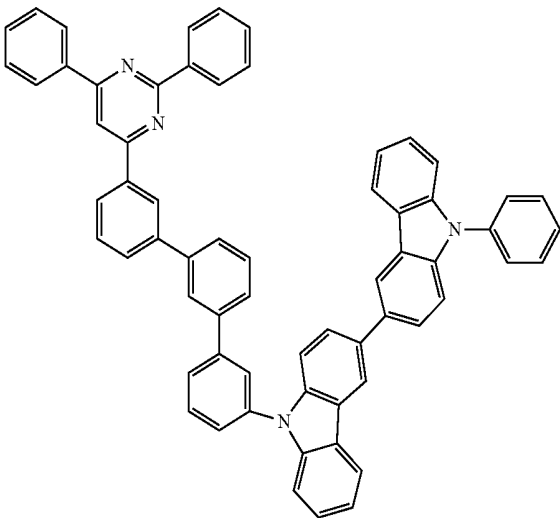


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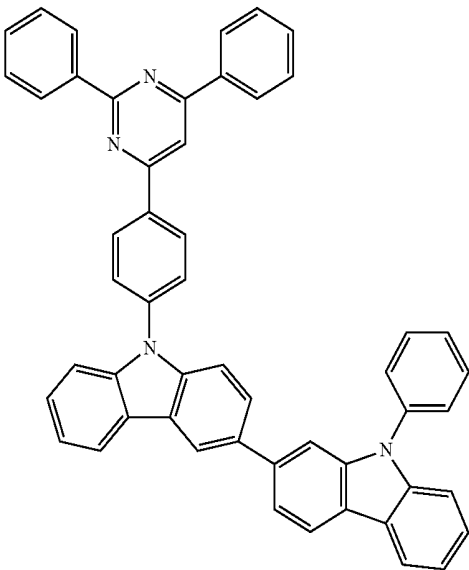


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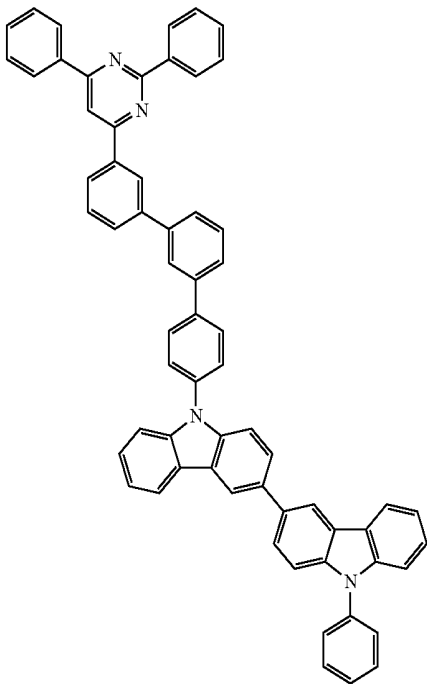
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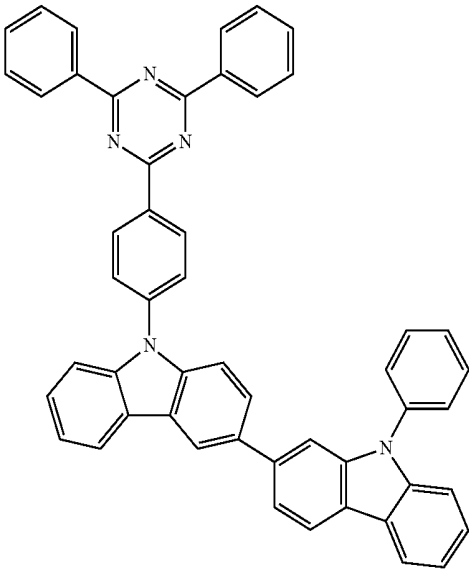
[14]



[15]

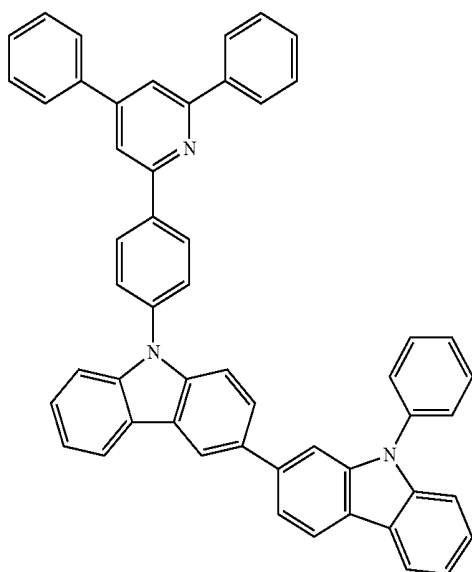


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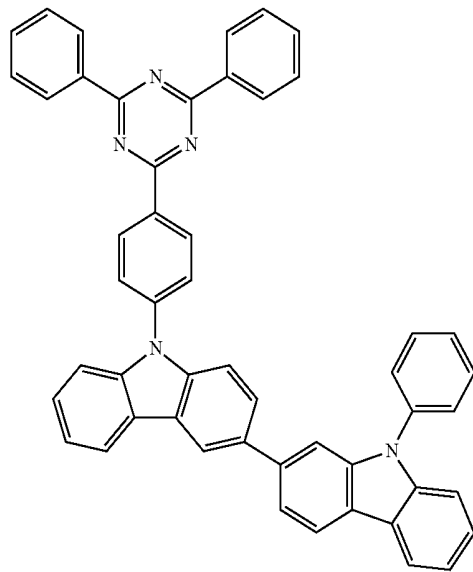


[16]

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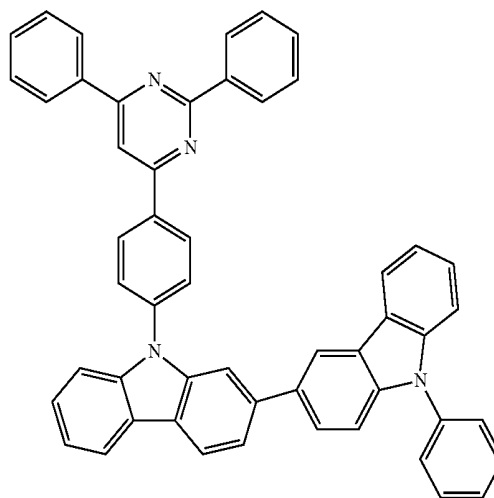


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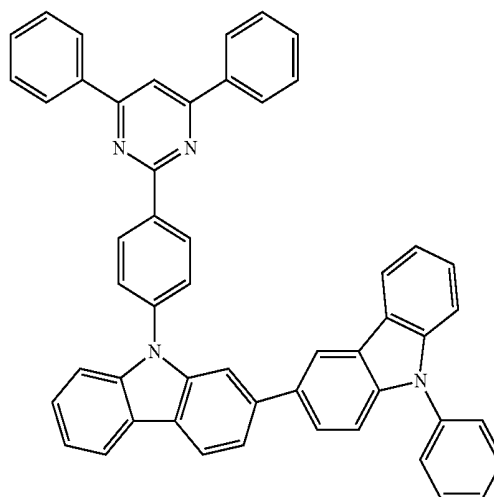
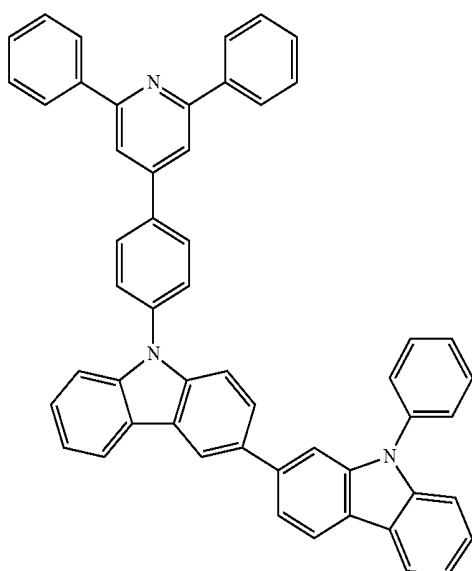


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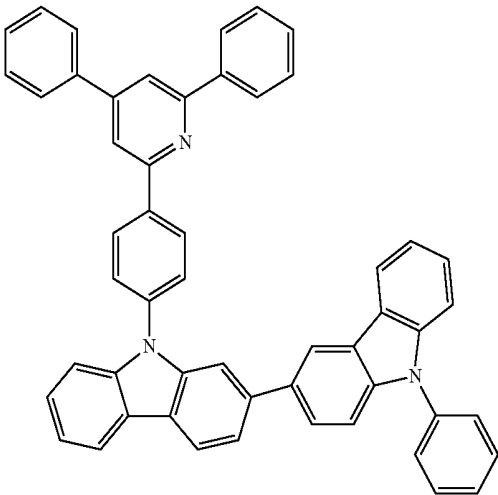
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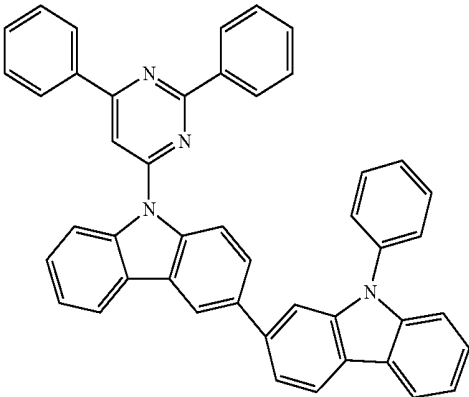


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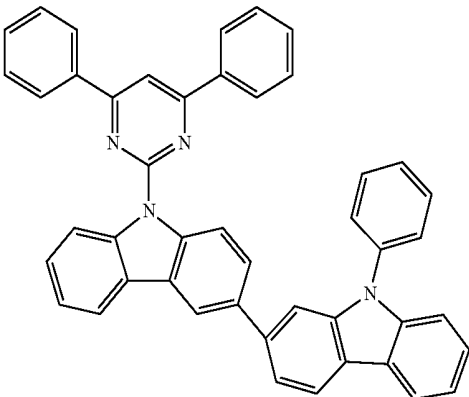


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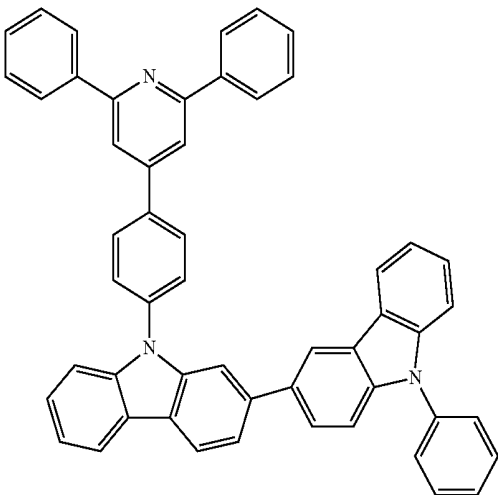
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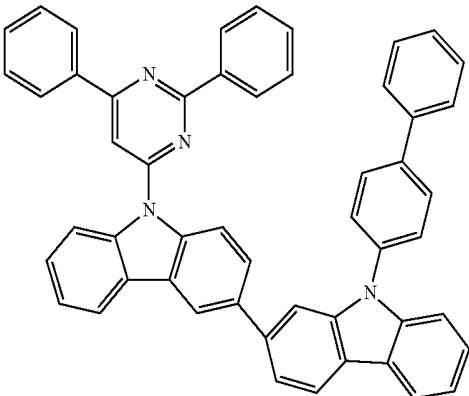
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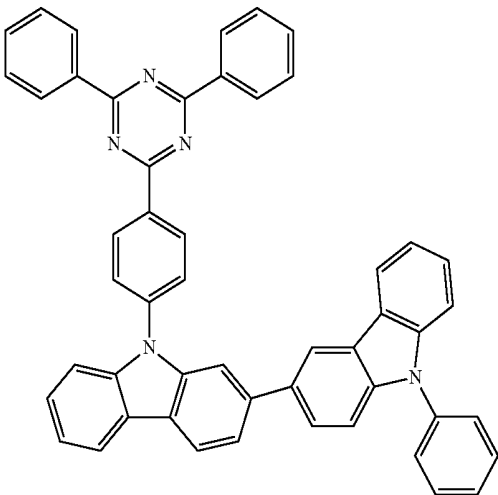
[26]



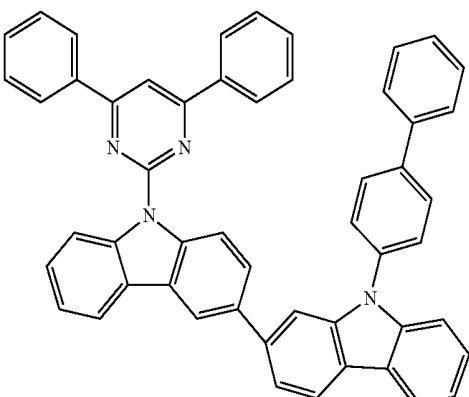
[23]



[27]



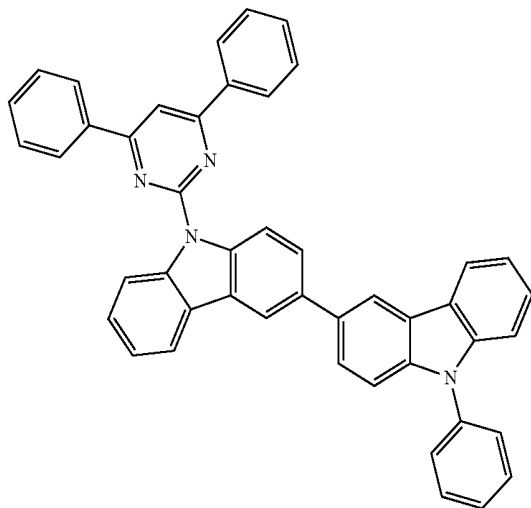
[24]



[28]

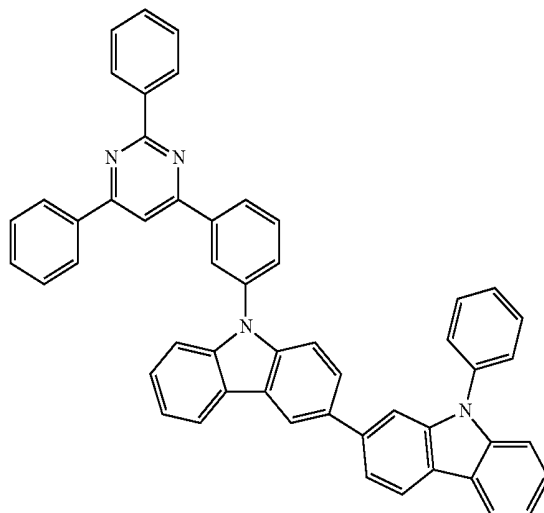
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[29]

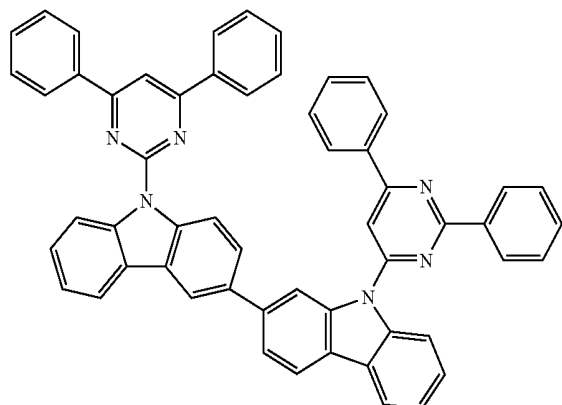


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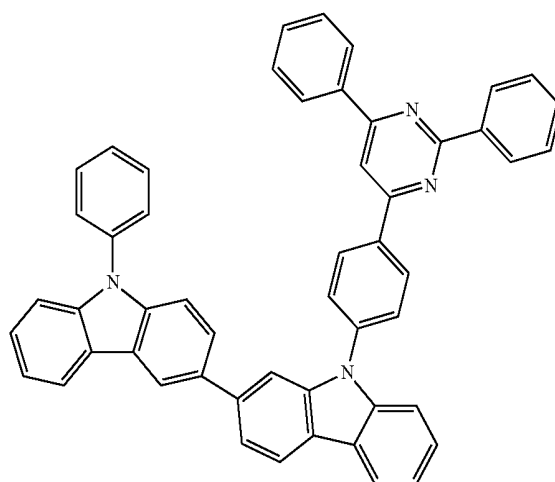
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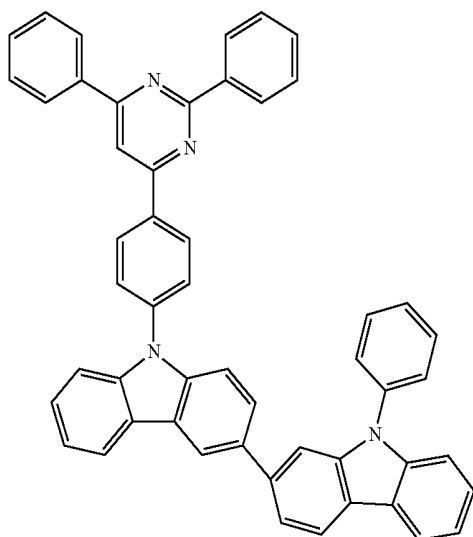
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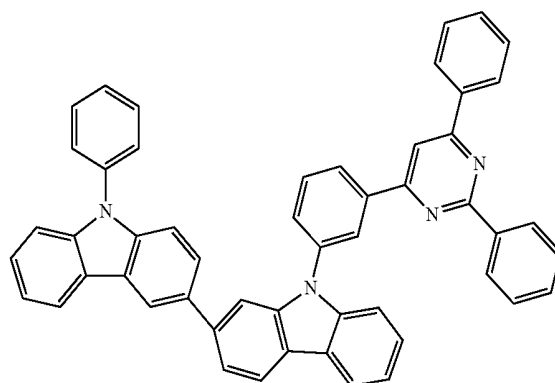
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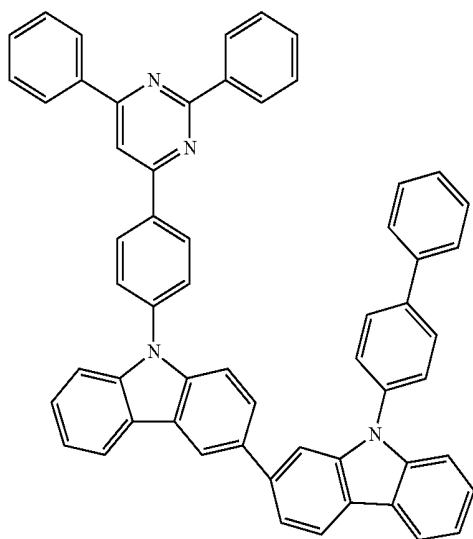
[31]



[34]

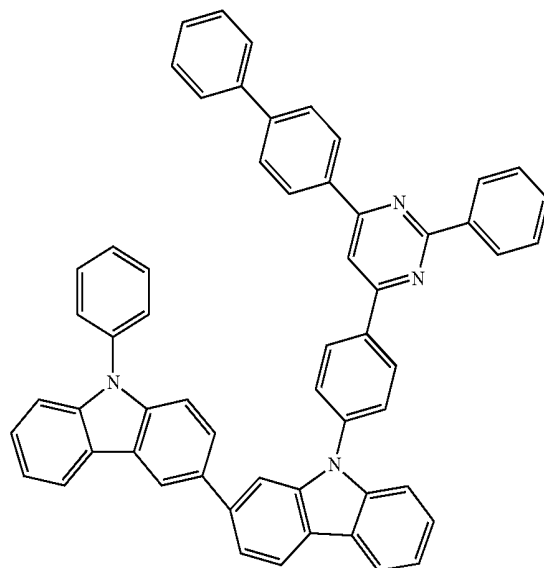


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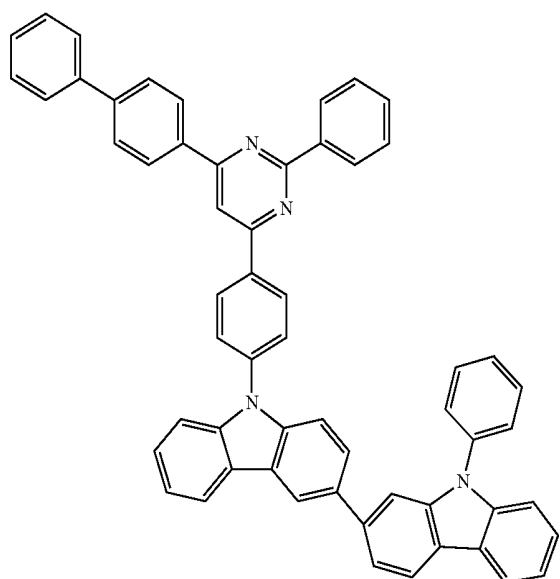


[35]

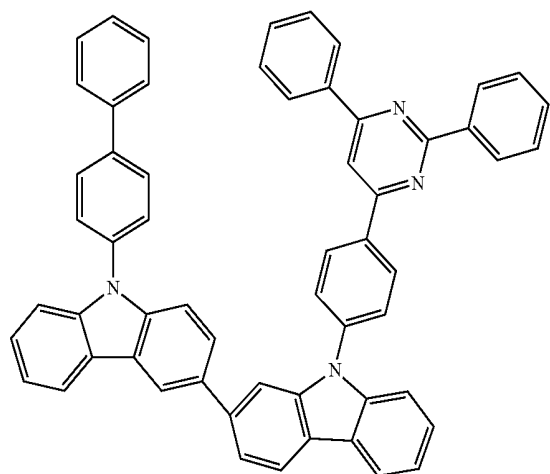
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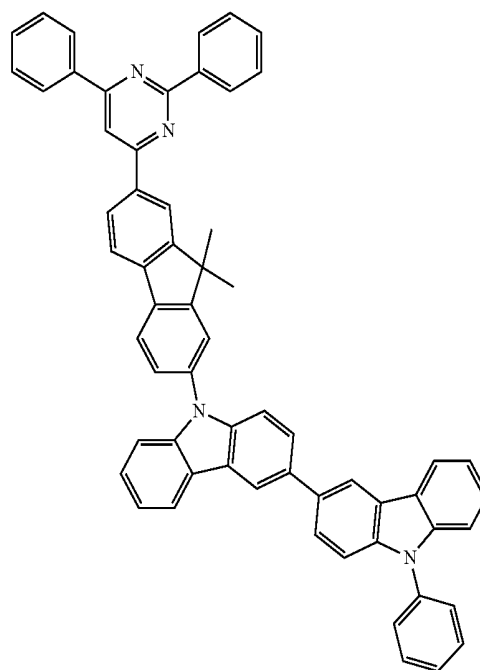
[38]



[36]

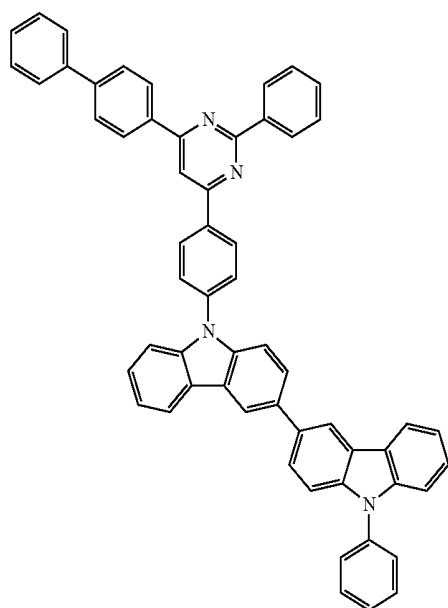


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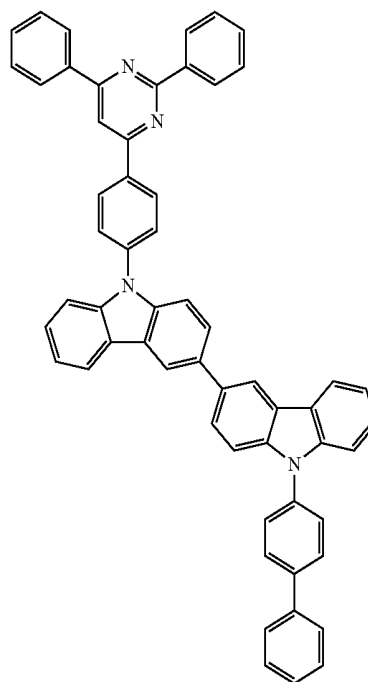


[39]

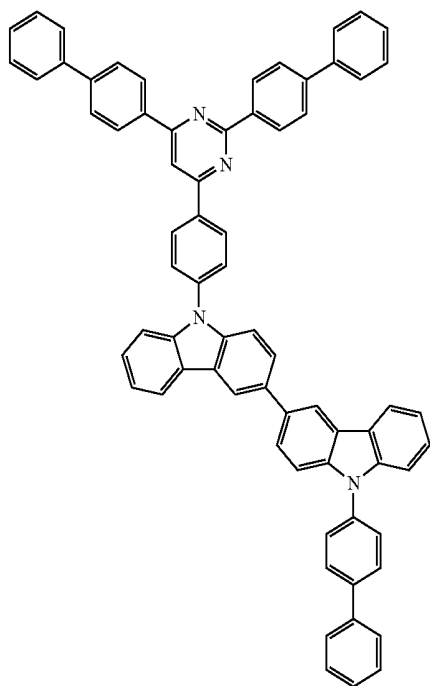
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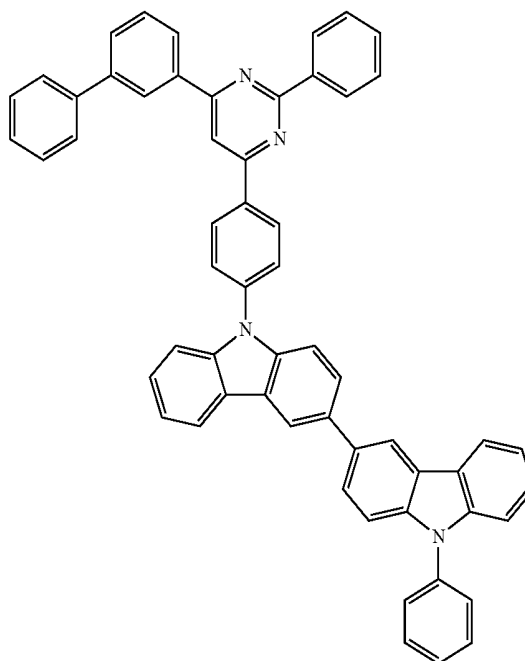
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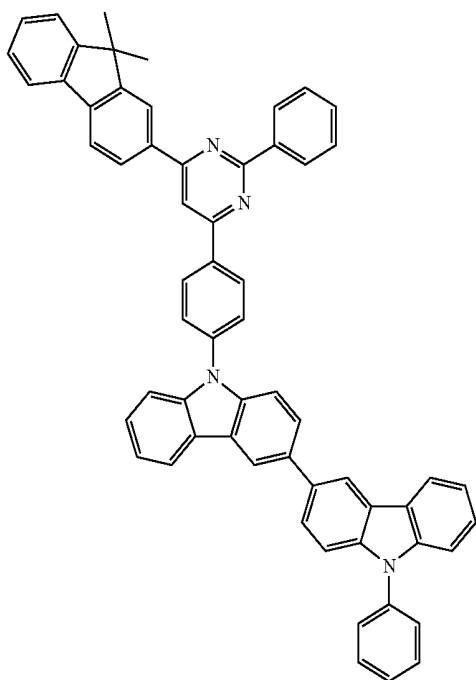
[41]



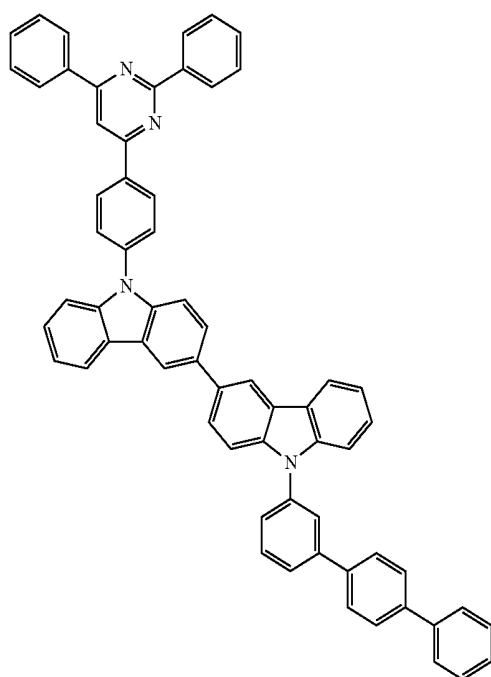
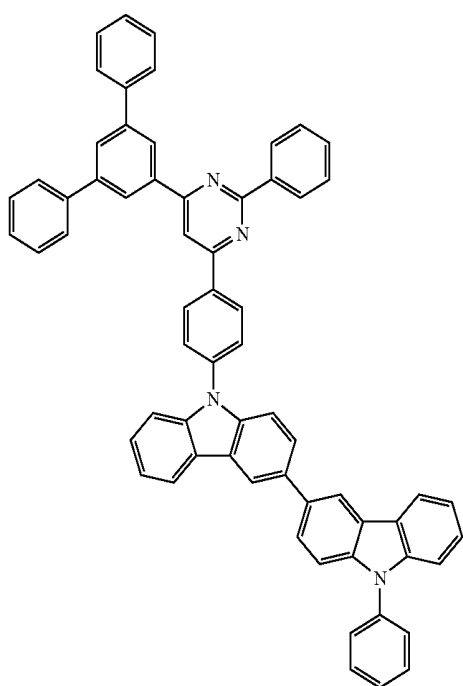
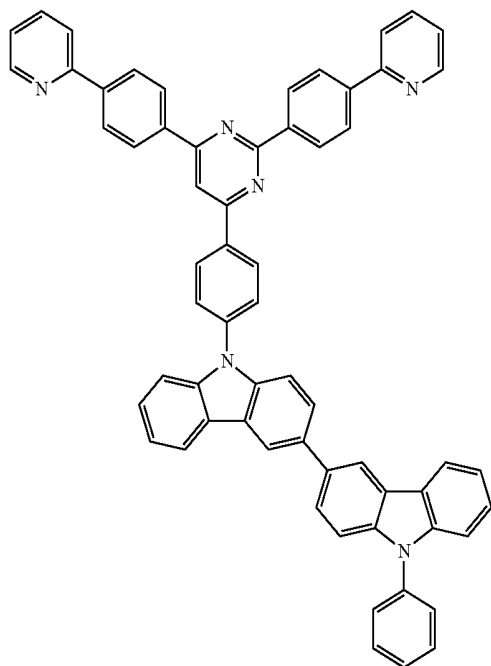
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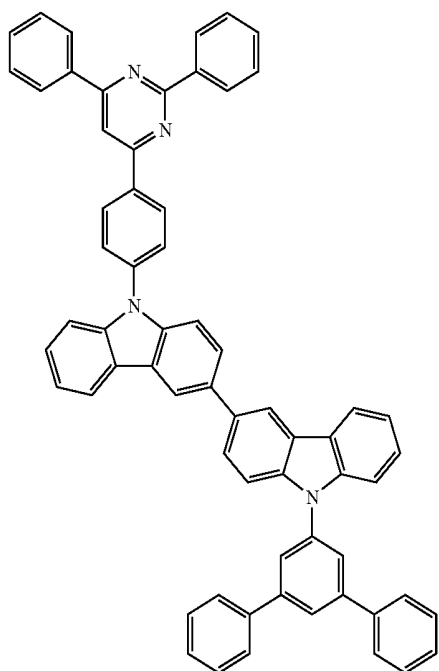
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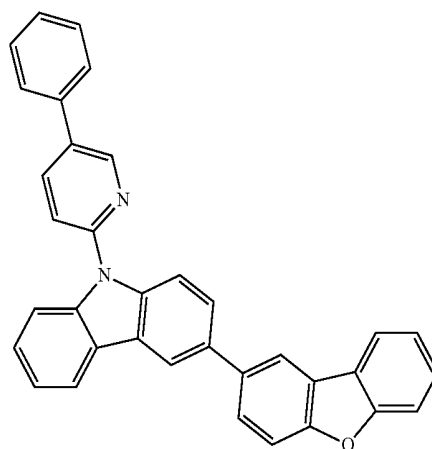


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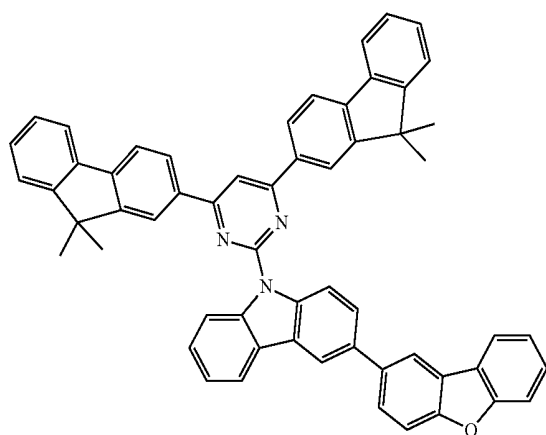
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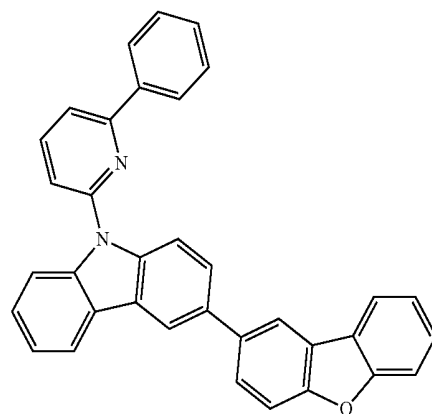


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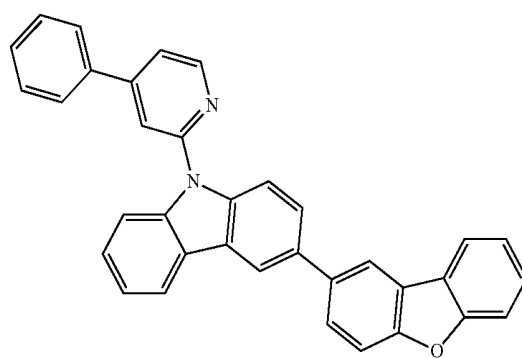
4. The organic light emitting diode display as claimed in claim 2, wherein the compound represented by Chemical Formula 2 is one of the following Compounds 49 to 73.



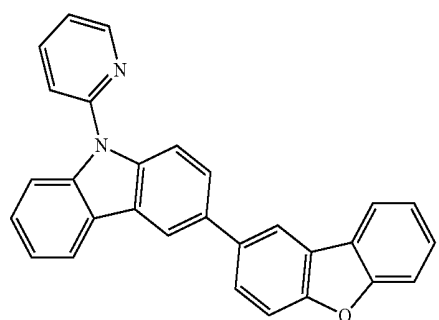
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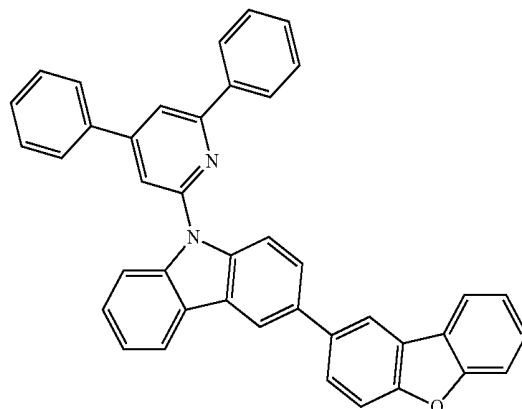
[52]



[53]



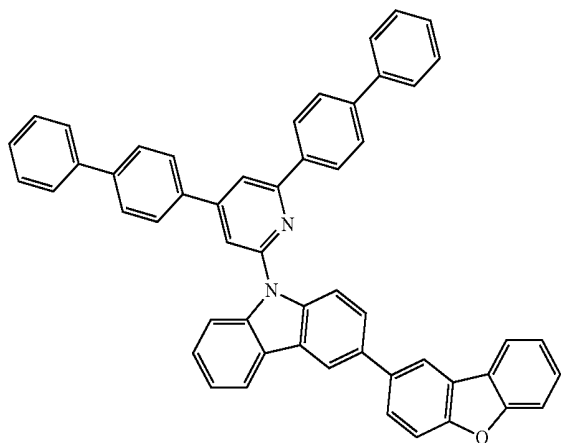
[50]



[54]

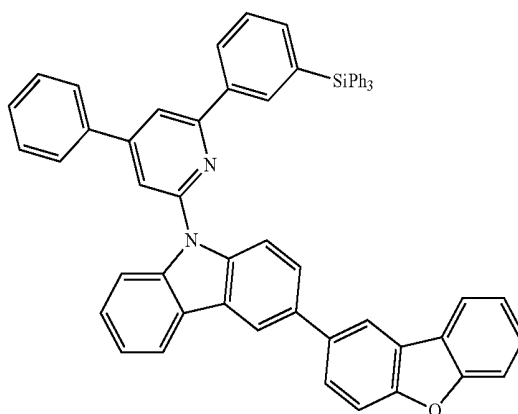
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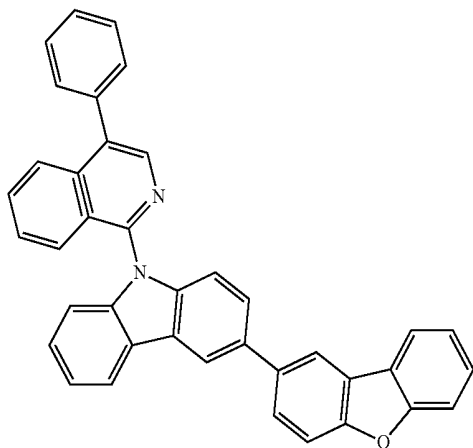


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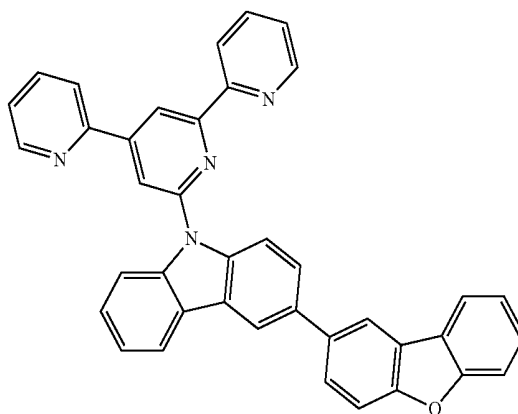
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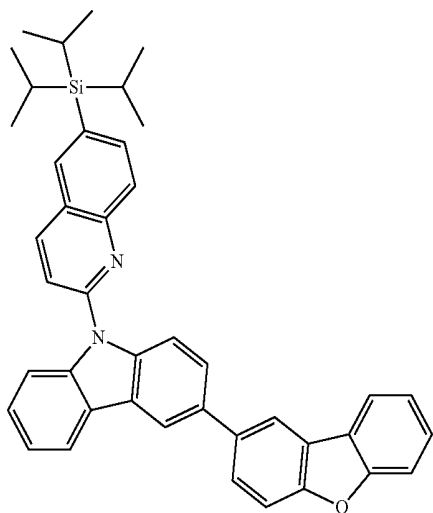
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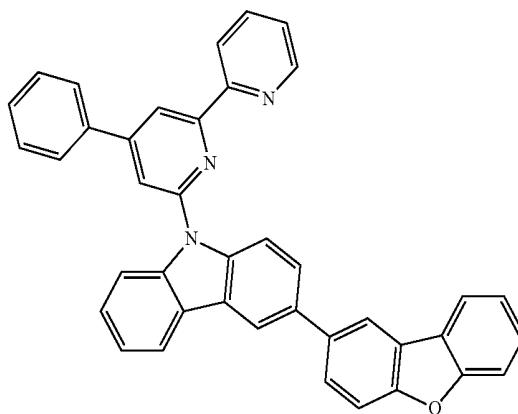
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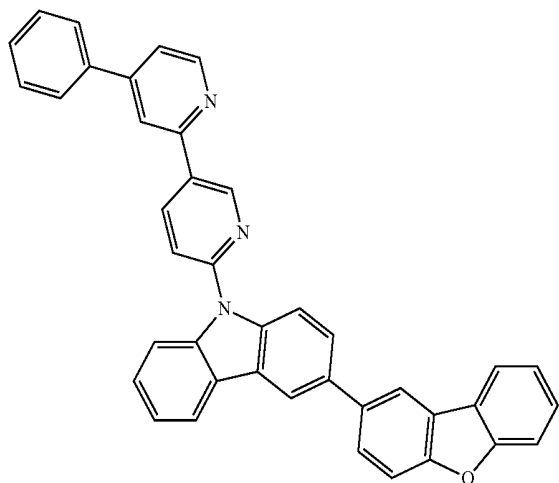


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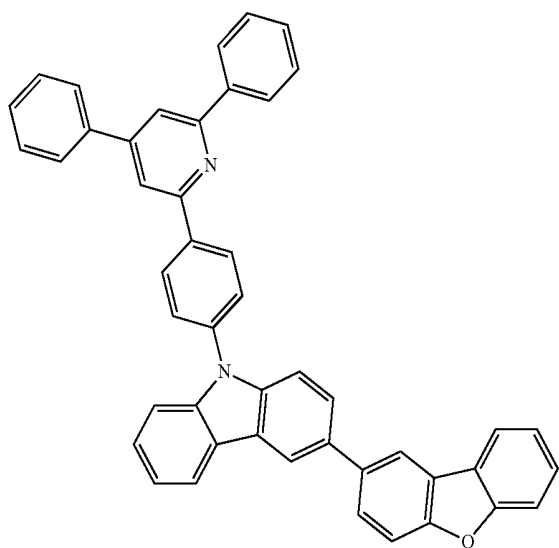


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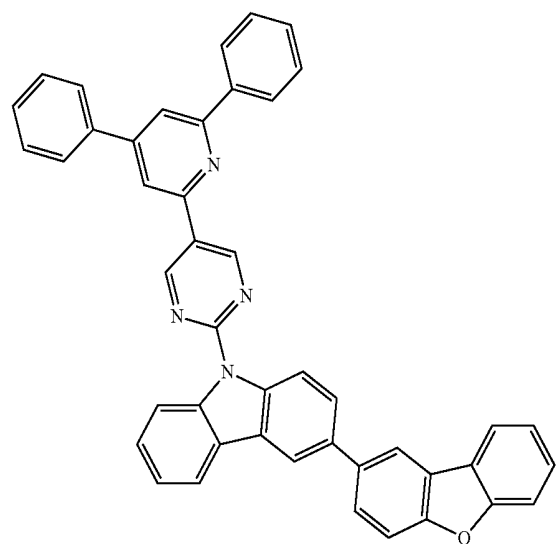
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[62]

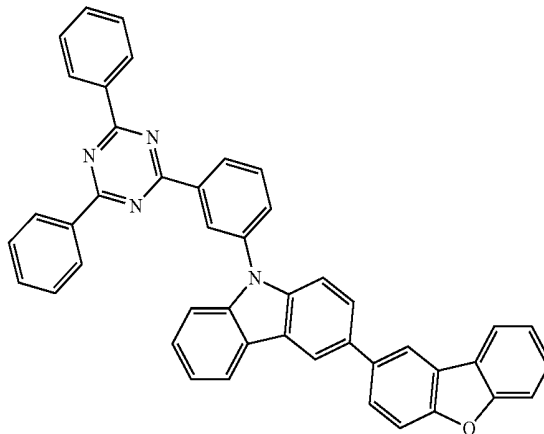


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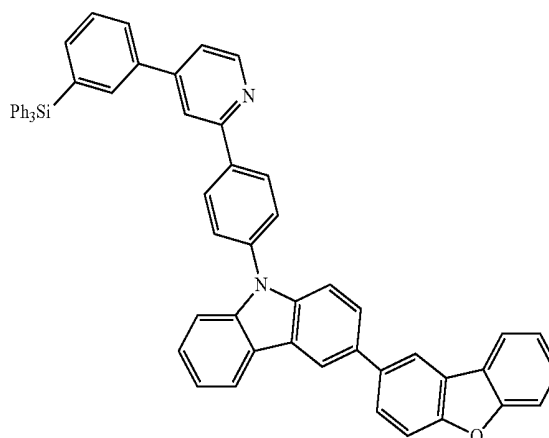


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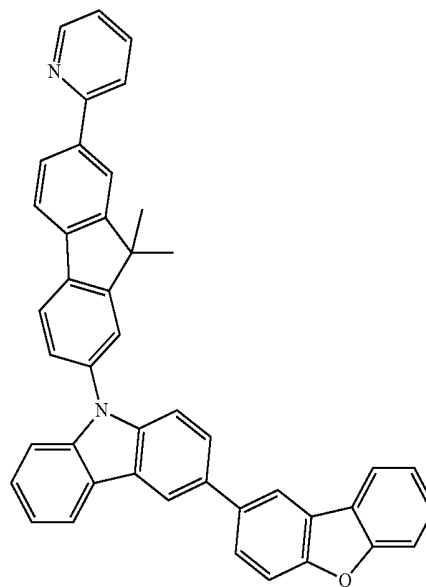
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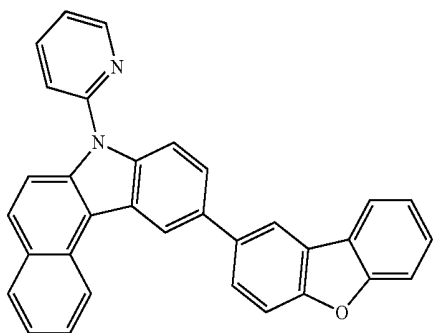
[65]



[66]

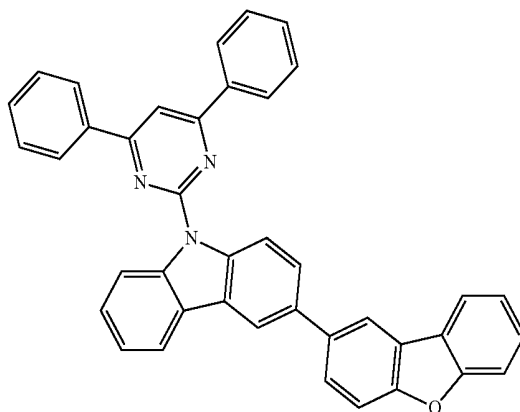


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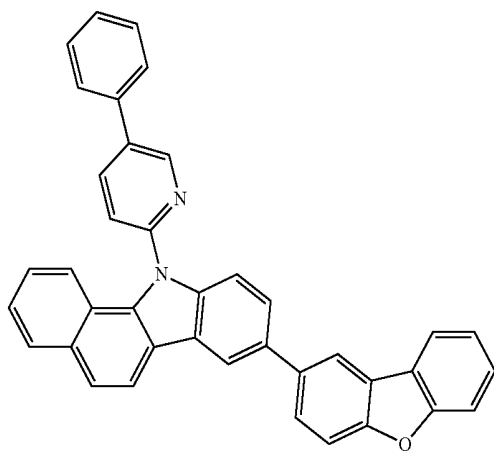
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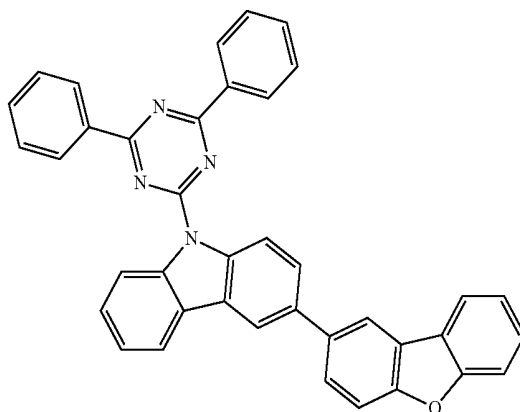


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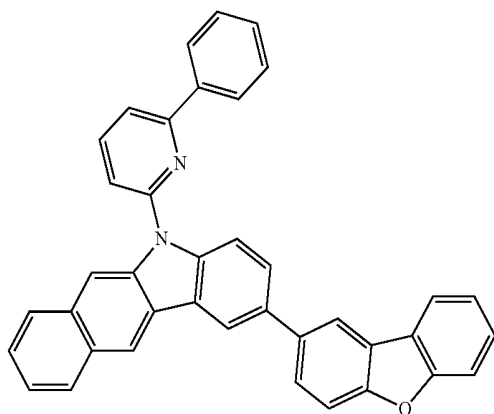
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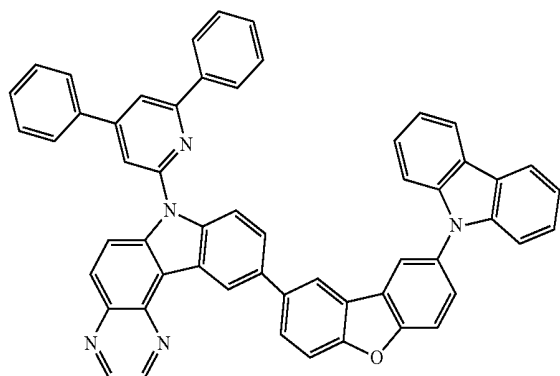
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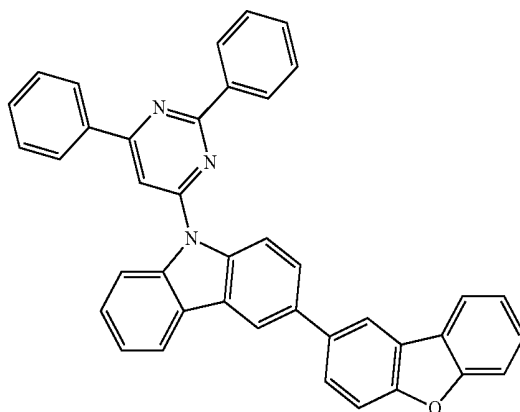
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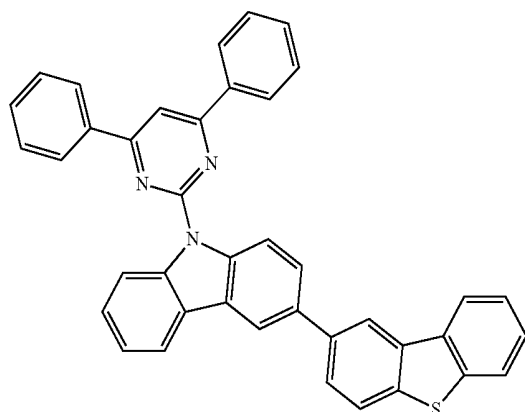
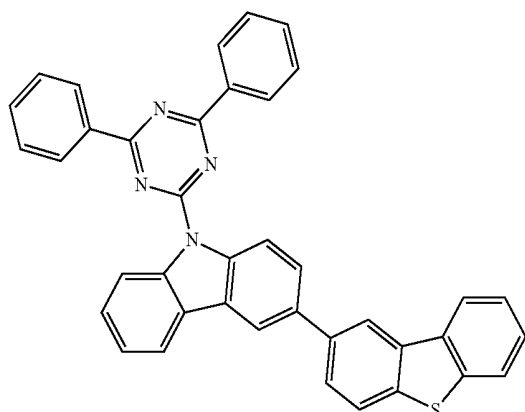
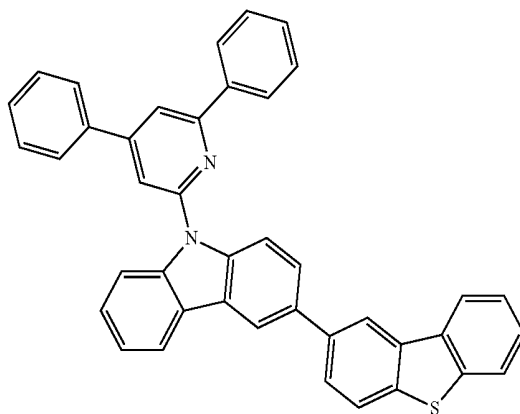
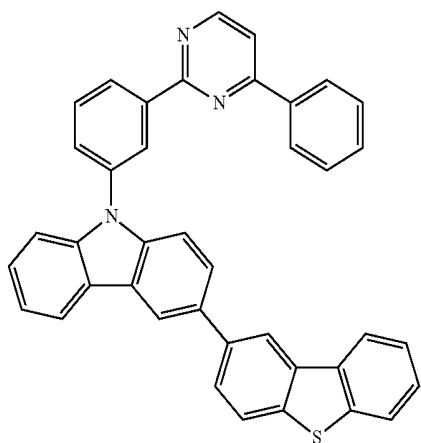
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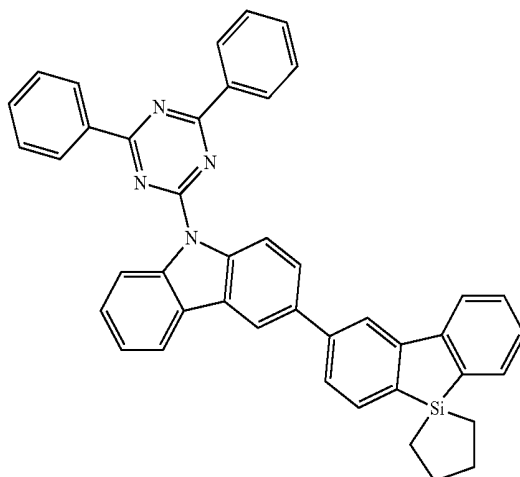
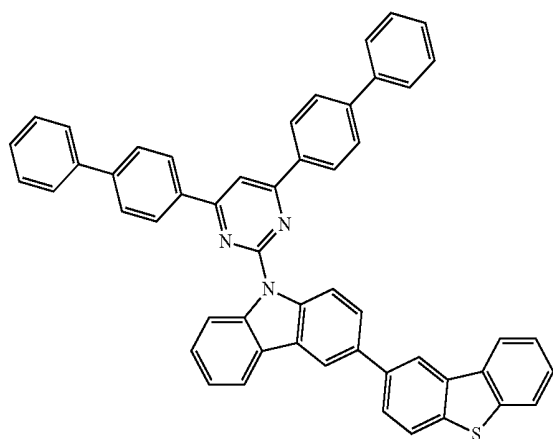
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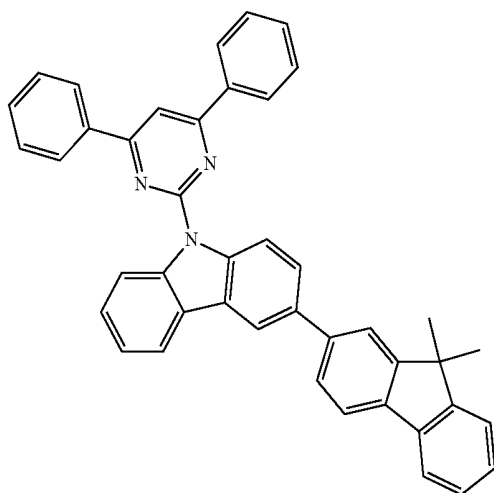
5. The organic light emitting diode display as claimed in claim 2, wherein the compound represented by Chemical Formula 3 is one of the following Compounds 74 to 78.



6. The organic light emitting diode display as claimed in claim 2, wherein the compound represented by Chemical Formula 4 is one of the following Compounds 79 to 84.

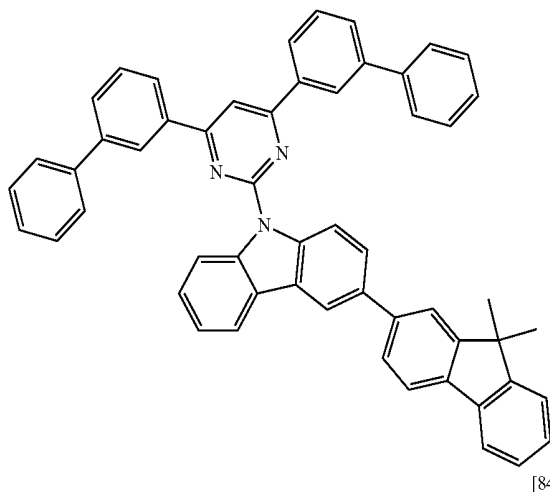


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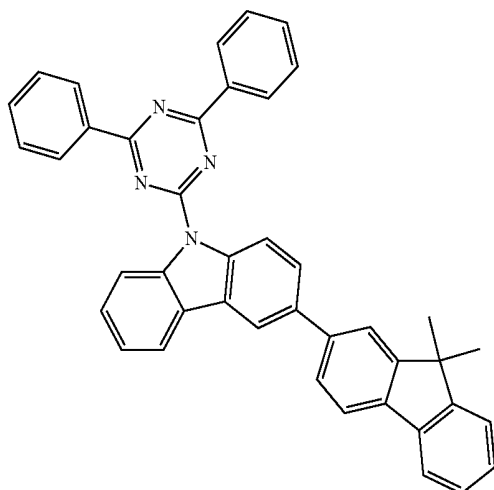


[80]

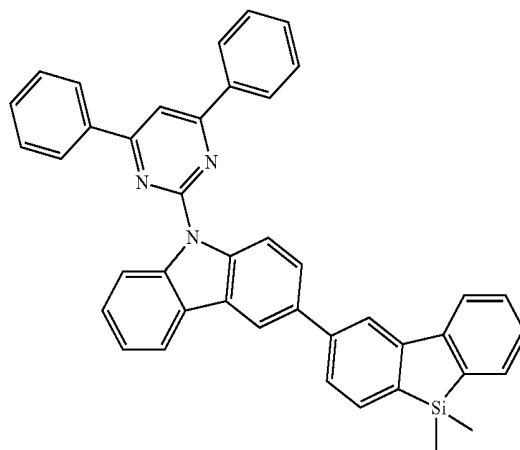
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[83]



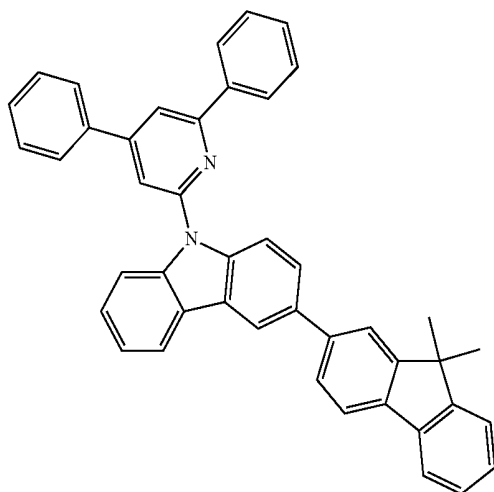
[81]



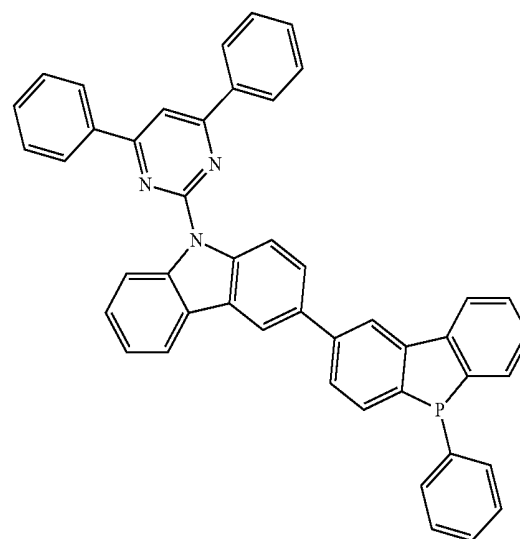
[84]

7. The organic light emitting diode display as claimed in claim 2, wherein the compound represented by Chemical Formula 5 is one of the following Compounds 85 to 88.

[85]



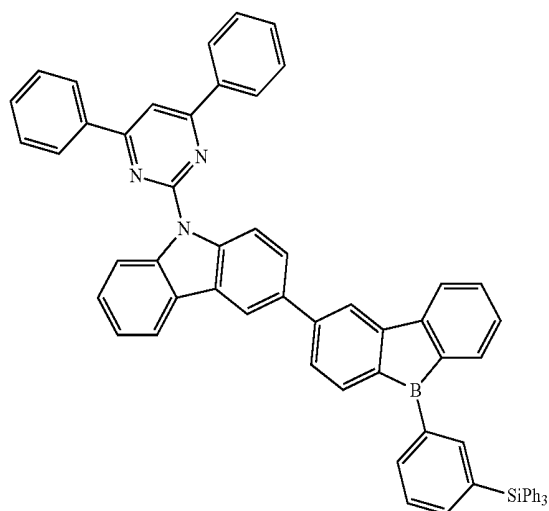
[82]



[85]

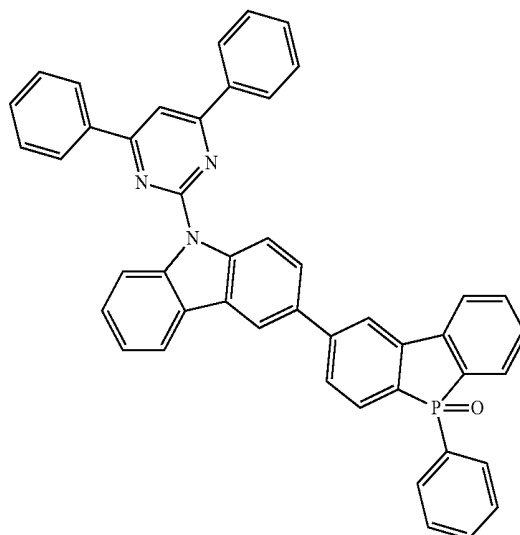
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[86]

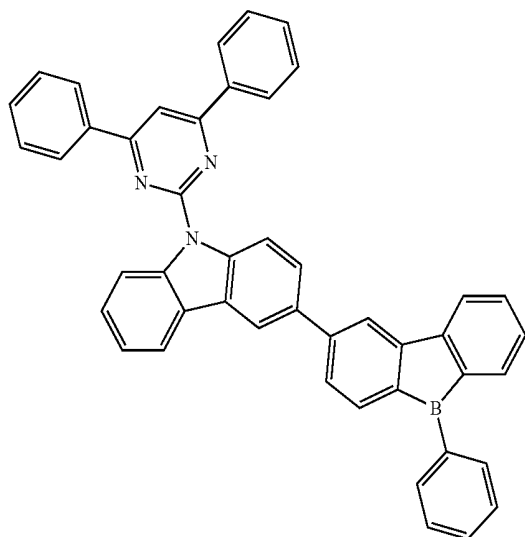


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[88]



[87]



8. The organic light emitting diode display as claimed in claim 1, wherein the capping layer has a refractive index of about 1.9 or higher.

9. The organic light emitting diode display as claimed in claim 1, wherein the capping layer has a refractive index of about 1.9 to about 3.0.

10. The organic light emitting diode display as claimed in claim 1, wherein the capping layer has a thickness of about 10 nm to about 300 nm.

11. The organic light emitting diode display as claimed in claim 1, further comprising at least one of a hole injection layer and a hole transporting layer between the first electrode and the organic light emitting layer.

12. The organic light emitting diode display as claimed in claim 1, further comprising at least one of an electron transporting layer and an electron injection layer between the organic light emitting layer and the second electrode.

13. The organic light emitting diode display as claimed in claim 1, further comprising a second substrate on the capping layer, the second substrate being spaced apart from the capping layer.

14. The organic light emitting diode display as claimed in claim 13, further comprising an air layer in a space between the capping layer and the second substrate.

15. The organic light emitting diode display as claimed in claim 13, further comprising a filling member in a space between the capping layer and the second substrate.

16. The organic light emitting diode display as claimed in claim 1, further comprising a thin film encapsulation layer on the capping layer.

* * * * *

一种有机发光二极管显示器,包括第一基板;第一基板上的第一电极;第一电极上的有机发光层;有机发光层上的第二电极;第二电极上的覆盖层,其中所述覆盖层包含至少一种杂环化合物,所述杂环化合物包括咔唑基和与所述咔唑基键合的杂环基。

